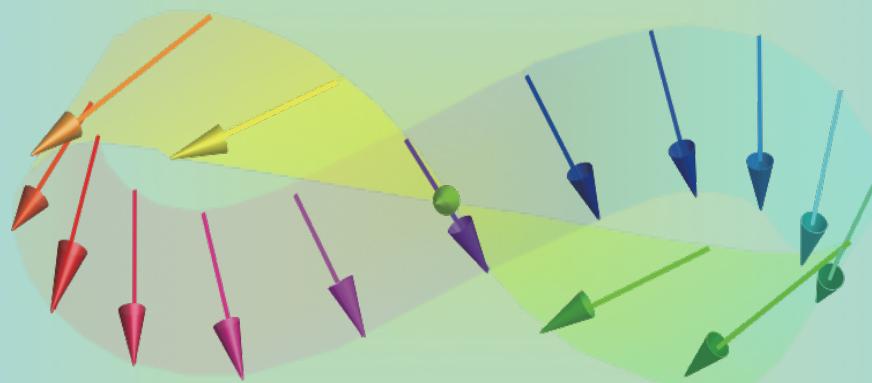


Tutorial on Spintronics and Its Device Applications

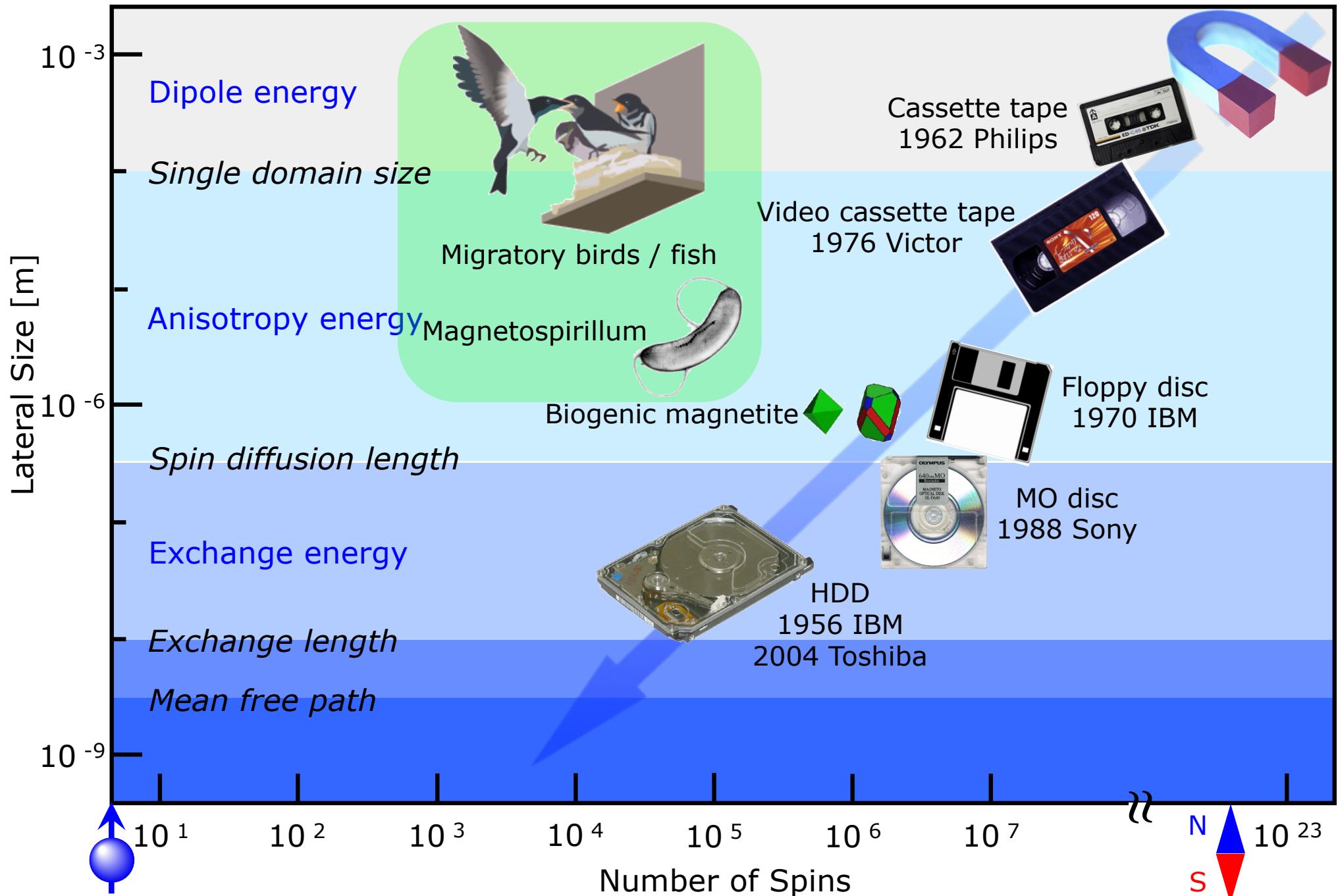


Atsufumi Hirohata

THE UNIVERSITY *of York*



Go into Nano-Scale





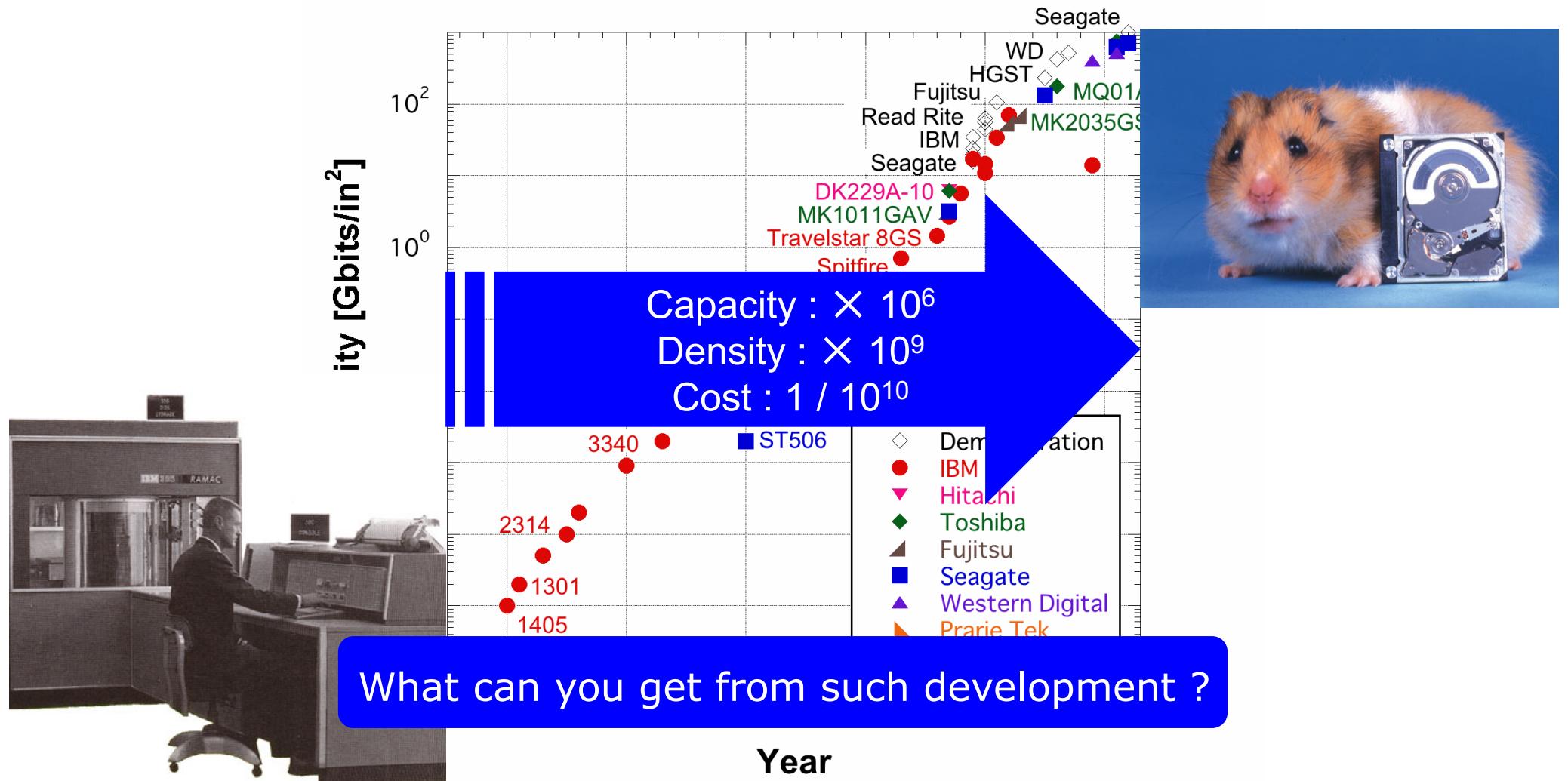
Increase in Recording Density of Hard Disc Drives

Similar to Moore's law :

Areal density in a hard disc drive (HDD) doubles every 36 months. (~ 1992)

After giant magnetoresistance (GMR) implementation,

it doubles less than every 20 months. (1992 ~)





Nobel Prize in Physics 2007

nature news

Published online 9 October 2007 | Nature | doi:10.1038/449643a

News

The physics prize inside the iPod

Giant magnetoresistance secures Nobel.

[Geoff Brumfiel \(/news/author/Geoff+Brumfiel/index.html\)](#)

Two researchers who discovered an effect that has dramatically shrunk the size of magnetic storage devices have won the 2007 Nobel Prize in Physics.

Albert Fert of the University of Paris-South in France and Peter Grünberg of Jülich Research Centre in Germany split the prize for their 1988 discovery of an effect called giant magnetoresistance (GMR). The Royal Swedish Academy of Sciences announced the award on 9 October in Stockholm.

The effect has been heralded as one of the first major applications of the fields of nanotechnology and 'spintronics'.

"I am so proud and so happy," Fert said in a press conference via telephone from France. "Science is something marvellous."

At the heart of GMR are the spins of electrons, which generate a magnetic field and can be aligned either up or down. An electron can easily pass through a material whose electrons are similarly aligned, but will encounter resistance when it passes through one with electrons aligned in the opposite direction.



Spin doctors: Peter Grünberg (left) and Albert Fert.

[physicsworld.com](#)

NEWS

Oct 9, 2007

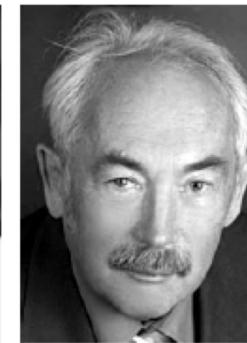
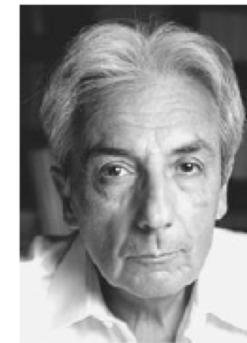
Nobel prize recognizes GMR pioneers

The 2007 Nobel Prize in Physics has been awarded jointly to Albert Fert of the Université Paris-Sud in France and Peter Grünberg of the Forschungszentrum Jülich in Germany "for the discovery of giant magnetoresistance". Their discovery, which both physicists made independently in 1988, led to a dramatic rise in the amount of data that can be stored on computer hard-disk drives. Fert and Grünberg share prize money totalling 10 million Swedish krone (about \$1.5m).



The Nobel Prize in Physics 2007

"for the discovery of Giant Magnetoresistance"



Blandin - AP, Everett Collection

NOBEL PRIZES

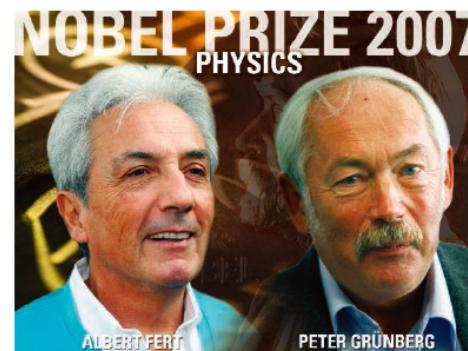
Effect that Revolutionized Hard Drives Nets a Nobel

If you work at a computer, play video games, or listen to music on an iPod, you've benefited directly from the efforts of the winners of the 2007 Nobel Prize in Physics. Albert Fert of France's national research agency, CNRS, in Orsay, France, and Peter Grünberg of the Jülich Research Center in Germany independently discovered an effect known as giant magnetoresistance (GMR) that fueled a dramatic increase in the capacity of computer hard drives. The discovery also laid the cornerstone of a new field known as spintronics, in which researchers try to exploit the fact that electrons spin like little tops to make novel devices.

"It's a physics discovery that has had real consequences," says Robert Buhrman, an applied physicist at IBM's Almaden Research Center in San Jose, California. "Without it we'd not be able to live life around a drive." The discovery was known that it's field to a iron or nickel conductivity. It would flow parallel to the material and more. Technologists effect to make "that sensed a magnetized hard drive. Known as ignore resistance-the resistance

varied by a few percent.

In 1988, Grünberg and Fert found that they could greatly increase the change in resistance if they made layer-cake films with layers of iron separated by layers of nonmagnetic chromium only a few atoms thick. If two adjacent iron layers are magnetized in the same direction, then electrons spinning in one direction will pass along the film readily, whereas electrons spinning in the other direction will not. If, however, the iron layers are magnetized in opposite directions, then all electrons run into greater resistance, regardless of how they are spinning. That makes a GMR film an extremely sensitive magnetic field detector. As a result, all the bits and hardware in a disk drive can be made much smaller.



Thanks for the memories. Physicists Albert Fert (left) and Peter Grünberg independently discovered an effect that vastly increased the capacity of computer drives.

The basic quantum mechanical concepts behind GMR were understood in the 1970s, but at the time technology was not available to exploit them, Fert says. "I put this idea in the fridge," he says. "Then in the 1980s, it became possible to fabricate these materials." Grünberg could not be reached for comment when *Science* went to press.

Although Fert and Grünberg discovered the effect, Stuart Parkin of IBM's Almaden Research Center in San Jose, California, did much of the work to make GMR technologically useful. Stuart Wolf, a physicist at the University of Virginia, Charlottesville, says he was surprised that Parkin was not honored as well. But Tony Blandin of the University of Cambridge, U.K., says that the Nobel committee apparently distinguished between the discovery and its cultivation. "This is properly a physics prize for a truly extraordinary and novel effect."

The advent of GMR helped launch the emerging field of spintronics, Wolf says. "This particular discovery seemed to crystallize a lot of people's interest in working in this area," he says. Their efforts may someday lead to myriad other devices, such as computer memory that can hold information even when it loses power and microchips that exploit spin to perform computations.

-ADRIAN CHO

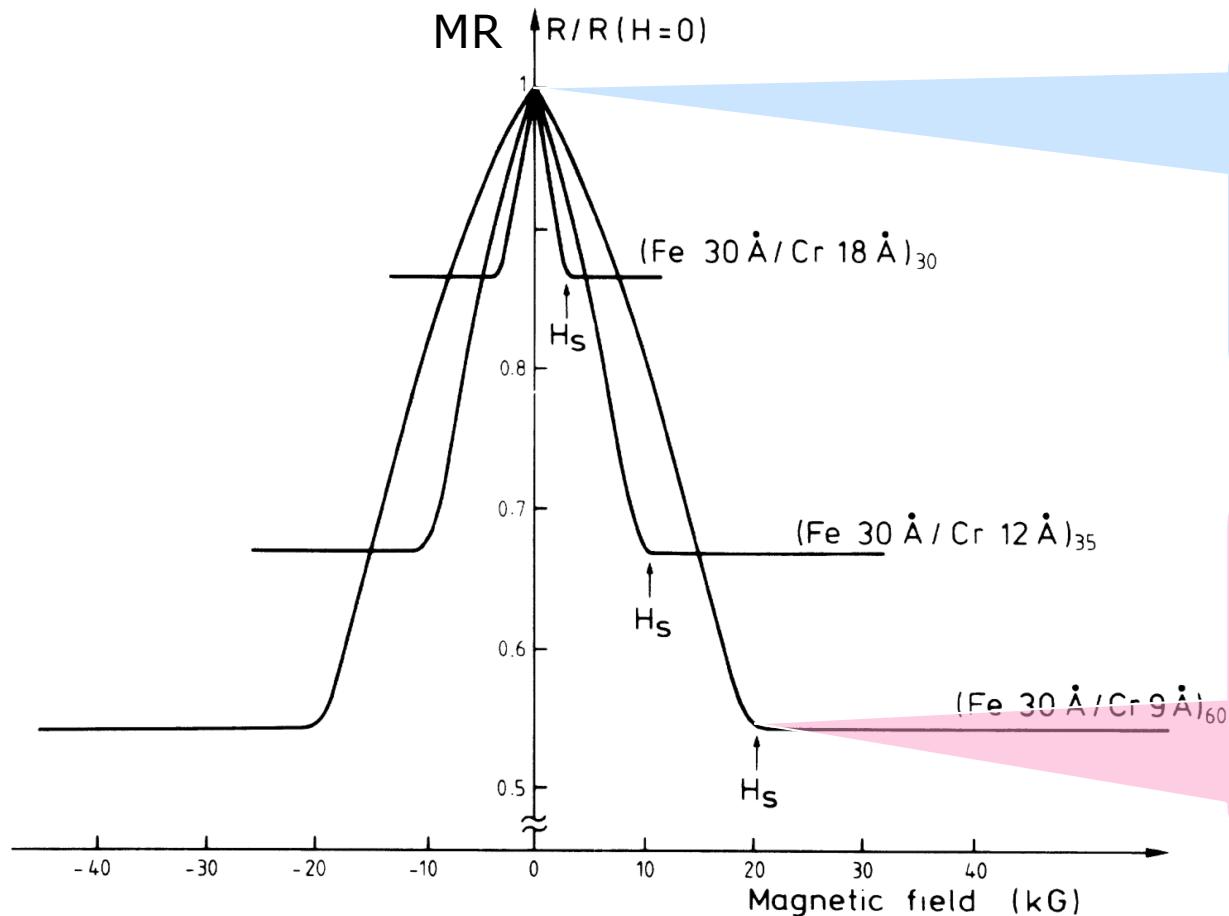
With reporting by Daniel Clery.



Discovery of Giant Magnetoresistance

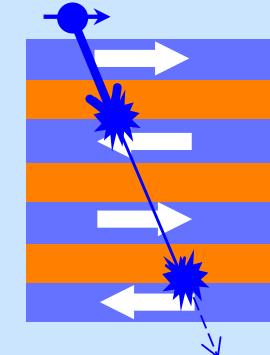
Giant magnetoresistance (GMR) :

$$[3 \text{ nm Fe} / 0.9 \text{ nm Cr}] \times 60 *$$

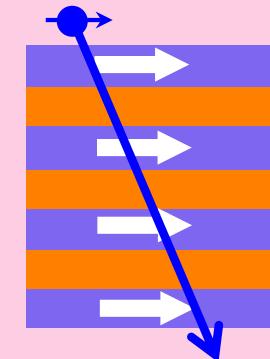


$$H = 0$$

Spin-valve
“OFF”



$H =$
Saturation
Spin-valve
“ON”



50 % resistance change at 4.2 K

* M. N. Baibich *et al.*, *Phys. Rev. Lett.* 61, 2472 (1988); P. Grünberg *et al.*, *Phys. Rev. Lett.* 57, 2442 (1986).



HDD in Cloud

In this lecture theatre,



30 Smart Phones = 1/4 Cloud server
81 % (2016, UK)



20 Tablet PCs = 1/4 Cloud server
71 % (2016, UK)

3 Cloud servers used

Google
for Education

1 TB max. / person = 2.5 Cloud servers



Microsoft
Azure

 **amazon**
web services



Magnetism + Electronics

By taking advantages from both magnetism and semiconductor physics,

Magnetism



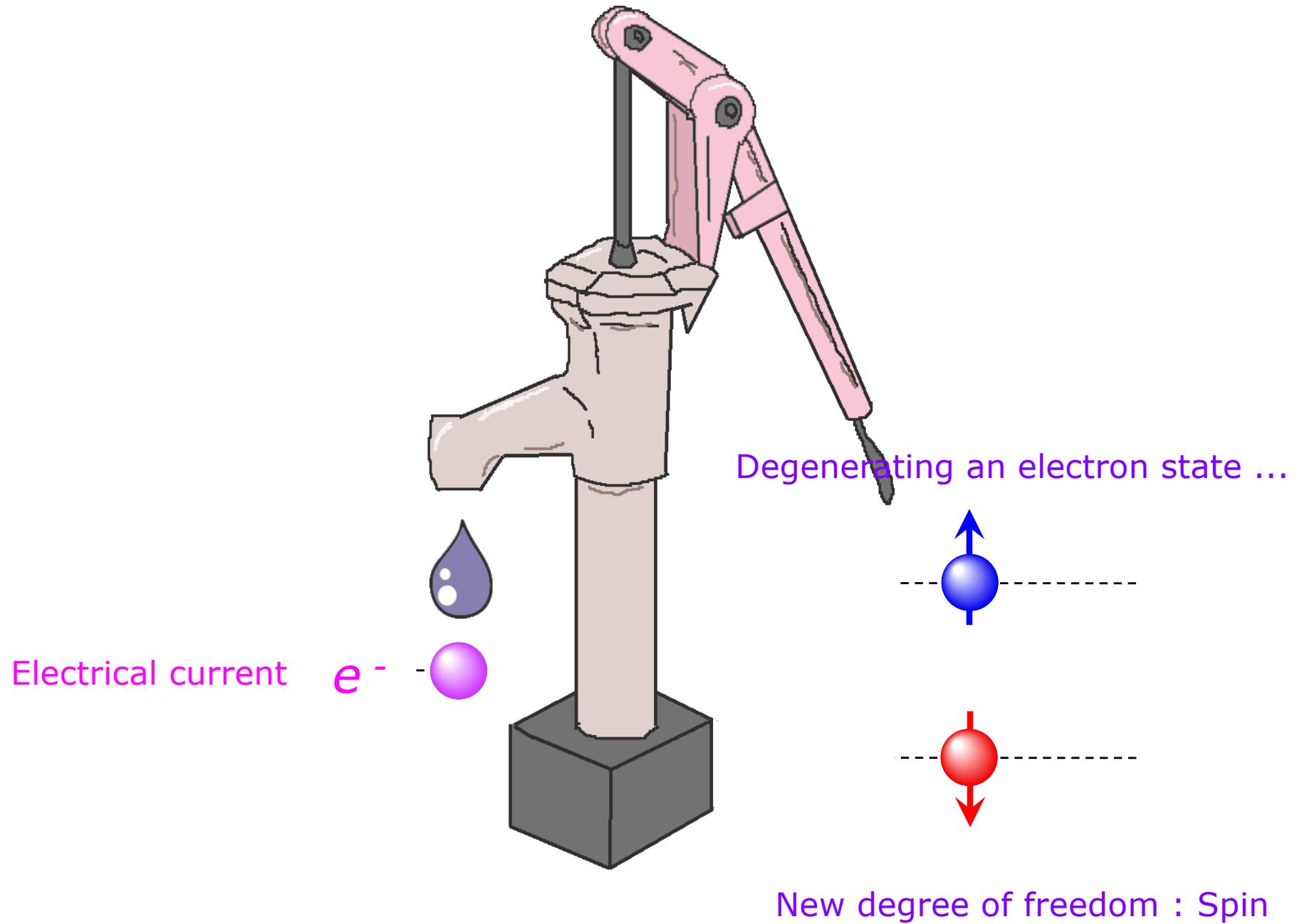
- ✓ Atomically smooth surface / interface
- ✓ Spin diffusion length (\sim nm)
- ✓ Low resistivity ($10^{-7} \sim 10^{-8} \Omega\cdot m$)
- ✓ Spin polarisation
- ✓ Magnetically anisotropic

Semiconductor physics

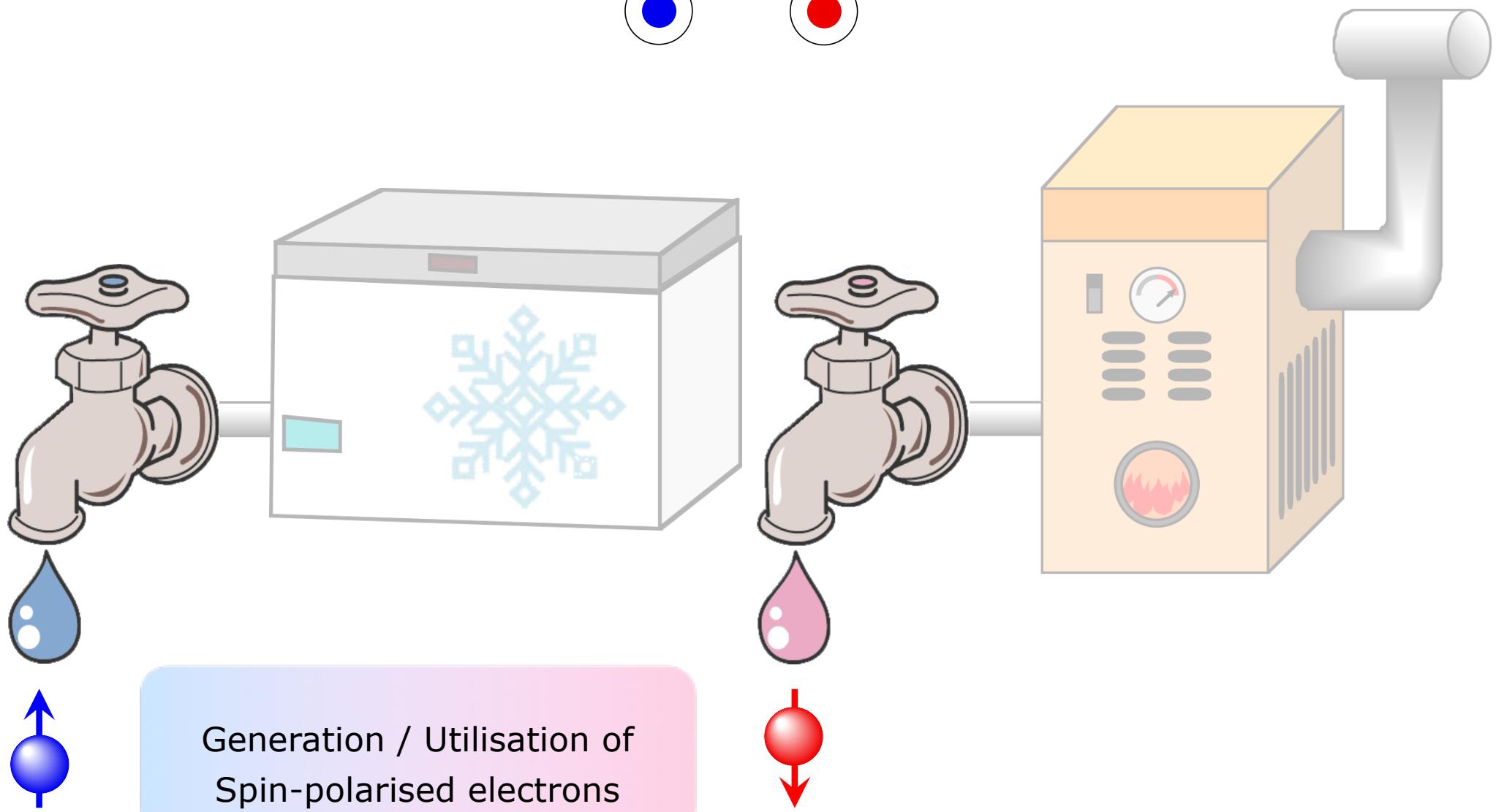
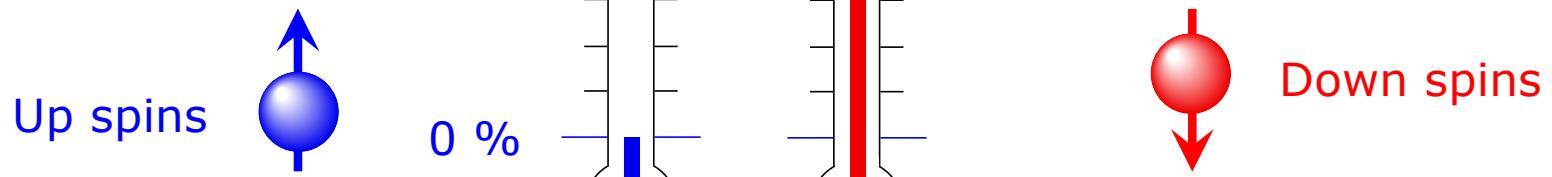


- ✗ Depletion layer ($\mu m \sim nm$)
- ✗ Spin diffusion length ($\sim \mu m$)
- ✓ Variable resistivity ($10^{-5} \sim 10^8 \Omega\cdot m$)
- ✓ Doping (atomic engineering)
- ✗ Isotropic

Conventional Electronics



Magnetoelectronics

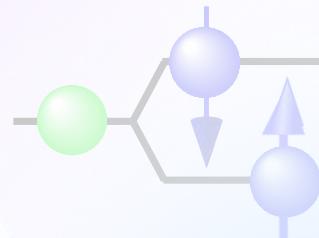




Generation of Spin-Polarised Electrons

Zeeman splitting

Y. Ohno *et al.*, *Nature* **402**, 790 (1999).

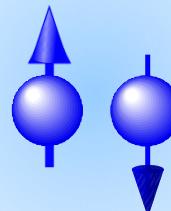


Circularly polarised photoexcitation

M. W. J. Prins *et al.*, *J. Phys.: Condens. Matter* **7**, 9447 (1995);
A. Hirohata *et al.*, *Phys. Rev. B* **63**, 104425 (2001).



Spins



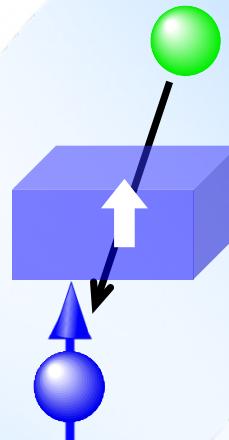
Thermal gradient introduction

K. Uchida *et al.*, *Nature* **455**, 778 (2008).

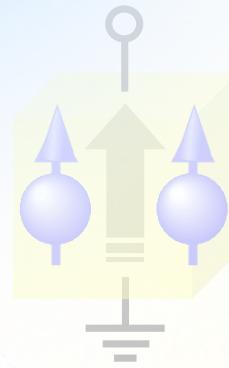


Spin injection from a ferromagnet

M. Johnson, *Science* **260**, 324 (1993);
F. J. Jedema *et al.*, *Nature* **410**, 345 (2000).



Magnetic field application



Electric field application

H. Ohno *et al.*, *Nature* **408**, 944 (2000).



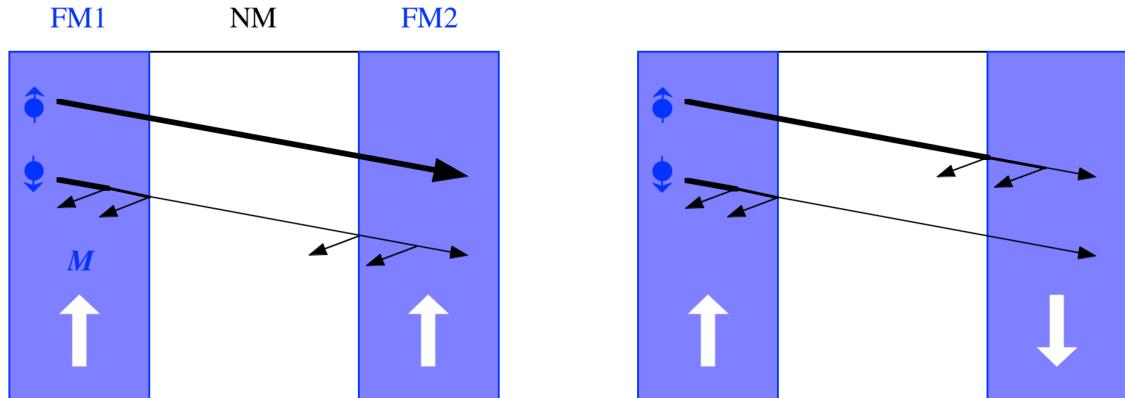
Theoretical Models for GMR

Interlayer exchange coupling model :

RKKY-like oscillation *

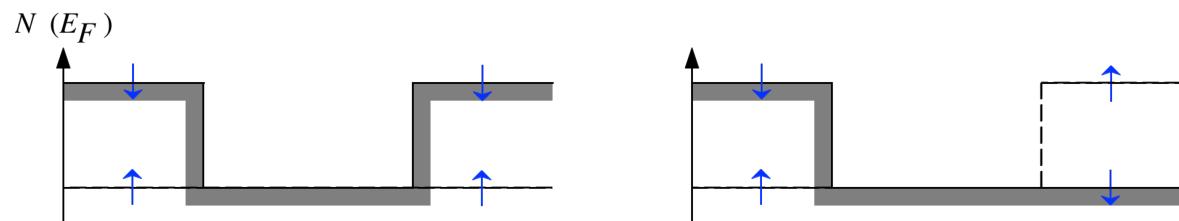
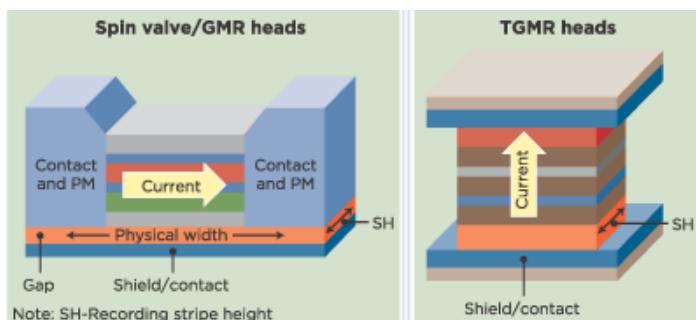
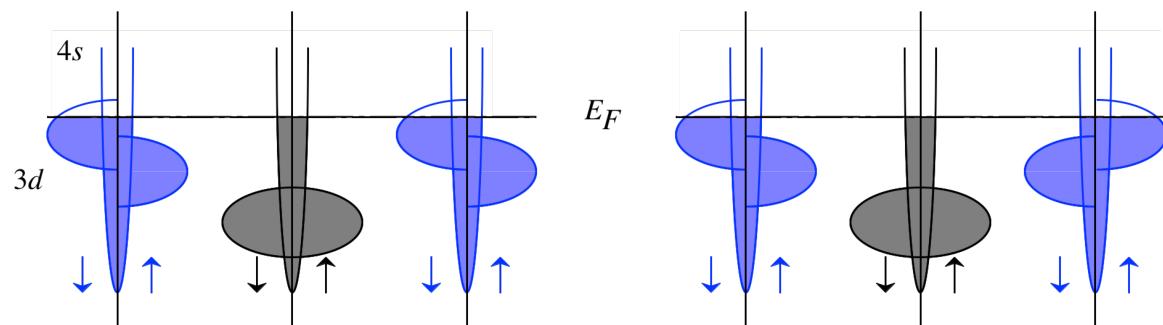
Two current model :

3d ferromagnets (FM) carry
up spin current
down spin current
independently with different
scattering rates at
the FM layers
the FM / NM interfaces. **



Current orientation :

Current in the plane (CIP)
Current perpendicular to the
plane (CPP)



* K. B. Hathaway, *Ultrathin Magnetic Structures II*, B. Heinrich and J. A. C. Bland (Eds.) (Springer, Berlin, 1994), p. 45-72;

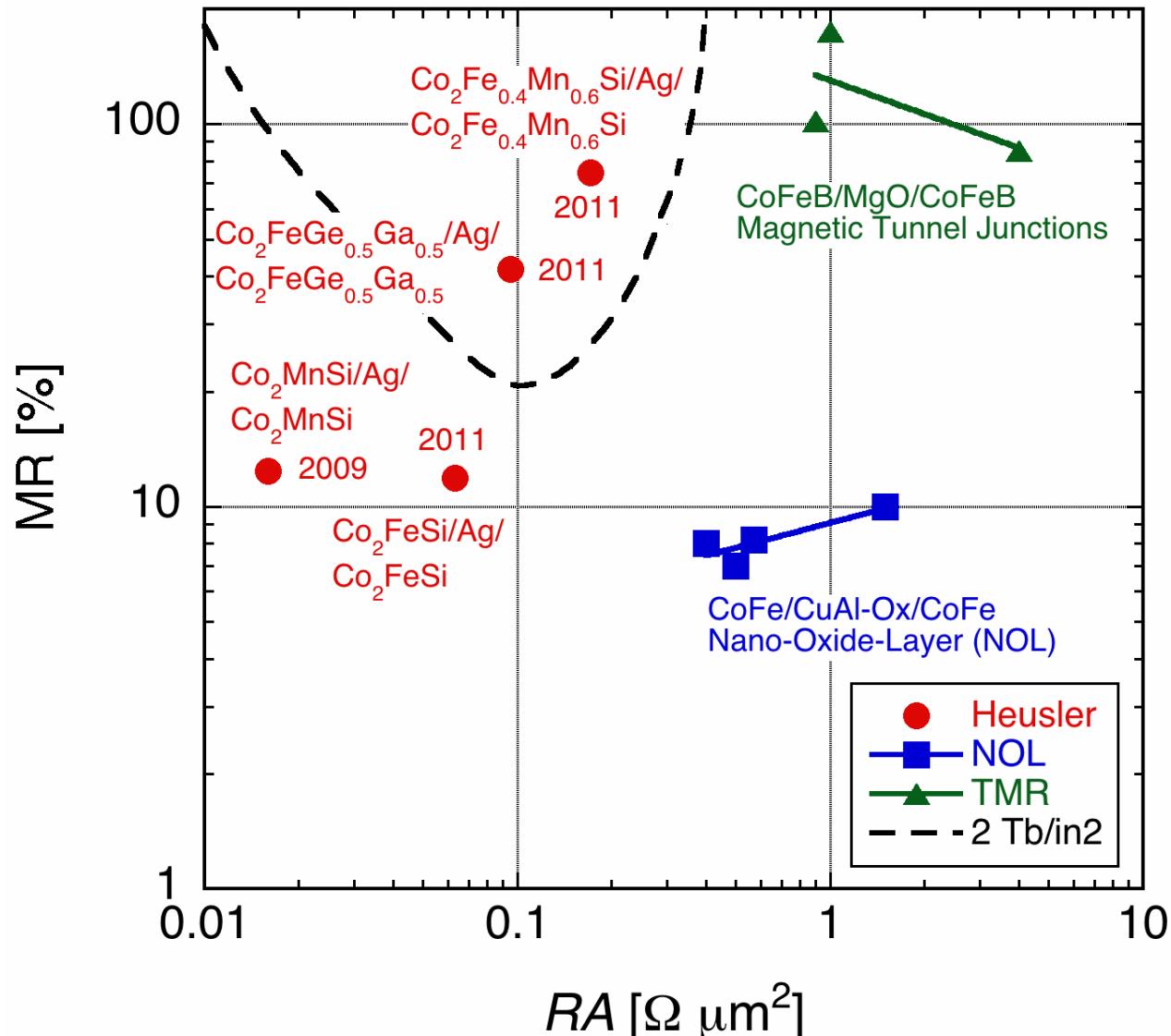
** J. Mathon, *Spin Electronics*, M. Ziese and M. J. Thornton (Eds.) (Springer, Berlin, 2001), p. 71-88.

Larger GMR Ratios



For $> 2 \text{ Tb/in}^2$ recording :

Larger GMR ratios and smaller resistance-area product (*RA*) are required.

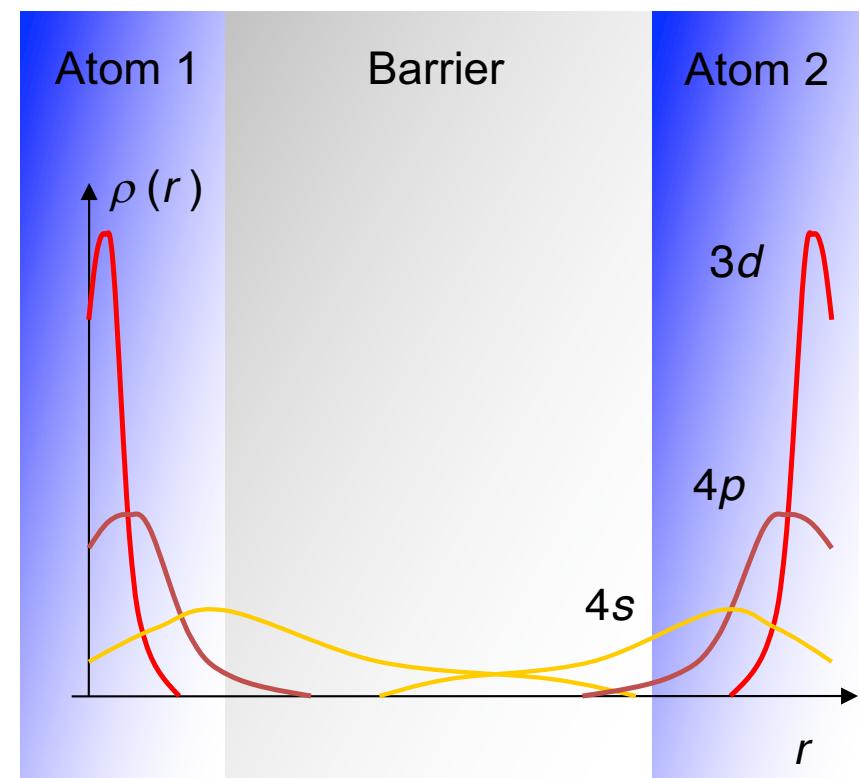
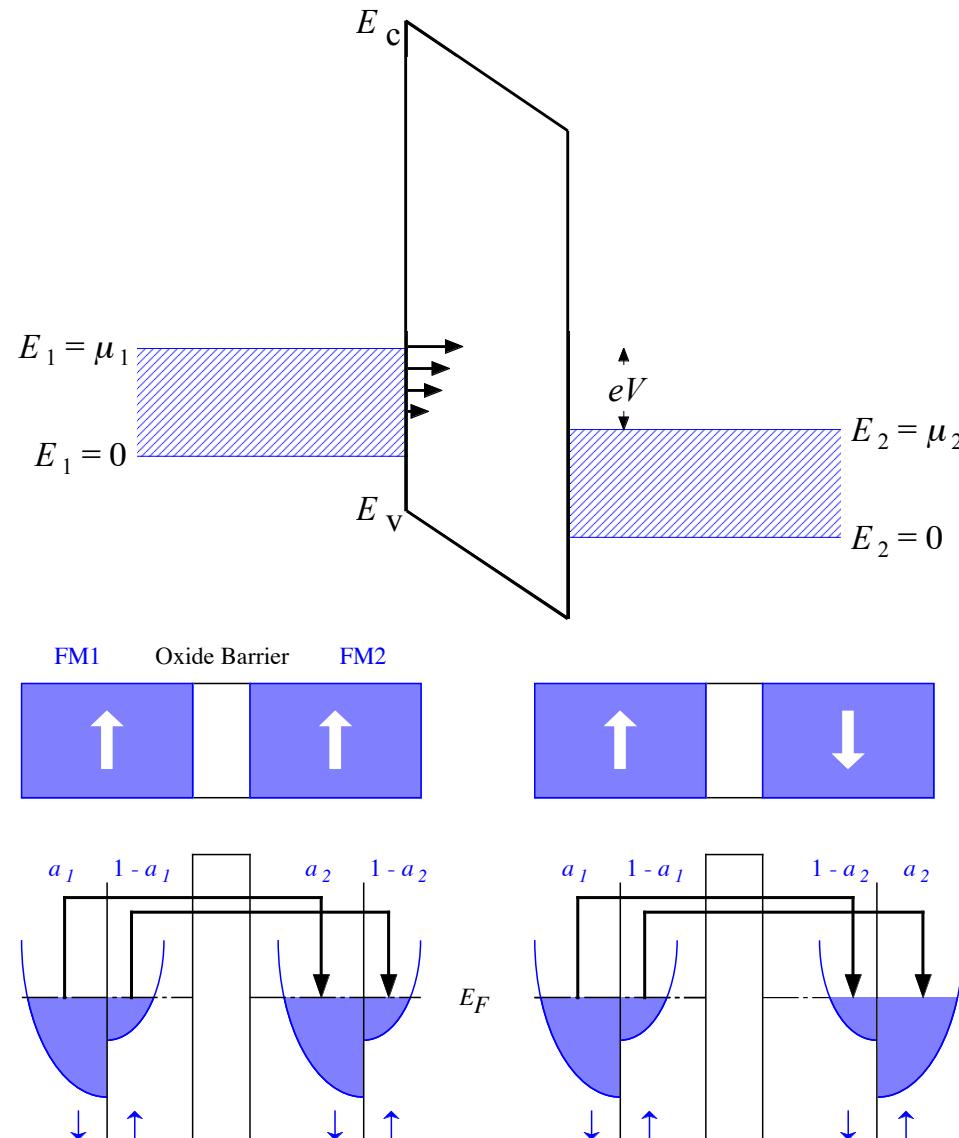




Spin-Dependent Electron Tunneling

Jullière's model :

FM / insulator / FM junctions *



* M. Jullière., *Phys. Rep.* **54A**, 225 (1975).



Theoretical Models for TMR

Free electron models :

Juliere's model :

$$\begin{cases} G^P \propto a_1 a_2 + (1-a_1)(1-a_2) \\ G^A \propto a_1(1-a_2) + (1-a_1)a_2 \end{cases}$$

$$\frac{R^A - R^P}{R^P} = \frac{2P_1 P_2}{1 - P_1 P_2}$$

Slonczewski's model * :

spin split free electron band

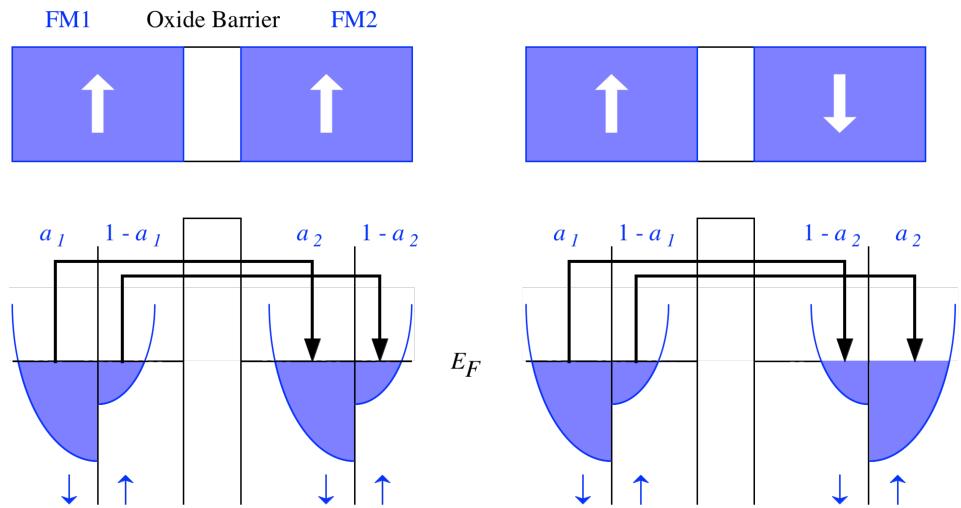
→ for large energy gap in a barrier, spin polarization :

$$P = \frac{N_{\uparrow}(E_F) - N_{\downarrow}(E_F)}{N_{\uparrow}(E_F) + N_{\downarrow}(E_F)}$$

WKB approximation **

Transfer Hamiltonian approach

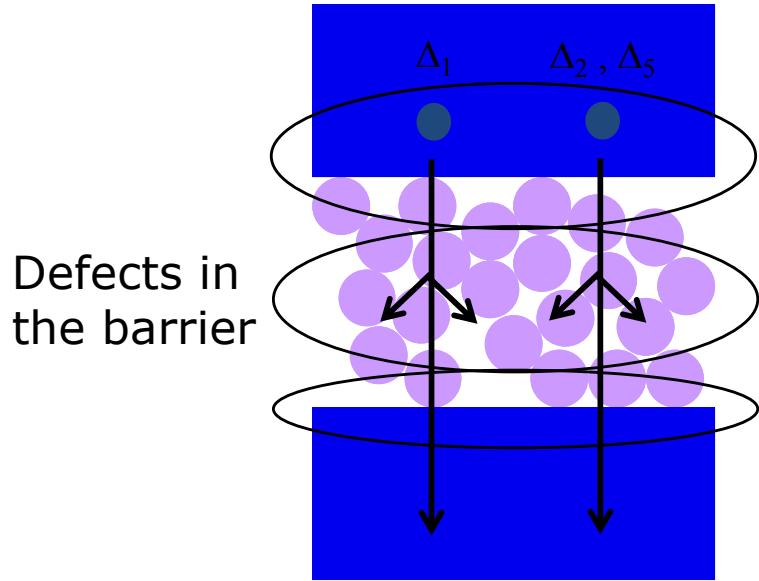
Ab initio calculations





Improved Tunnel Barriers

Conventional amorphous barriers : *



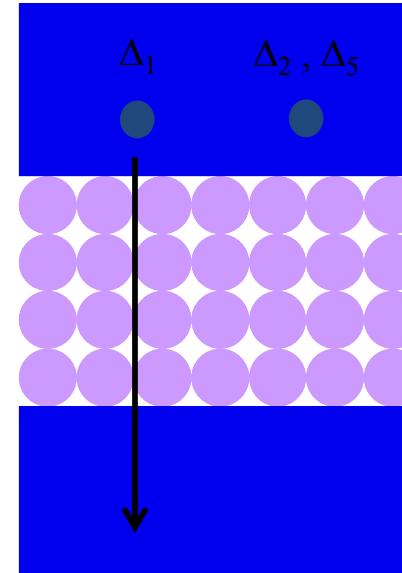
Disorder at the interface :

- FM over-oxidation
- lattice defects

Disorder at the interface :

- FM over-oxidation
- lattice defects
- island growth of the barrier

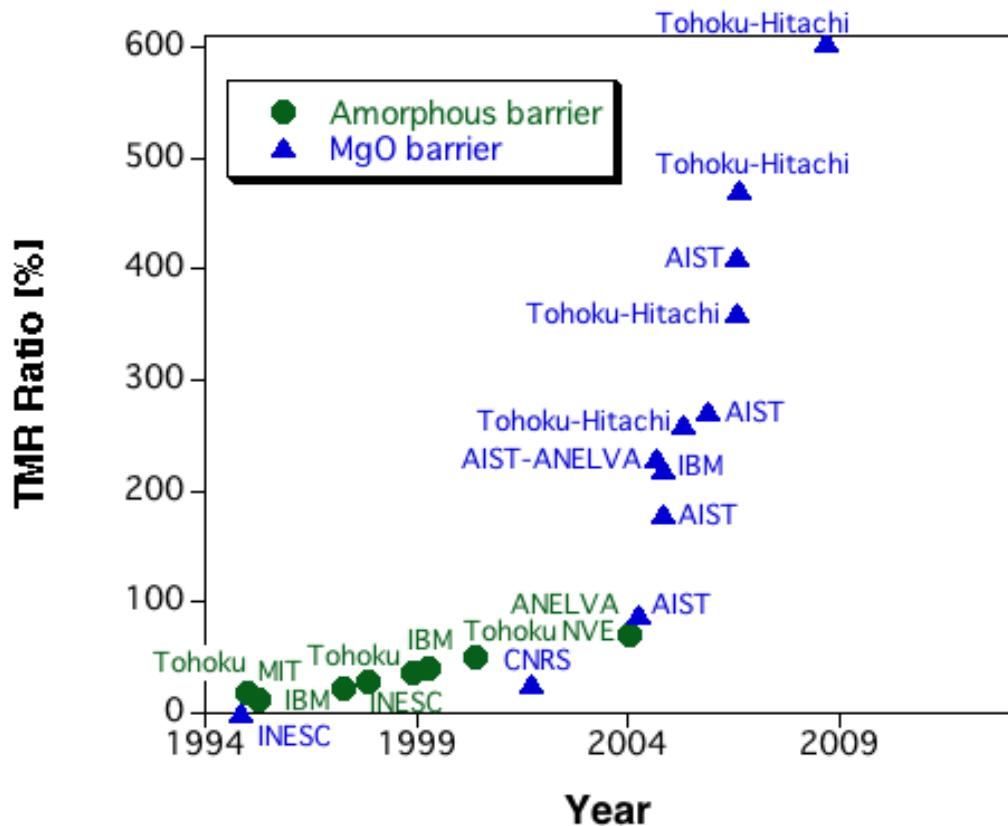
Epitaxial (oriented) barriers : *





TMR for Device Applications

Recent progress in TMR ratios :

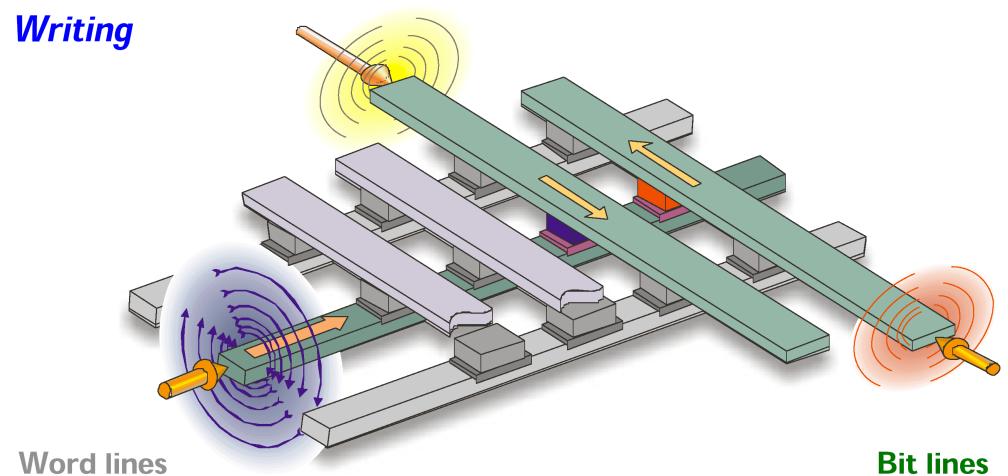


> 600 % TMR ratio has
been achieved !

↓
> Gbit MRAM can be
realised.

NOT following Jullière's
model : *

$$TMR = 2P_1P_2 / (1 - P_1P_2)$$



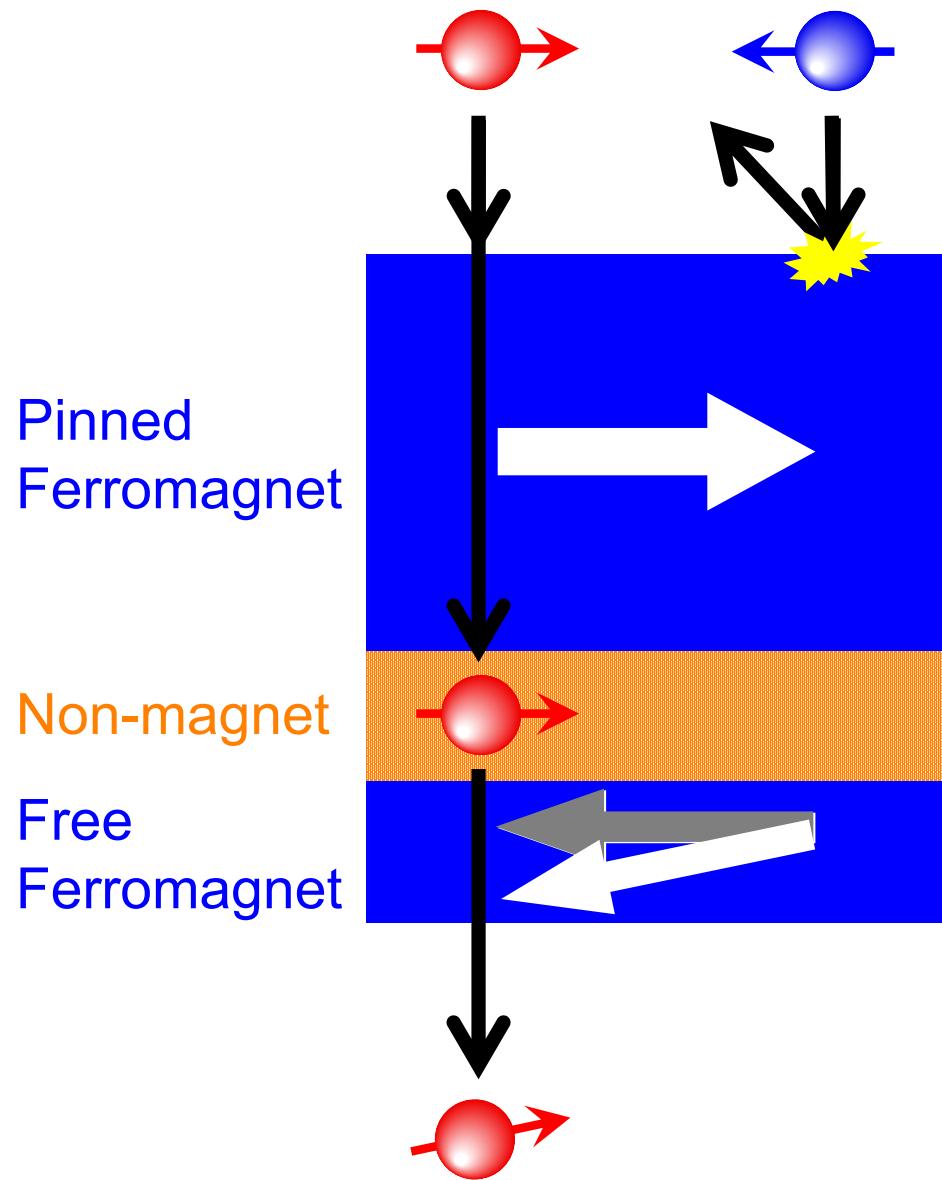
* M. Jullière., *Phys. Rep.* **54A**, 225 (1975).

** S. S. P. Parkin, *1st Int'l Sch. on Spintronics and Quantum Info. Tech.*, May 13-15, 2001 (Maui, HI, USA).

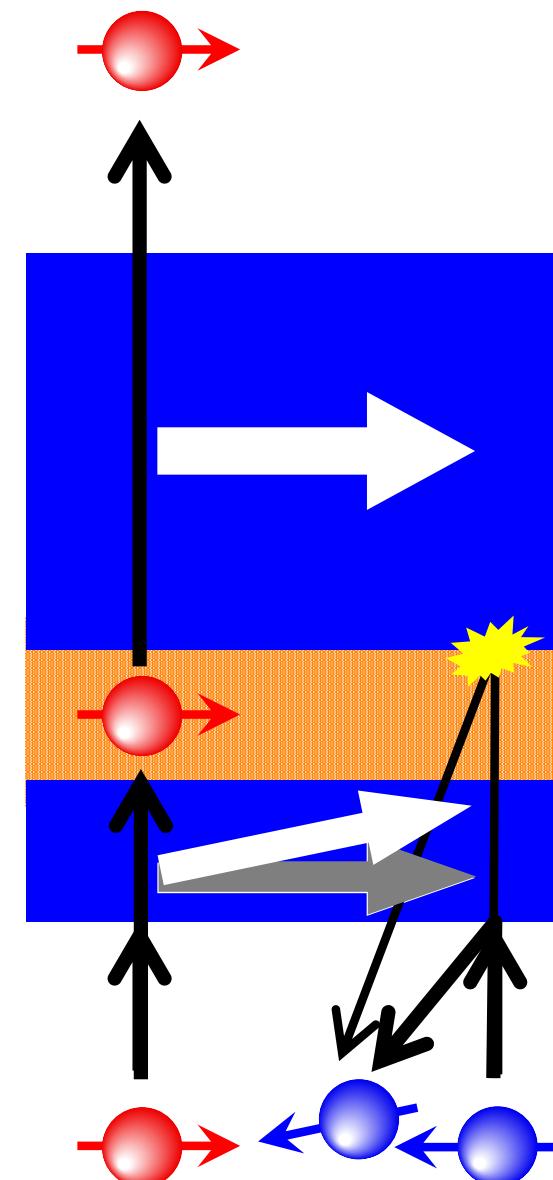


Current-Induced Magnetisation Switching

Antiparallel → Parallel



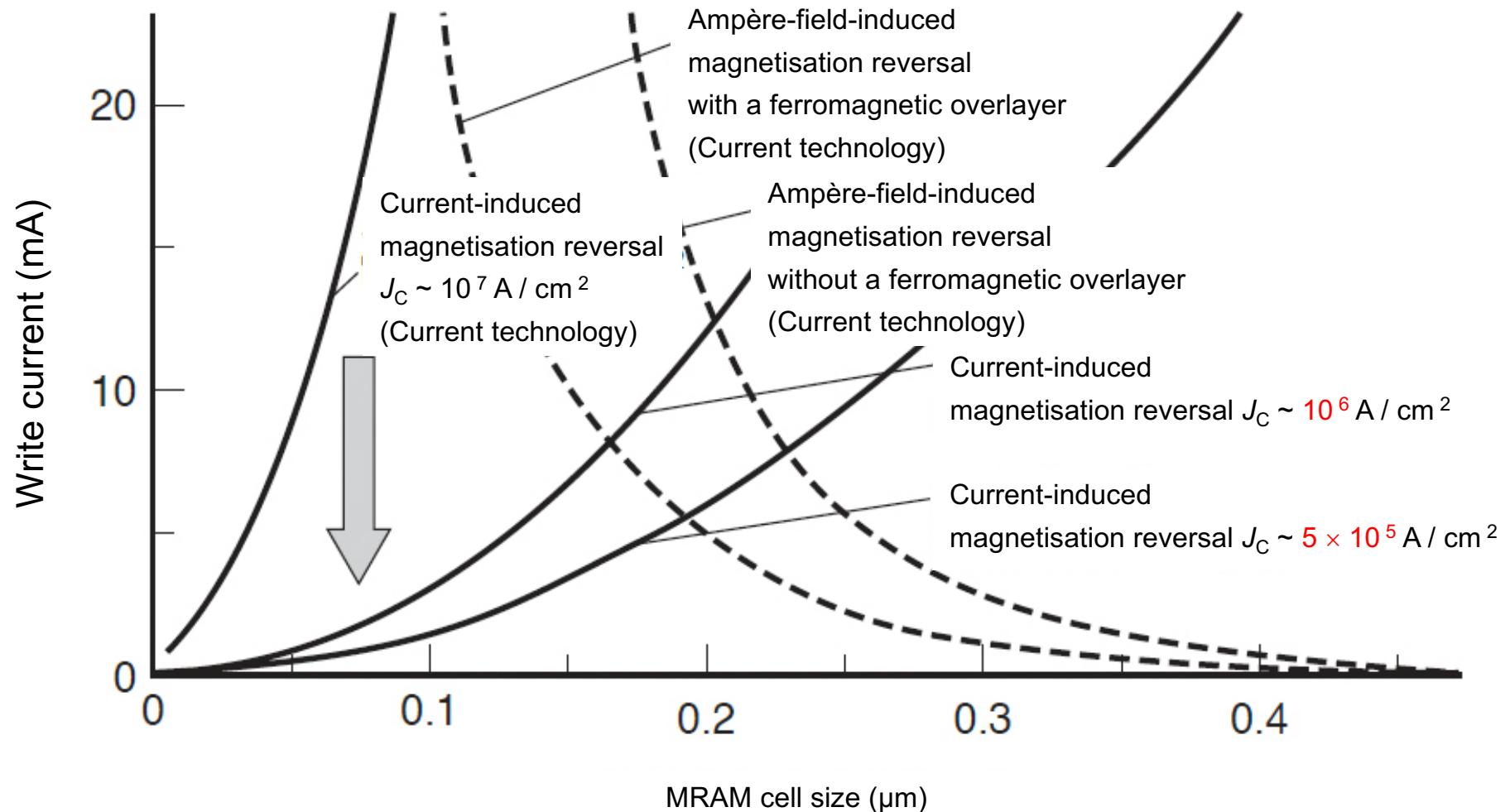
Parallel → Antiparallel





Improved MRAM Operation (Spin RAM)

Required writing currents for several techniques dependent upon cell size :





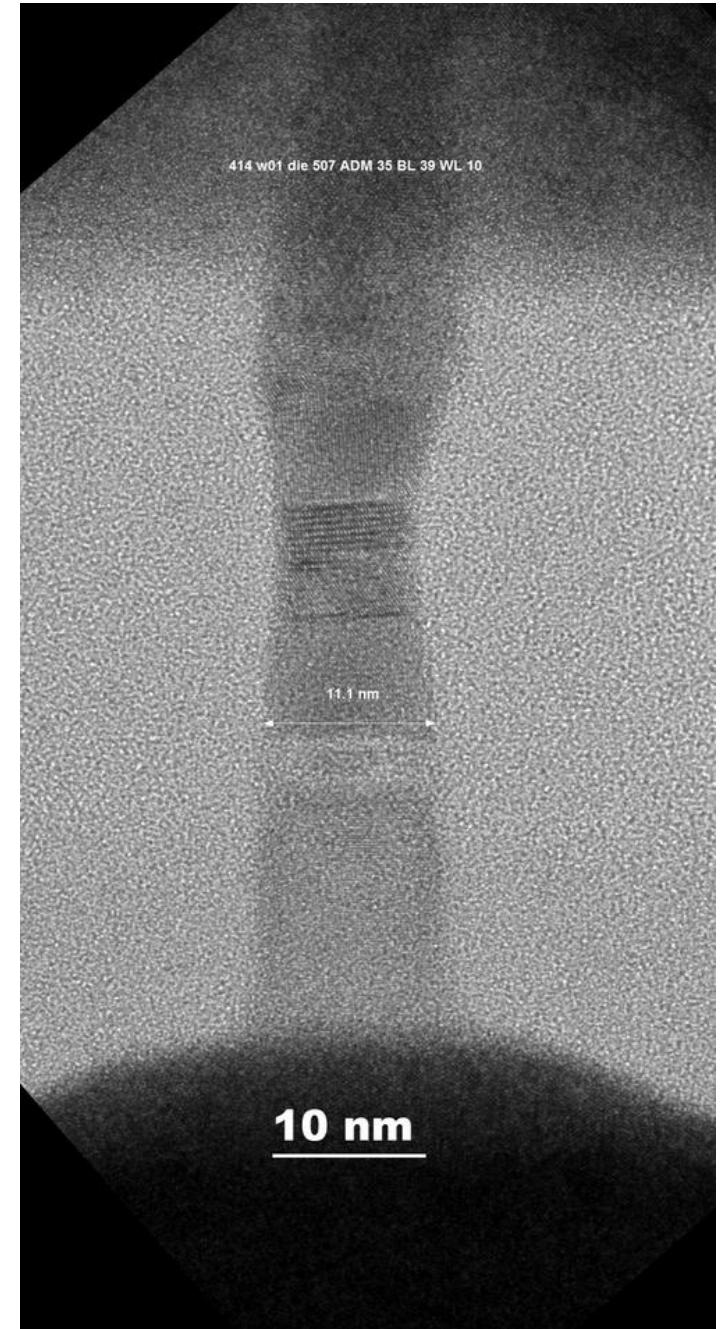
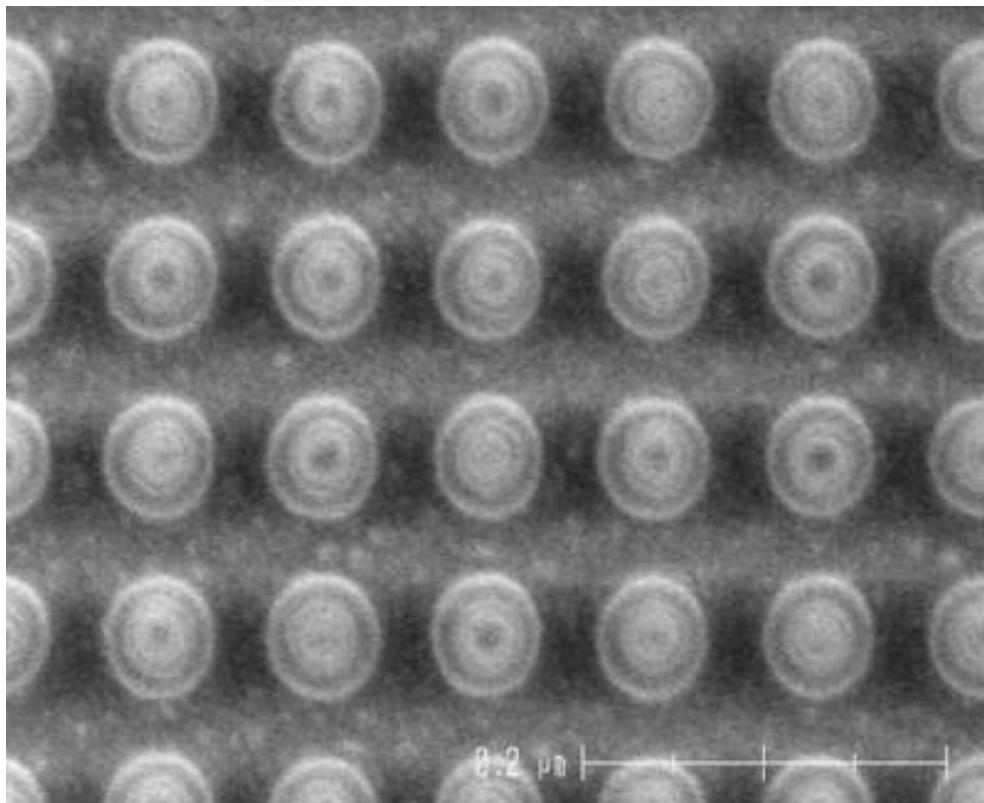
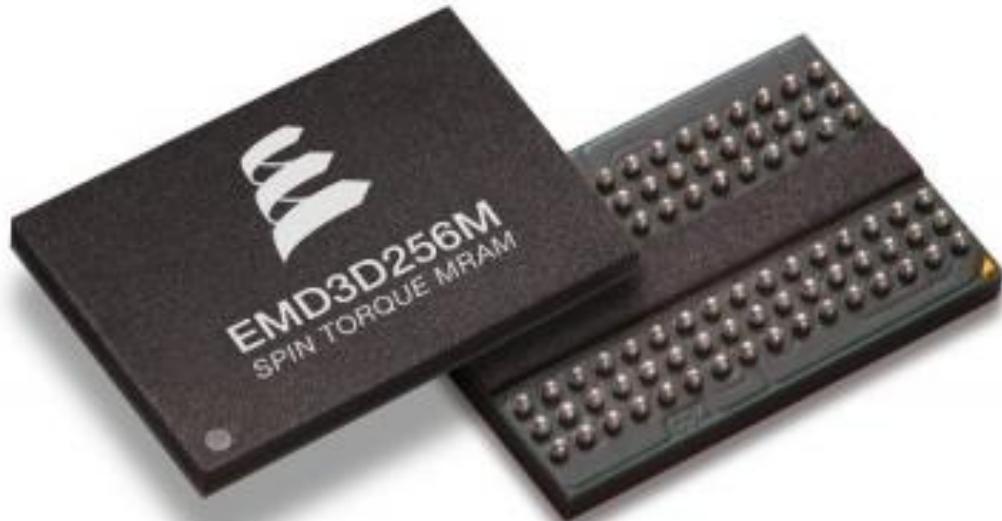
Advantages of MRAM / Spin RAM

	Spin RAM	MRAM	FLASH		DRAM		FeRAM	SRAM
Rules	32 nm	90 nm	32 nm	90 nm	45 nm	90 nm		90 nm
Non-volatility	Y	Y	Y	Y	N	N	Y	N
Read time	~1 ns	300 ns (GMR) <60 ns (TMR)	10–50 ns	10–50 ns	10 ns	10 ns	100–200 ns	1.1 ns
Write time	~1 ns	<10 ns	0.1–100 ms	0.1–100 ms	10 ns	10 ns	~100 ns	1.1 ns
Repetition	>10 ¹⁵	>10 ¹⁵	>10 ⁶	>10 ⁶	>10 ¹⁵	>10 ¹⁵	10 ⁹ –10 ¹²	>10 ¹⁵
Cell size	0.01 μm^2 5 Gb cm ⁻² *	0.25 μm^2 256 Mb cm ⁻²	0.02 μm^2 2.5 Gb cm ⁻² *	0.1 μm^2 512 Mb cm ⁻²		0.25 μm^2 256 Mb cm ⁻²		1–1.3 μm^2 64 Mb cm ⁻²
Cell density	6 F ²	27 F ²		4 F ²	6 F ²	8 F ²	8 F ²	92 F ²
Chip capacity		>1 Gb		>1 Gb			<10 Mb	
Program energy per bit		120 pJ	10 nJ	30–120 nJ		5 pJ + refresh		5 pJ
Soft error hardness		Y		Y	Y	Y	Y	N
Process cost		RT process		Lower bit cost			HT process	

Note: * represents target values.



Latest Spin RAM

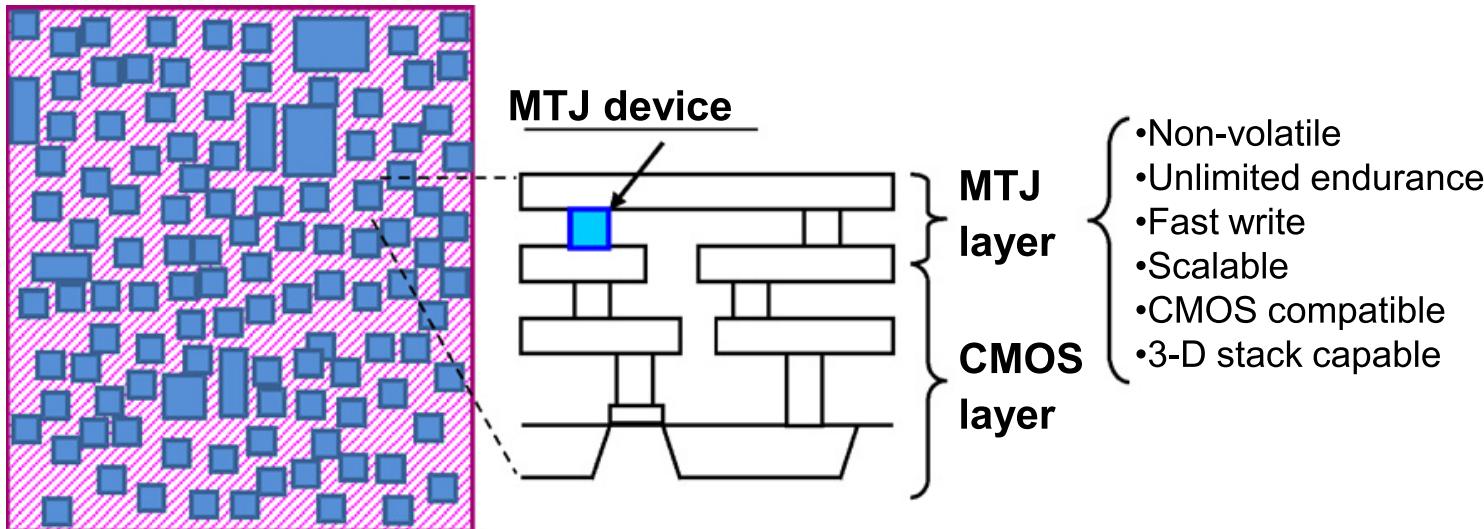


* News from EverSpin, IBM and Toshiba.

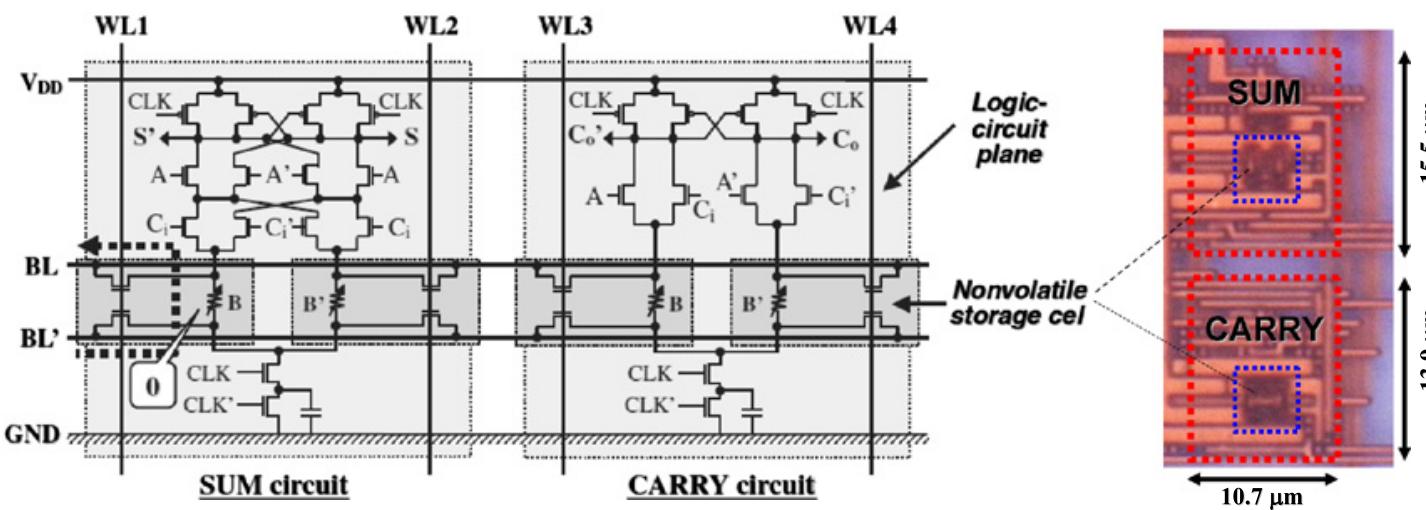


MRAM / Spin RAM Implementation

As a non-volatile universal memory, MRAM / Spin RAM can replace SRAM :



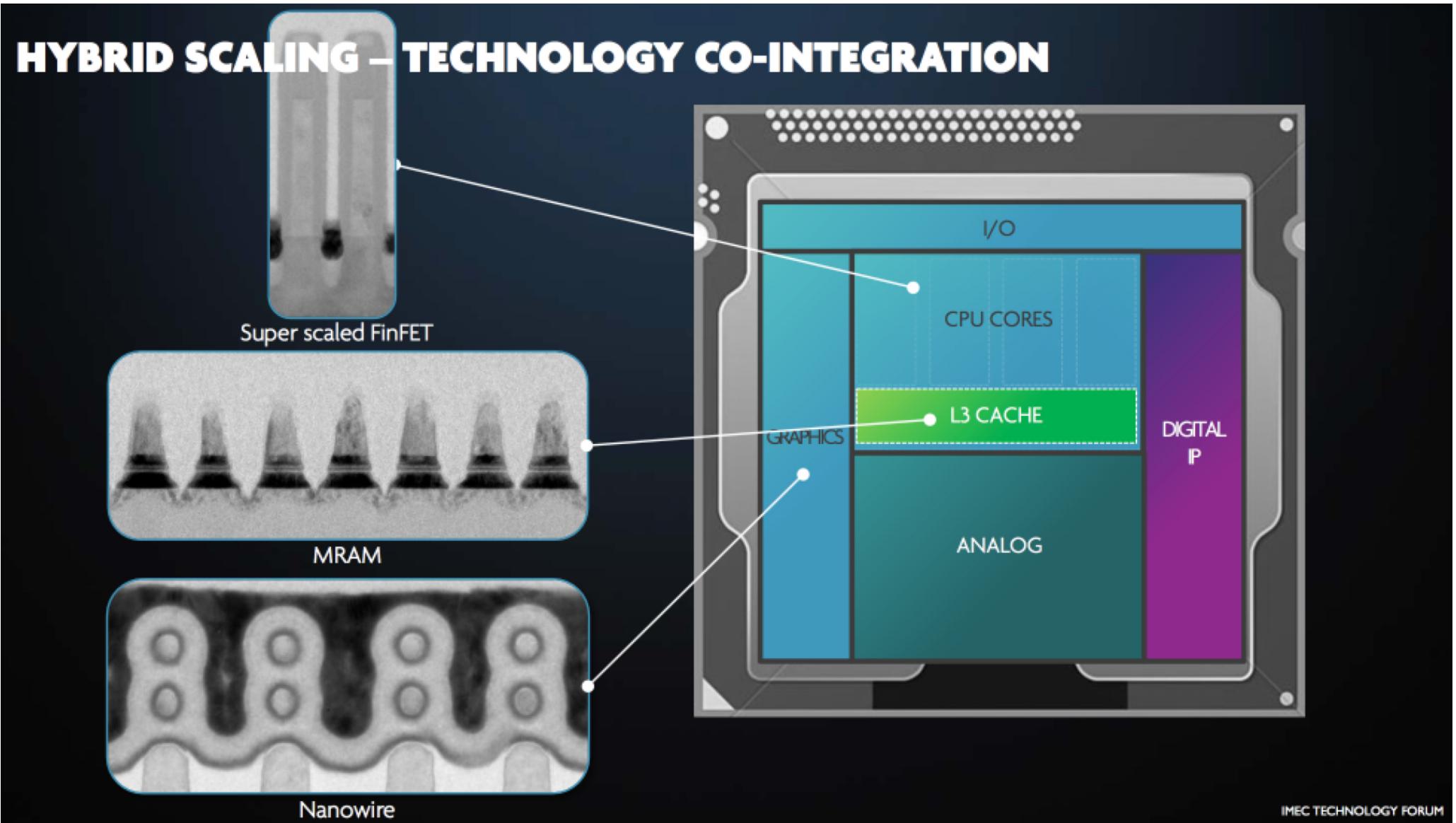
(a) Nonvolatile Logic-in-Memory Architecture



(b) Design example of nonvolatile full adder

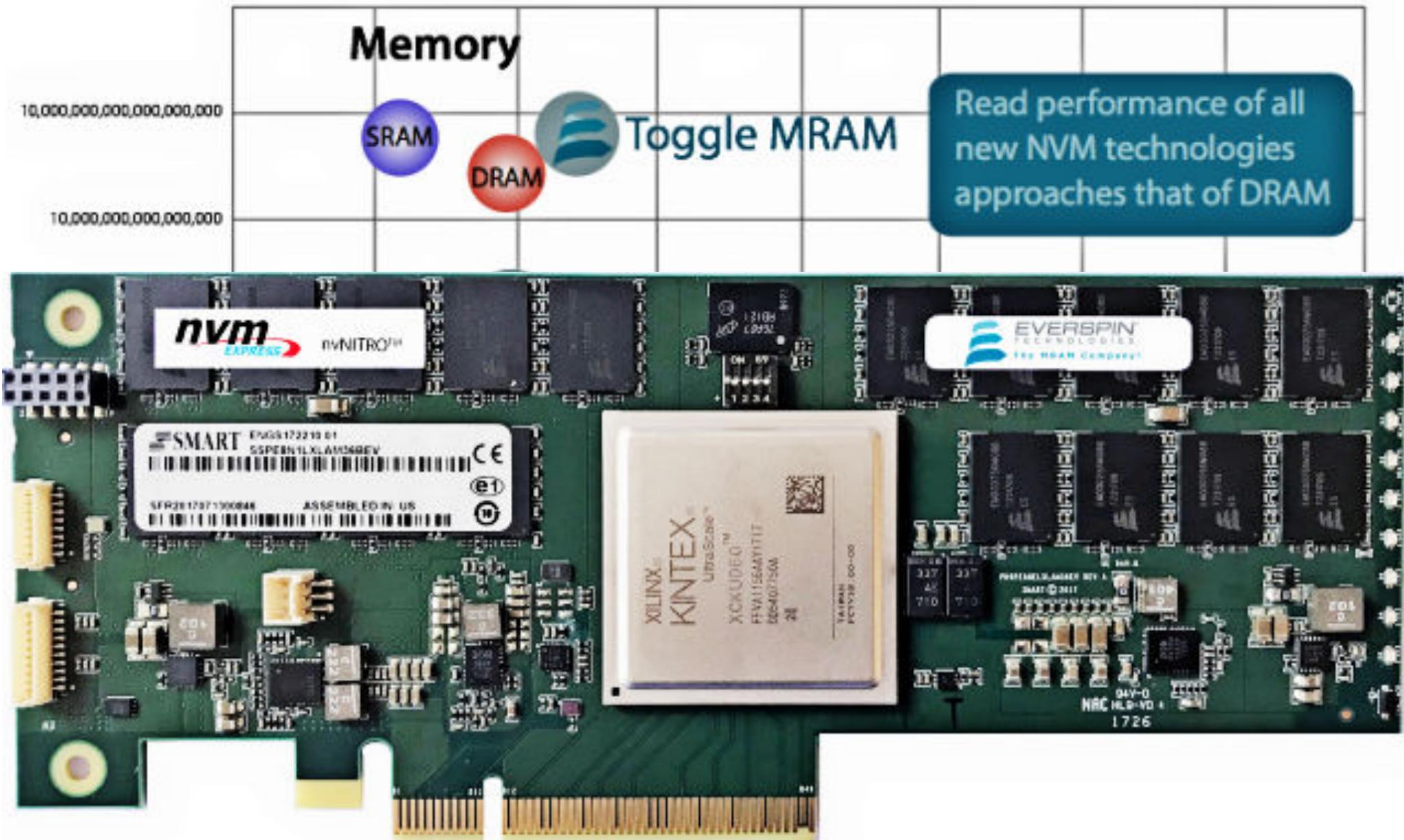


MRAM / Spin RAM and CPU Integration





MRAM for SRAM / DRAM Replacement



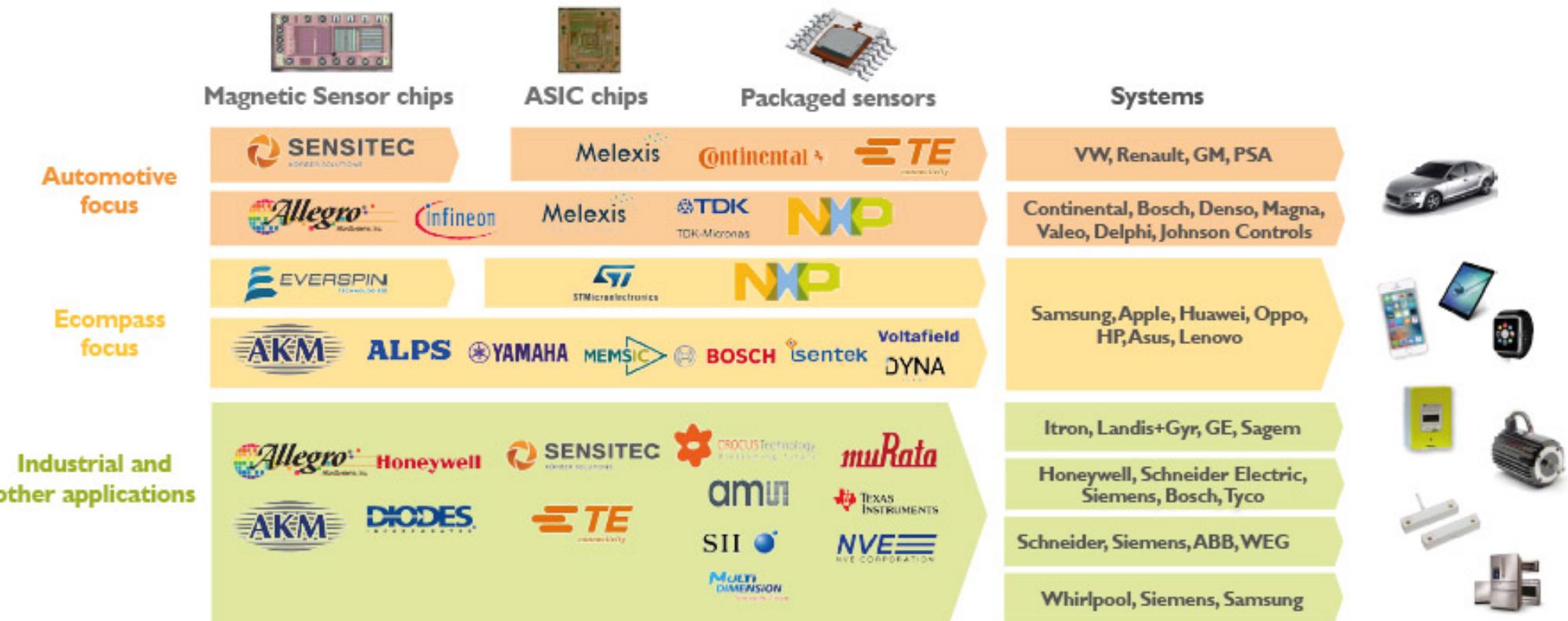
* <https://forums.xilinx.com/t5/Xcell-Daily-Blog/Everspin-s-new-MRAM-based-nvNITRO-NVMe-card-delivers-Optane/ba-p/785194>



MRAM Manufacturers

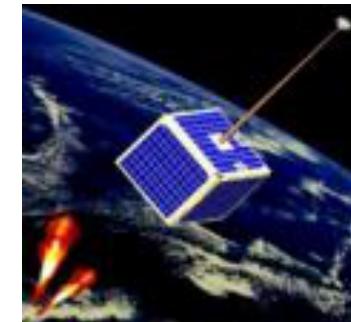
Magnetic sensor supply chain and key players*

(Source: Magnetic Sensor Market and Technologies 2017 report, Yole Développement, November 2017)



*Non-exhaustive list of the magnetic sensor supply chain and its key players

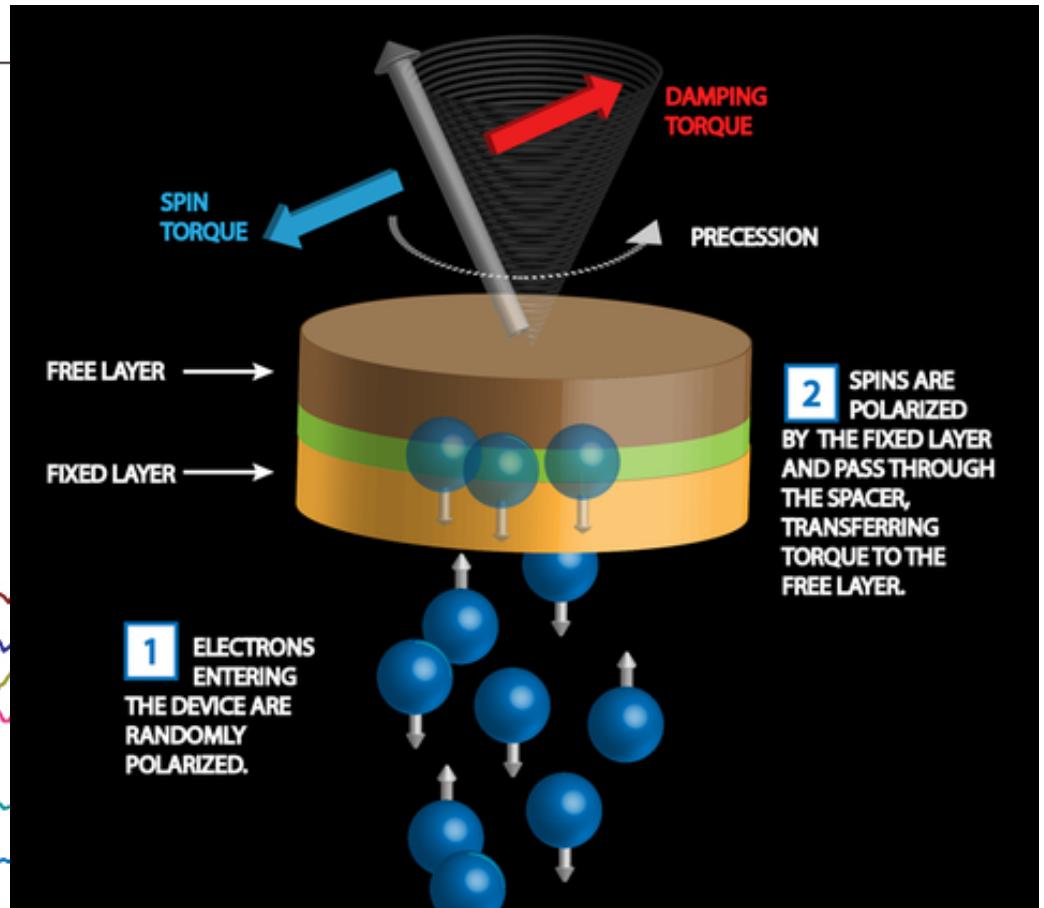
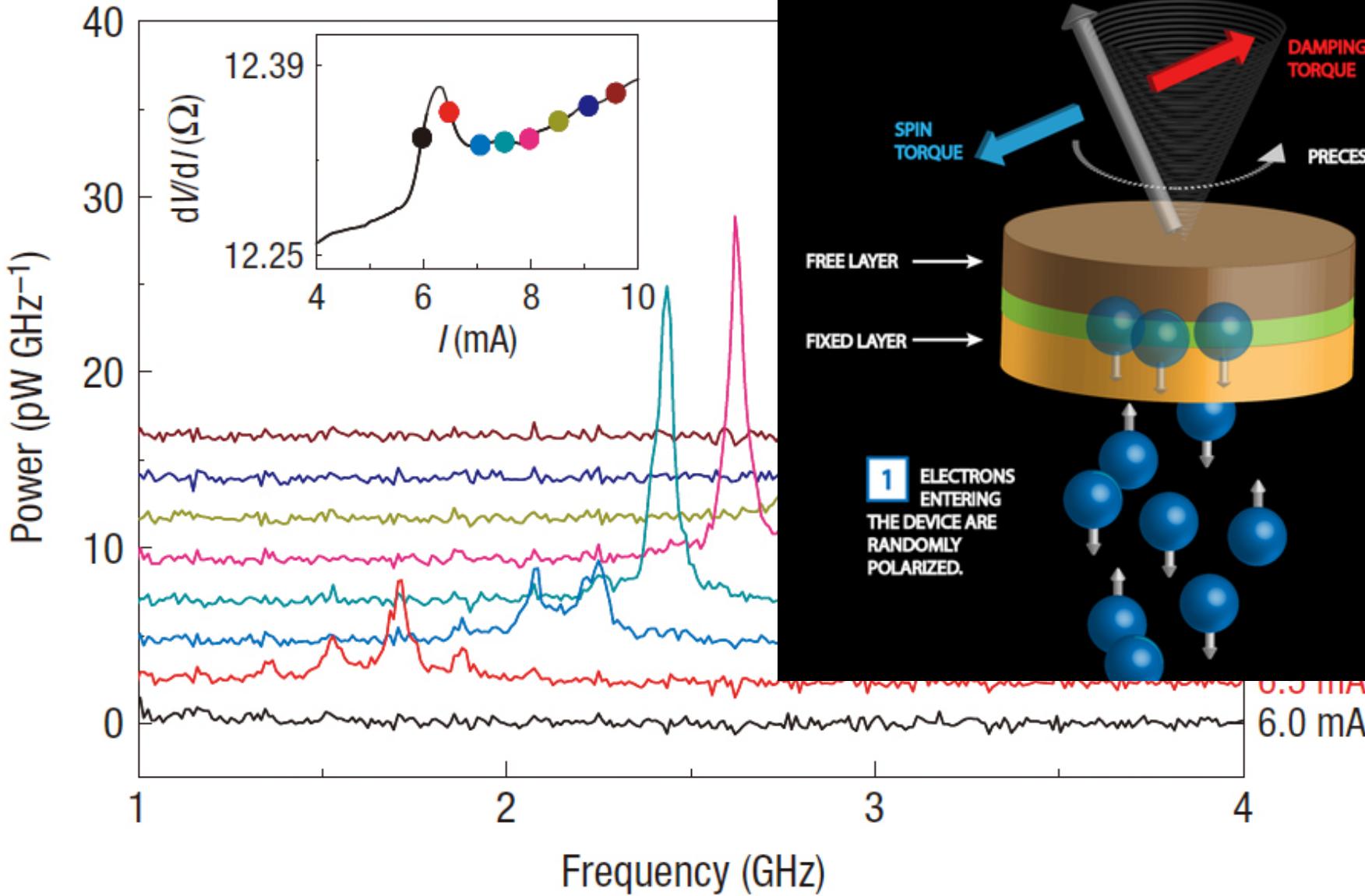
MRAM Applications





Spin Torque Oscillator

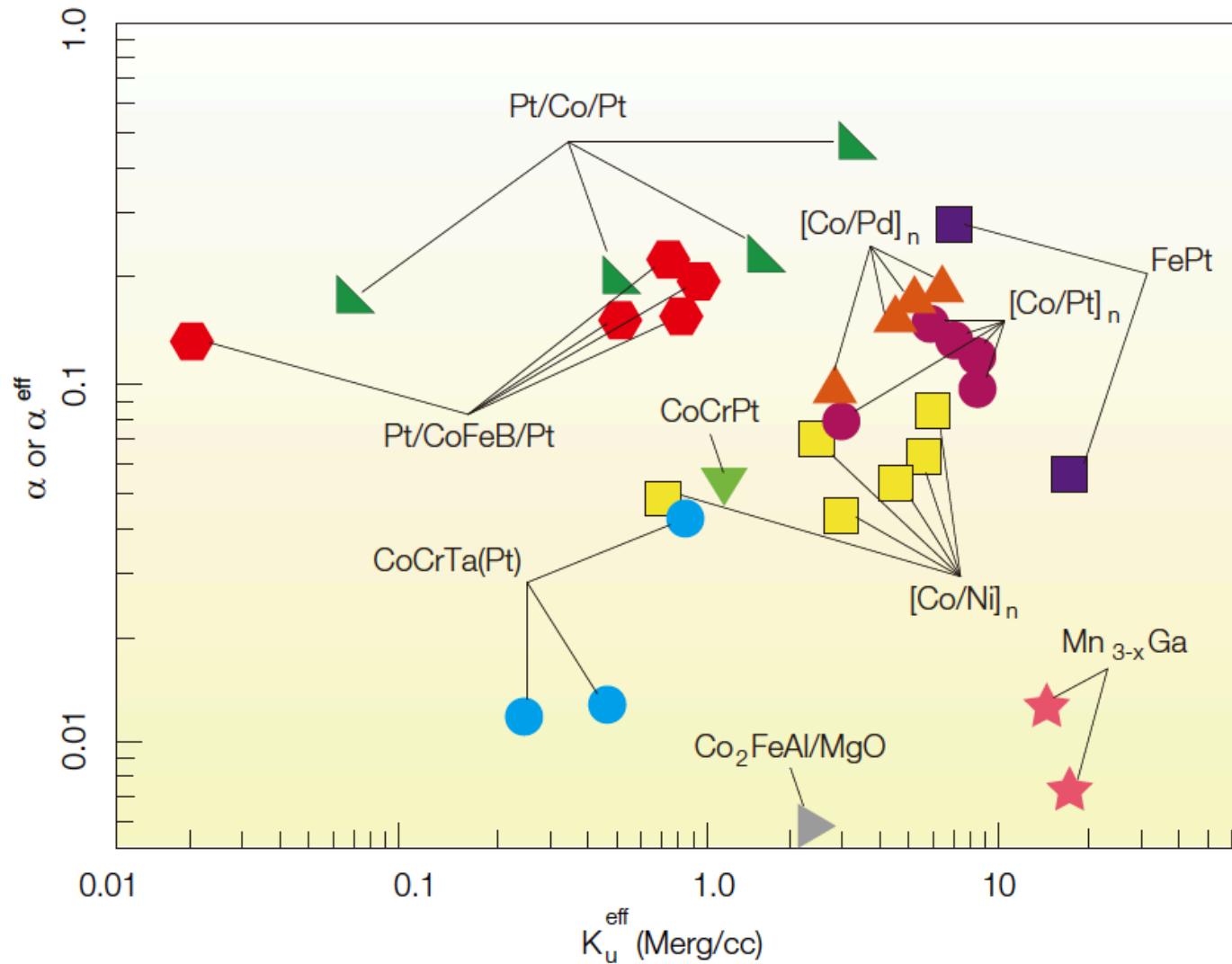
Magnetisation oscillates by spin-transfer torque : *



* O. Boulle *et al.*, *Nature Phys.* **3**, 492 (2007);

** <https://www.nist.gov/news-events/news/2013/04/unprecedented-view-spintronic-switching>.

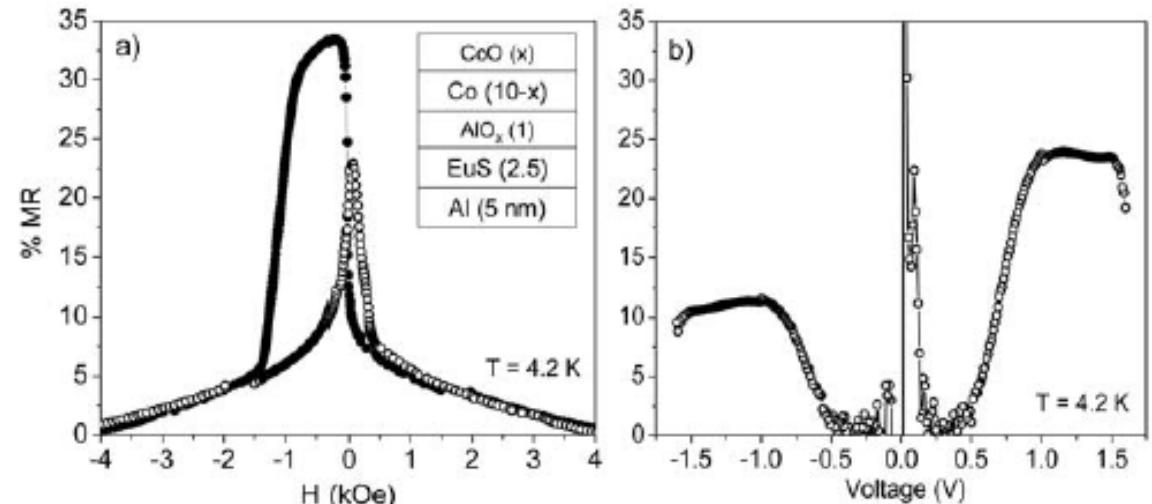
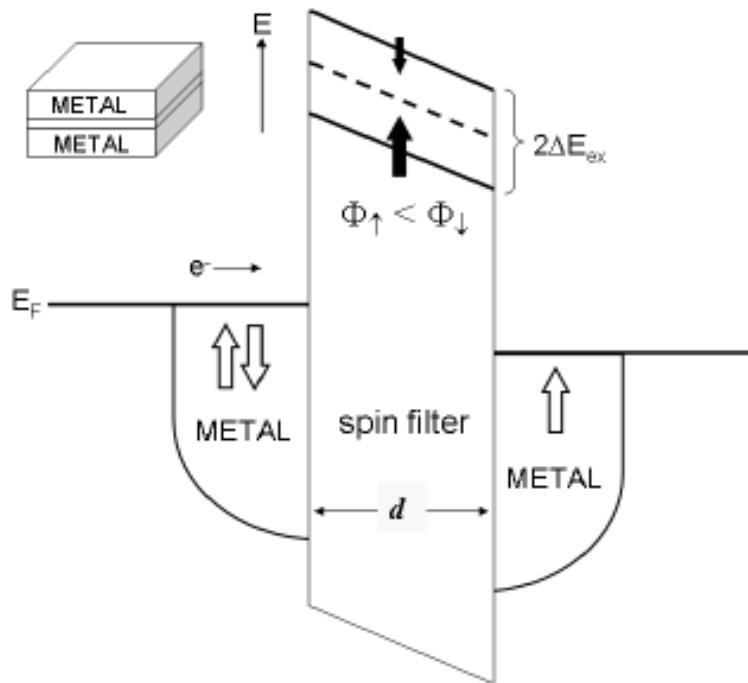
Damping Constants



Spin Filtering



Band splitting in a tunnel barrier can filter only one spin orientation :



Material	Magnetic Behavior	T _c (K)	Moment (μ_B)	Structure, a(nm)	E _g (eV)	2ΔE _{ex} (eV)	P (%)	Spin Filter Reference
EuO	FM	69.3	7.0	Fcc, 0.514	1.12	0.54	29	Santos ²³
EuS	FM	16.6	7.0	Fcc, 0.596	1.65	0.36	86	Moodera ²¹
EuSe	AFM	4.6	7.0	Fcc, 0.619	1.80		100	Moodera ²²
BiMnO ₃	FM	105	3.6	perovskite			22	Gajek ²⁶
NiFe ₂ O ₄	ferri-M	850	2	spinel	1.2		22	Lüders ²⁷
CoFe ₂ O ₄	ferri-M	796	3	spinel	0.80		25	Ramos ²⁸

* J. S. Moodera *et al.*, *Epitaxial Ferromagnetic Films and Spintronic Applications*, A. Hirohata and Y. Otani (Eds.) (Research Signpost, Kerala, 2009) p. 111-143.



Rebranding ...

REVIEW

Spintronics: A Spin-Based Electronics Vision for the Future

S. A. Wolf,^{1,2*} D. D. Awschalom,³ R. A. Buhrman,⁴ J. M. Daughton,⁵ S. von Molnár,⁶ M. L. Roukes,⁷ A. Y. Chtchelkanova,⁸ D. M. Treger⁸

This review describes a new paradigm of electronics based on the spin degree of freedom of the electron. Either adding the spin degree of freedom to conventional charge-based electronic devices or using the spin alone has the potential advantages of nonvolatility, increased data processing speed, decreased electric power consumption, and increased integration densities compared with conventional semiconductor devices. To successfully incorporate spins into existing semiconductor technology, one has to resolve technical issues such as efficient injection, transport, control and manipulation, and detection of spin polarization as well as spin-polarized currents. Recent advances in new materials engineering hold the promise of realizing spintronic devices in the near future. We review the current state of the spin-based devices, efforts in new materials fabrication, issues in spin transport, and optical spin manipulation.

Until recently, the spin of the electron was ignored in mainstream charge-based electronics. A technology has emerged called spintronics (spin transport electronics or spin-based electronics), where it is not the electron charge but the electron spin that carries information, and this offers opportunities for a

new generation of devices combining standard microelectronics with spin-dependent effects that arise from the interaction between spin of the carrier and the magnetic properties of the material.

Traditional approaches to using spin are based on the alignment of a spin (either "up" or "down") relative to a reference (an applied magnetic field or magnetization orientation of the ferromagnetic film). Device operations then proceed with some quantity (electrical current) that depends in a predictable way on the degree of alignment. Adding the spin degree of freedom to conventional semiconductor charge-based electronics or using the spin degree of freedom alone will add substantially more capability and performance to electronic products. The advantages of these new devices would be nonvolatility, increased data processing speed, decreased electric power consumption, and increased integration densities

compared with conventional semiconductor devices.

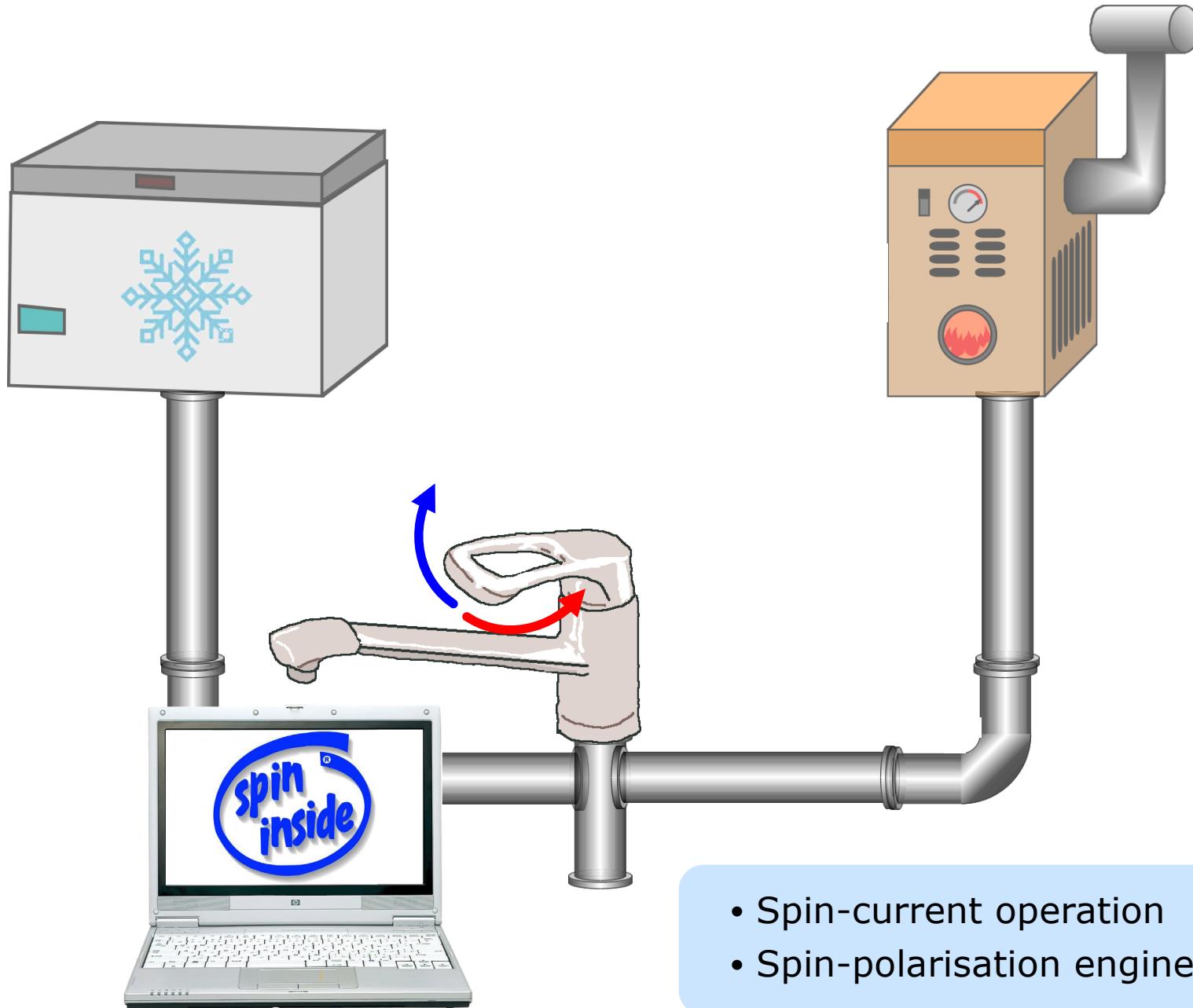
Major challenges in this field of spintronics that are addressed by experiment and theory include the optimization of electron spin lifetimes, the detection of spin coherence in nanoscale structures, transport of spin-polarized carriers across relevant length scales and heterointerfaces, and the manipulation of both electron and nuclear spins on sufficiently fast time scales. In response, recent experiments suggest that the storage time of quantum information encoded in electron spins may be extended through their strong interplay with nuclear spins in the solid state. Moreover, optical methods for spin injection, detection, and manipulation have been developed that exploit the ability to precisely engineer the coupling between electron spin and optical photons. It is envisioned that the merging of electronics, photonics, and magnetics will ultimately lead to new spin-based multifunctional devices such as spin-FET (field effect transistor), spin-LED (light-emitting diode), spin RTD (resonant tunneling device), optical switches operating at terahertz frequency, modulators, encoders, decoders, and quantum bits for quantum computation and communication. The success of these ventures depends on a deeper understanding of fundamental spin interactions in solid state materials as well as the roles of dimensionality, defects, and semiconductor band structure in modifying these dynamics. If we can understand and control the spin

¹Defense Advanced Research Projects Agency (DARPA), 3701 North Fairfax Drive, Arlington, VA 22203, USA. ²Naval Research Laboratory, Washington, DC 20375, USA. ³University of California, Department of Physics, Santa Barbara, CA 93106, USA. ⁴Cornell University, Applied and Engineering Physics, 211 Clark Hall, Ithaca, NY 14853, USA. ⁵NVE, 11409 Valley View Road, Eden Prairie, MN 55344, USA. ⁶Florida State University, MARTECH, 406 Keen Building, Tallahassee, FL 32306, USA. ⁷California Institute of Technology, Department of Physics, MS-114-36, Pasadena, CA 91125, USA. ⁸Strategic Analysis, 3601 Wilson Boulevard, Suite 500, Arlington, VA 22201, USA.

*To whom correspondence should be addressed. E-mail: swolf@darpa.mil



Next-Generation Spintronic Applications



- Spin-current operation
- Spin-polarisation engineering

Spin injection
from a ferromagnet

Magnetic field
application

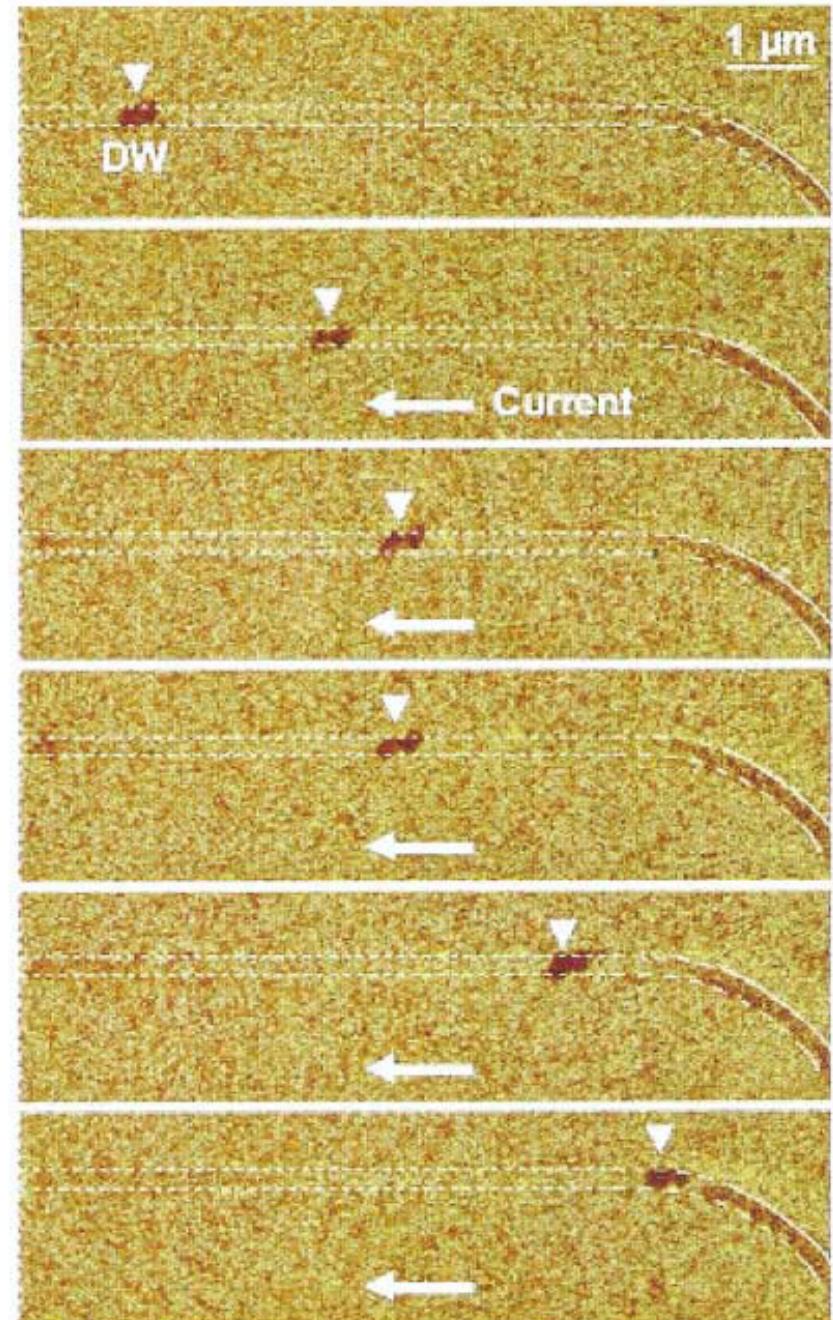
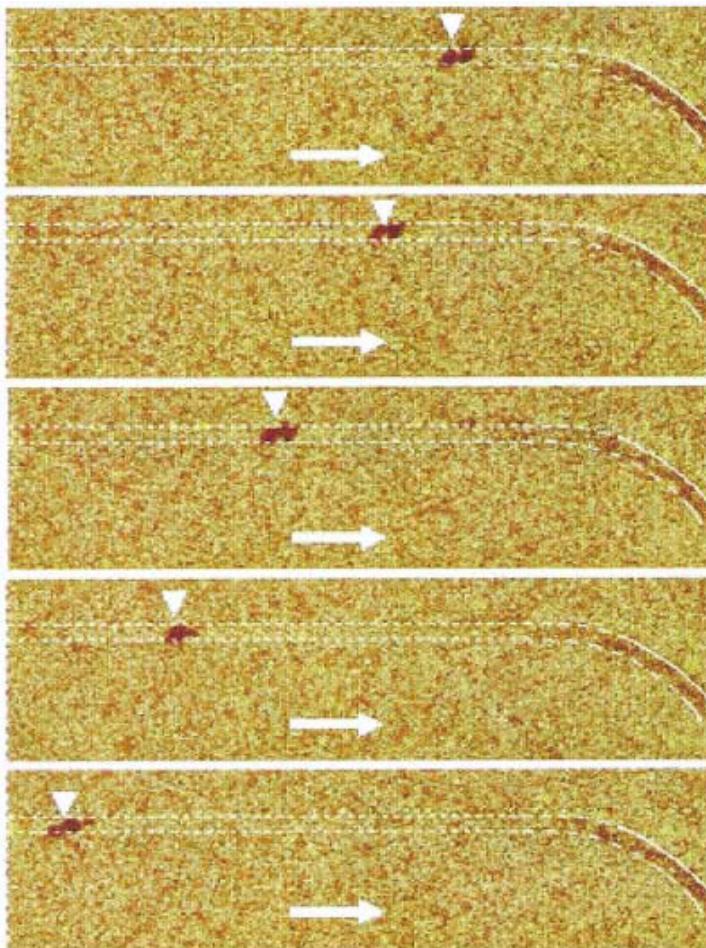


Spins



Domain Wall Displacement

- For fast operation **spin transfer torque (STT)** will be used to move the walls.
- This requires a narrow track, possibly down to 100 nm, so that the STT dominates the Lorentz field.

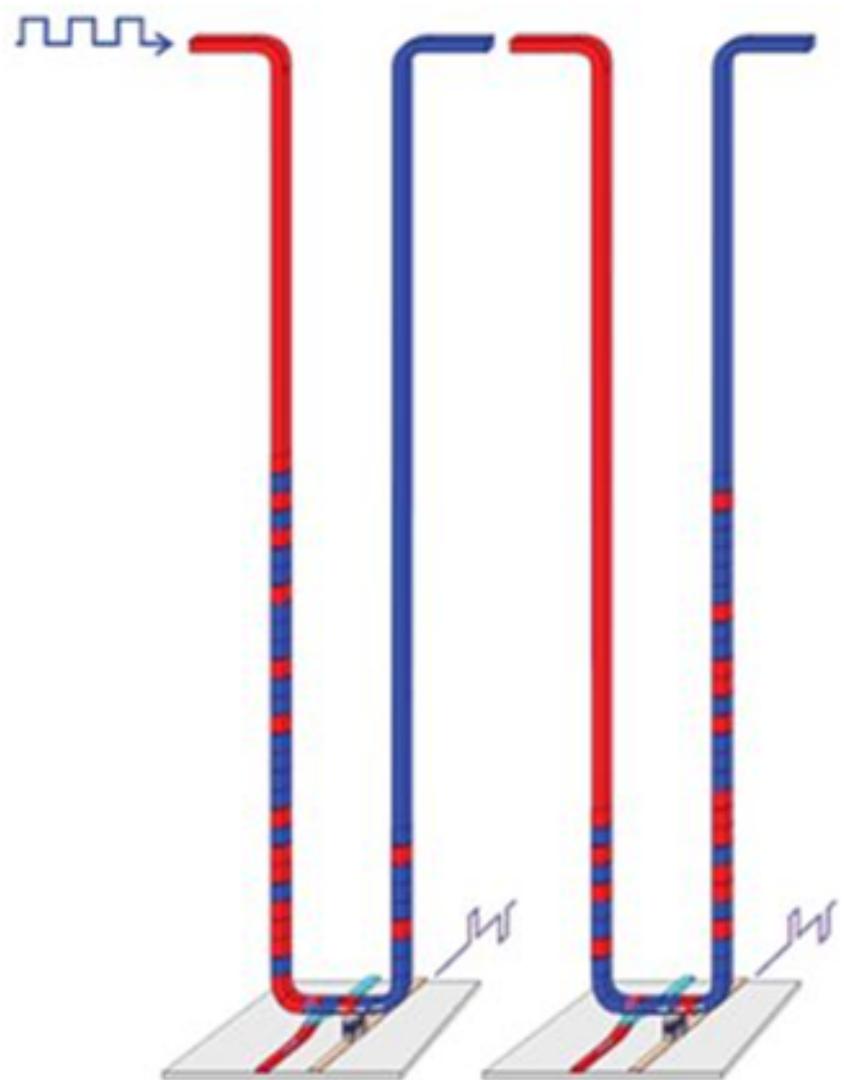


* A. Yamaguchi et al., *Science* **97**, 077205 (2004).



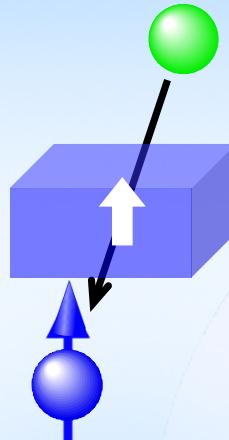
Racetrack memory

- Racetrack memory has been originally proposed by Parkin of IBM.*
- The principle is to use domain walls (DWs) as a **shift register or storage system**.
- This can lead to a new storage architecture.
- Racetrack systems may be cheaper to fabricate than MRAM for low cost storage.
- The vertical orientation is impractical due to the demagnetising effects.

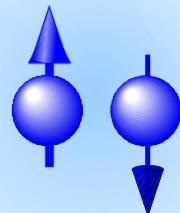


* S. S. P. Parkin *et al.*, *Science* **320**, 190 (2008).

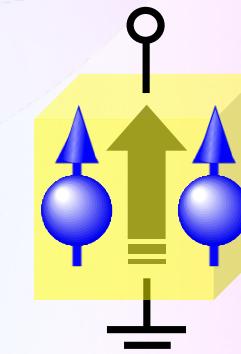
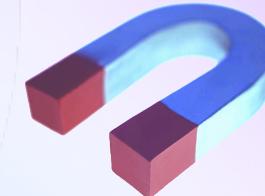
Spin injection
from a ferromagnet



Spins



Magnetic field
application

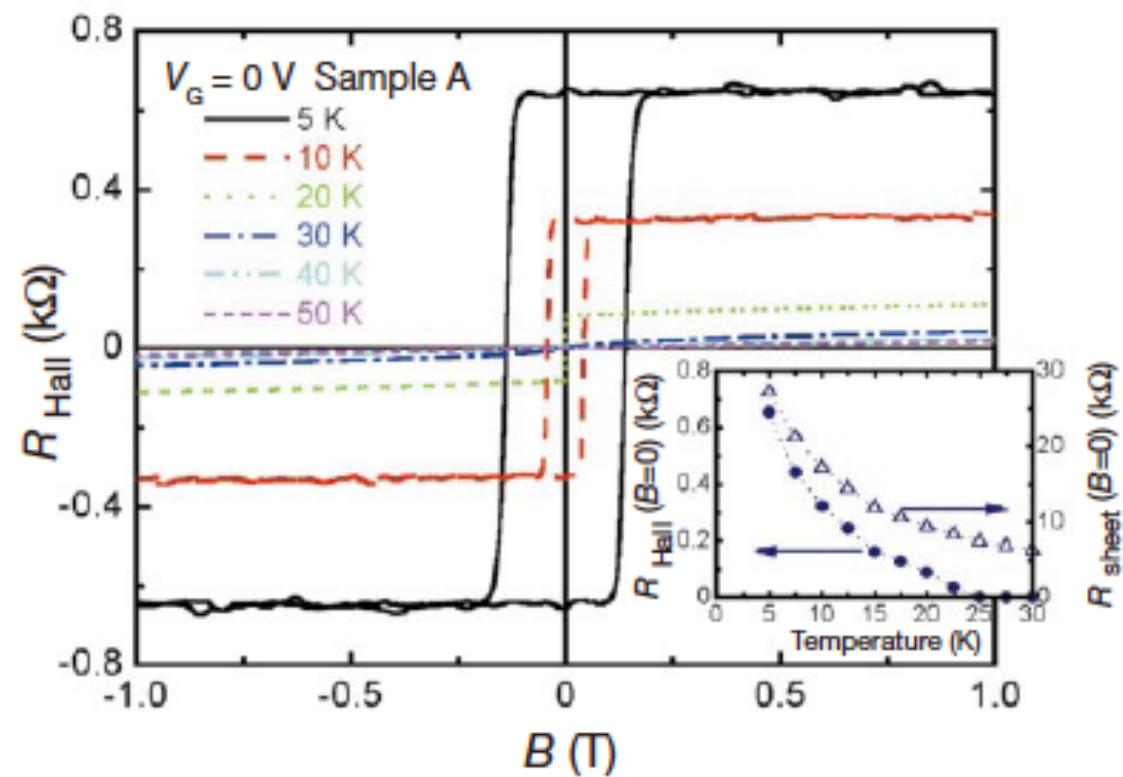
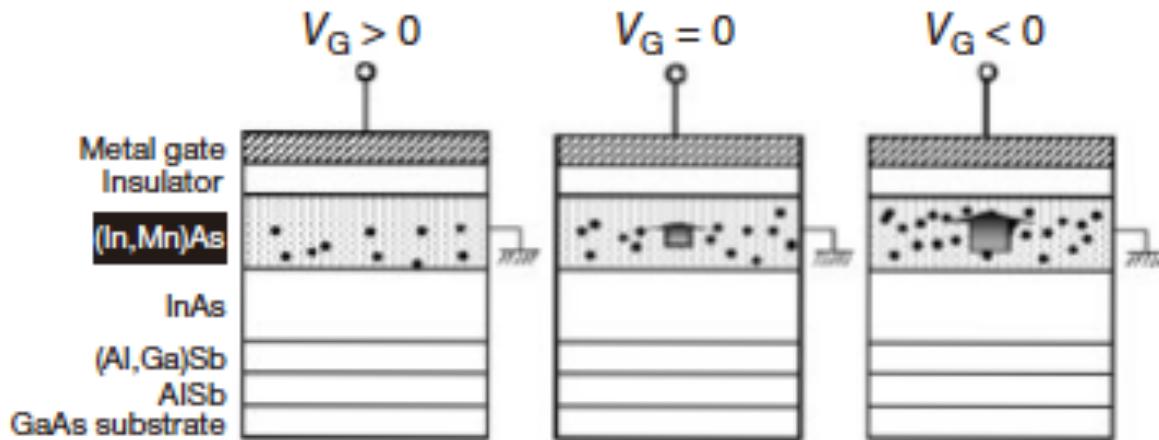


Electric field
application



Electric Field Control of Magnetism - Semiconductors

Dilute magnetic semiconductor (GaMnAs) : *

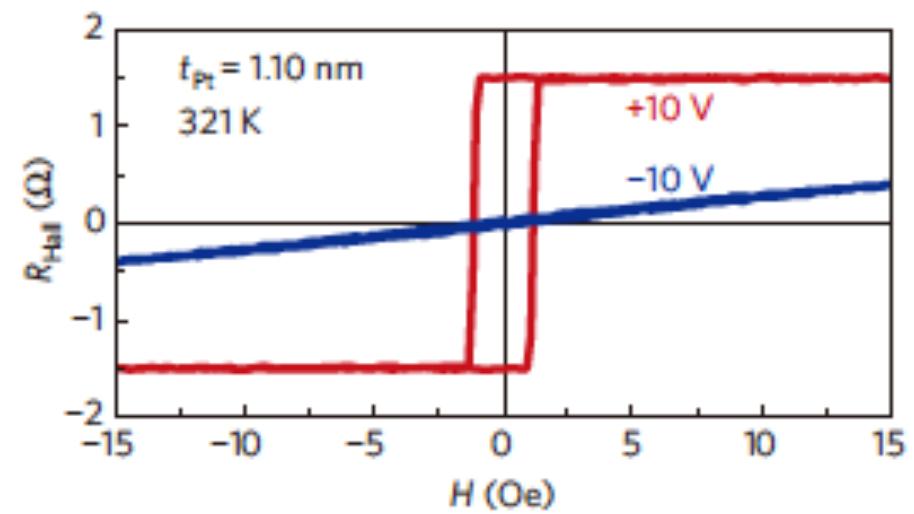
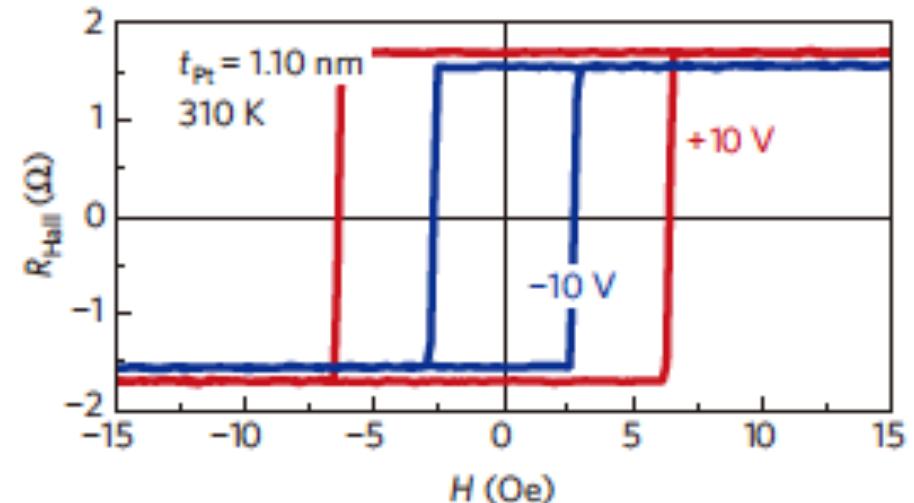
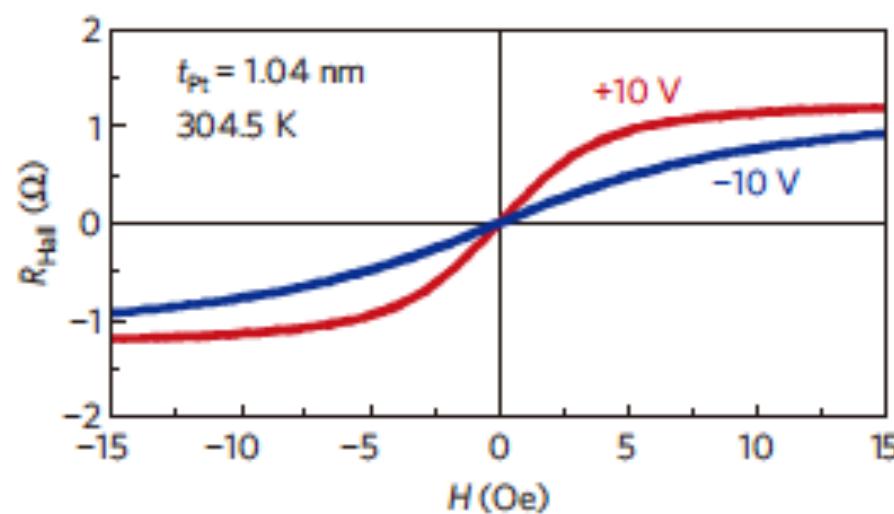
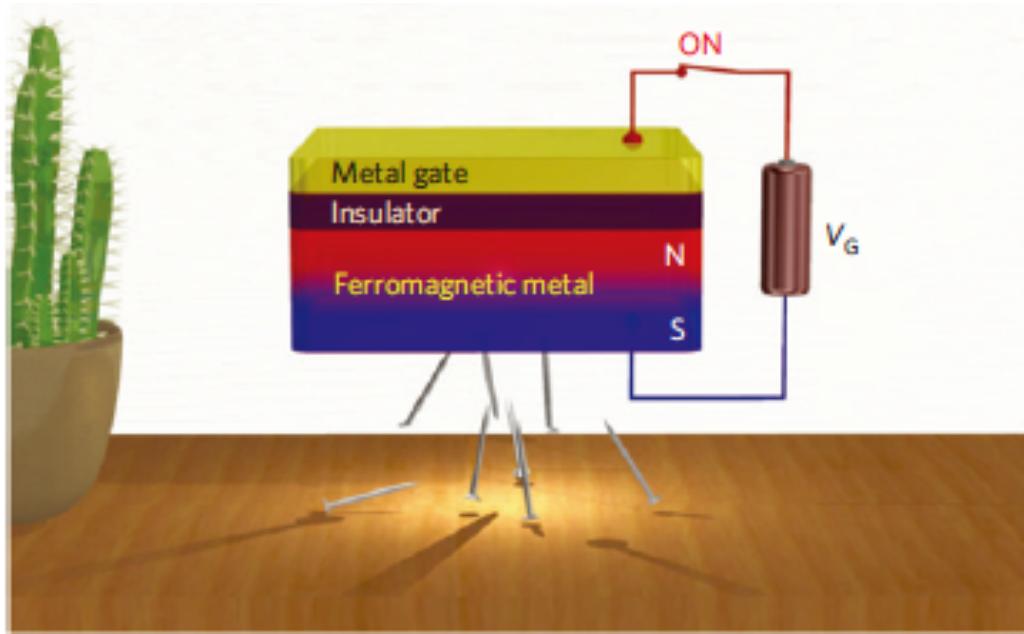


* H. Ohno et al., *Nature* **408**, 944 (2000).



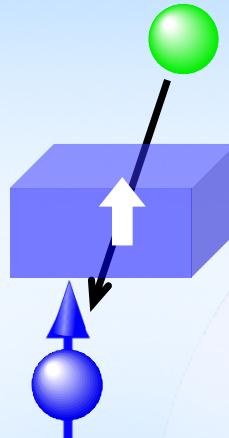
Electric Field Control of Magnetism - Metals

Ferromagnetic metal (Co) : *

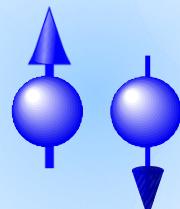


* D. Chiba *et al.*, *Nature Mater.* **10**, 853 (2011).

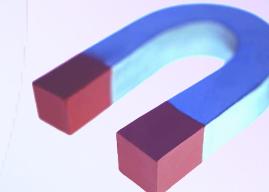
Spin injection
from a ferromagnet



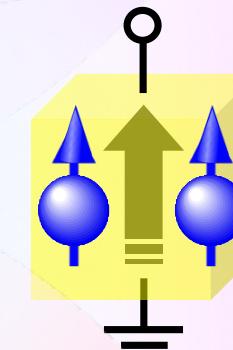
Spins



Magnetic field
application



Electric field
application

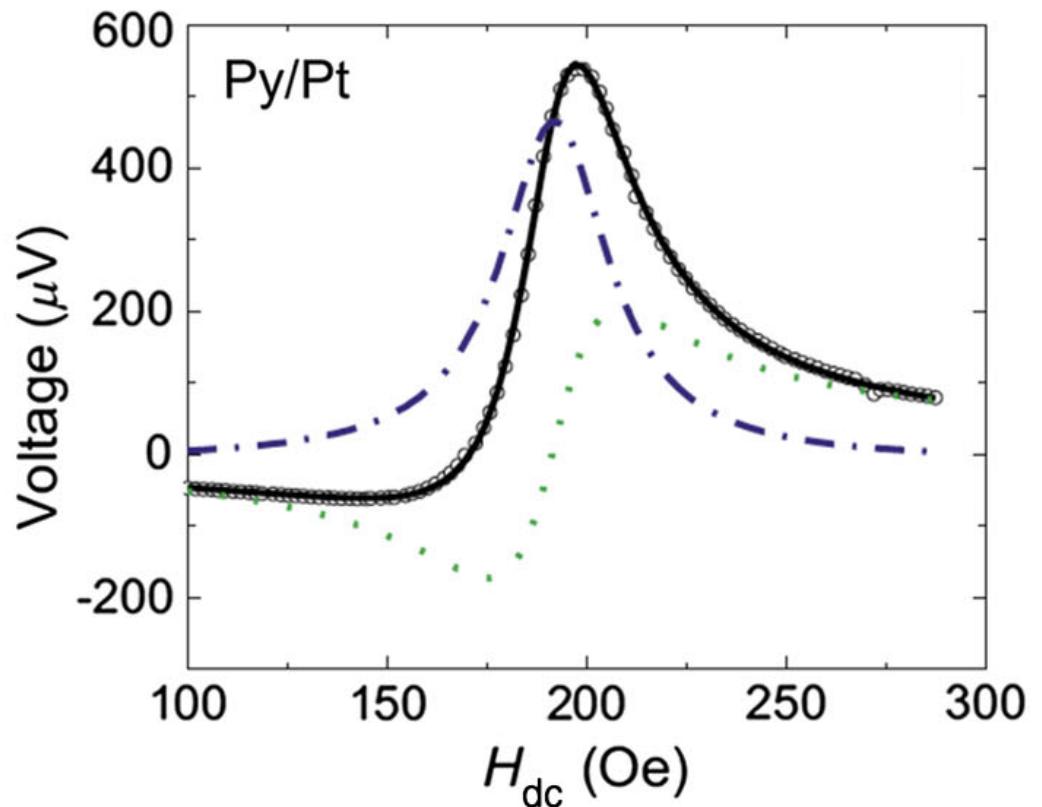
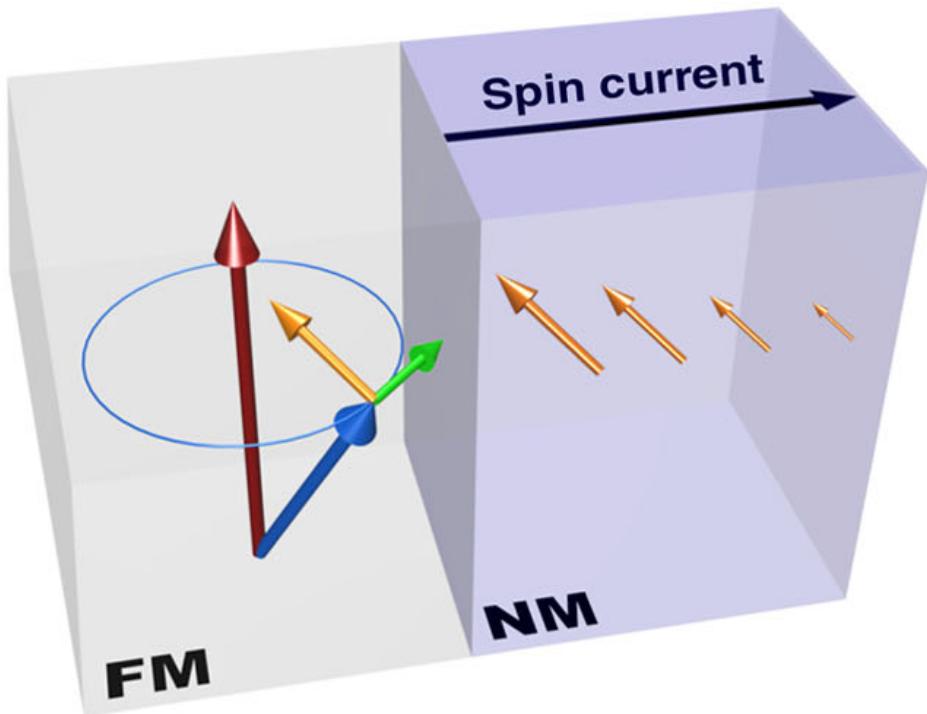


Electromagnetic
wave
introduction



Microwave-Induced Spin Currents

Spin-polarised currents can be introduced by electromagnetic wave : *



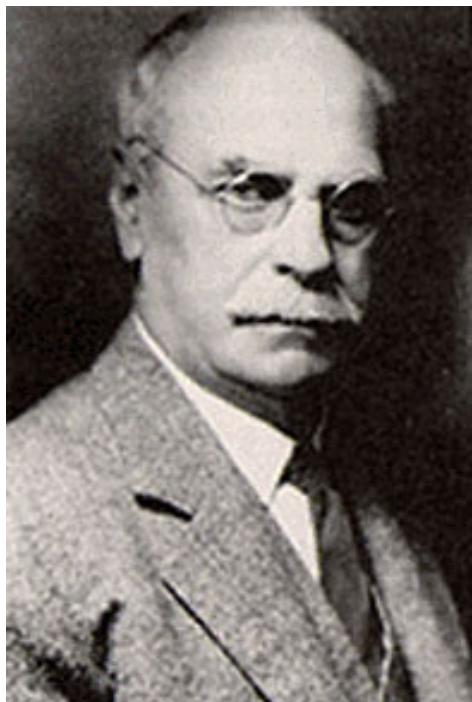
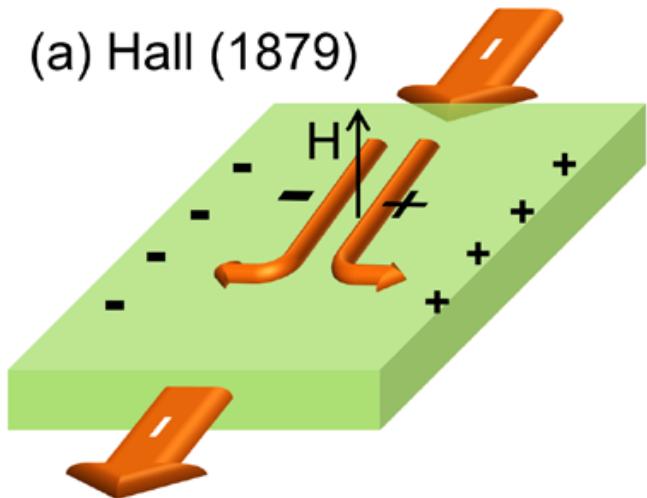
* O. Mosendz *et al.*, *Phys. Rev. B* **82**, 214403 (2010);
A. Hoffmann and S. Bader, *Phys. Rev. Appl.* **4**, 047001 (2015).



Spin Hall Effect

Spin Hall / inverse spin Hall / anomalous spin Hall effects etc. : *

(a) Hall (1879)



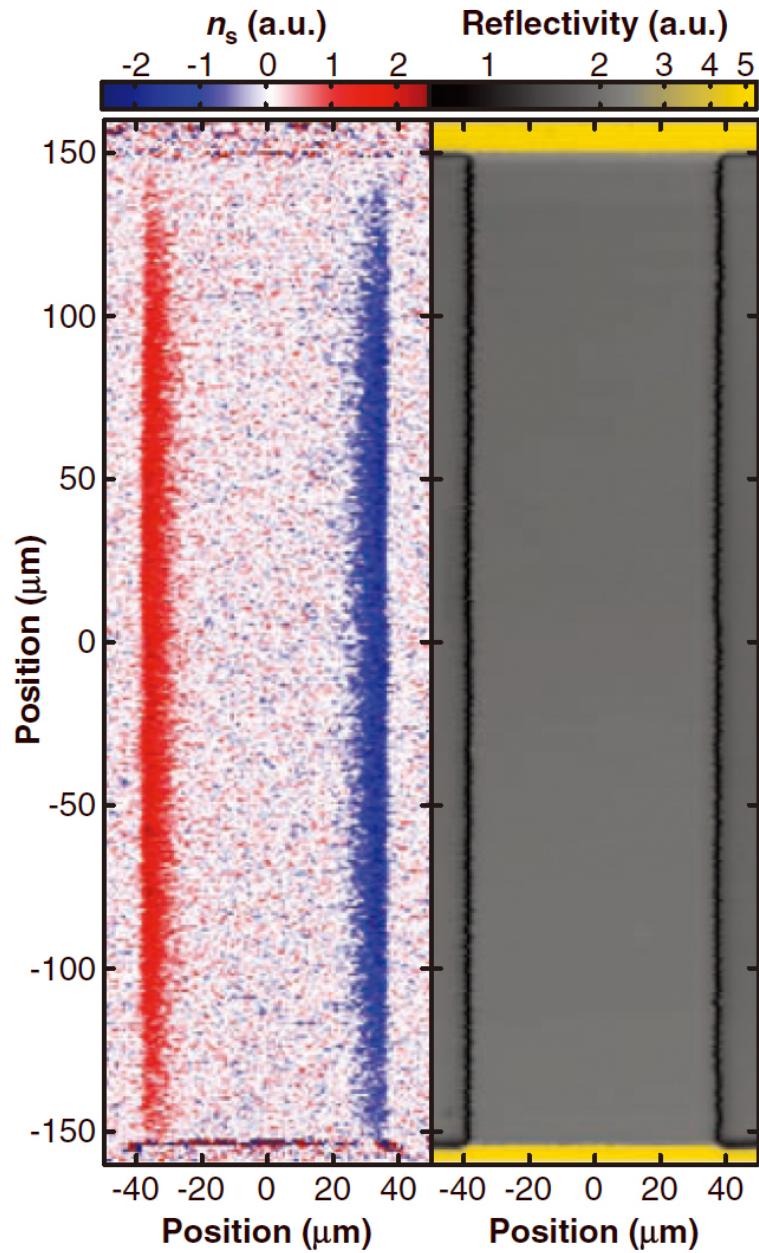
Edwin Herbert Hall
(1855-1938)

* C.-Z. Chang and M. Li, *J. Phys.: Condens. Matter* **28**, 123002 (2016).



Spin Hall Effect in GaAs

MOKE detection of spins generated by the spin Hall effect : *

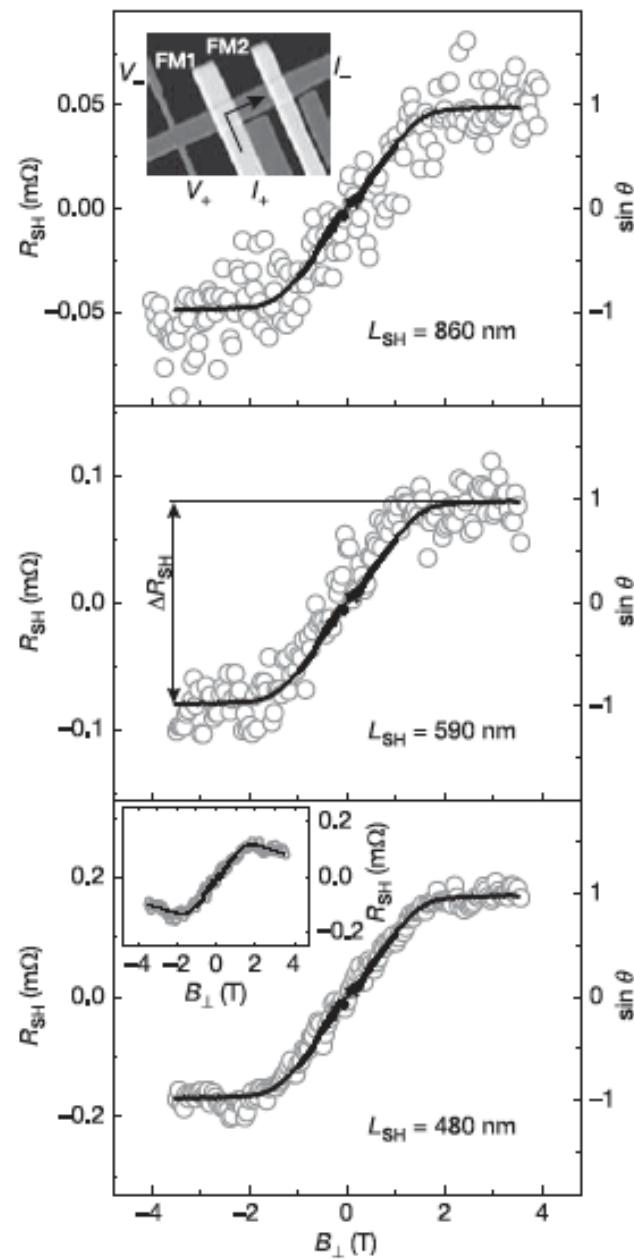
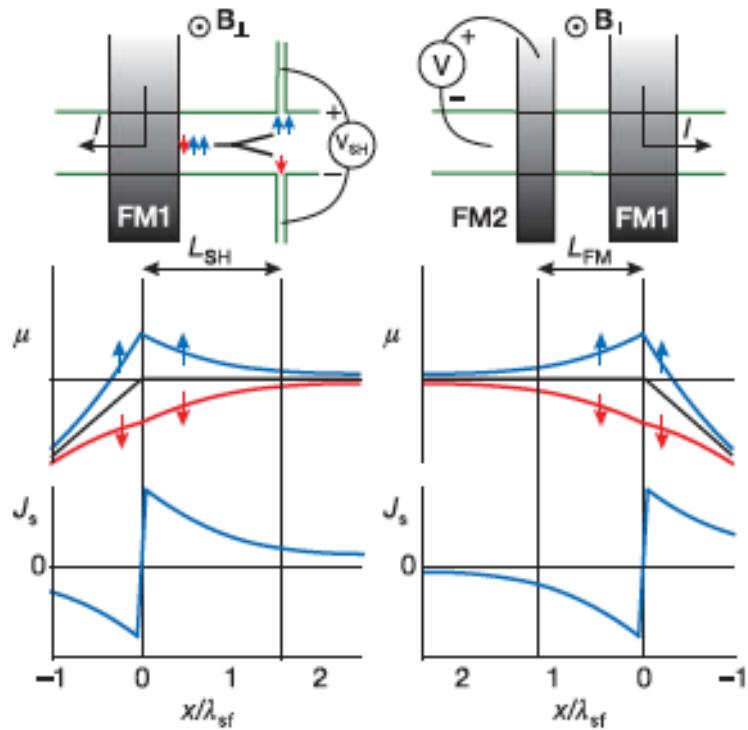
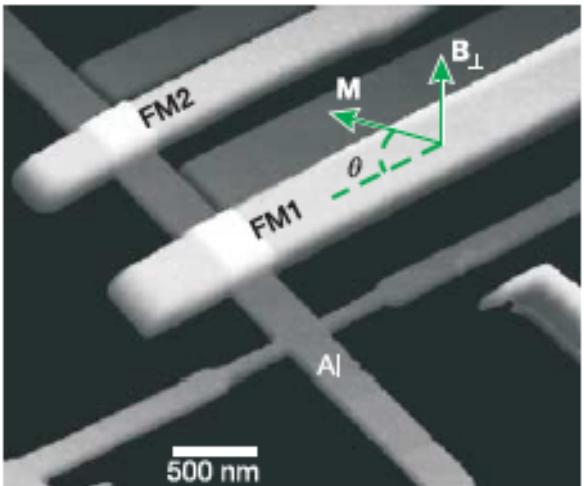


* Y. K. Kato *et al.*, *Science* **306**, 1910 (2004).



Lateral Spin-Valve with the Spin Hall Effect

$\text{Co}_{0.8}\text{Fe}_{0.2}$ / Al_2O_3 / Al nanowires : *

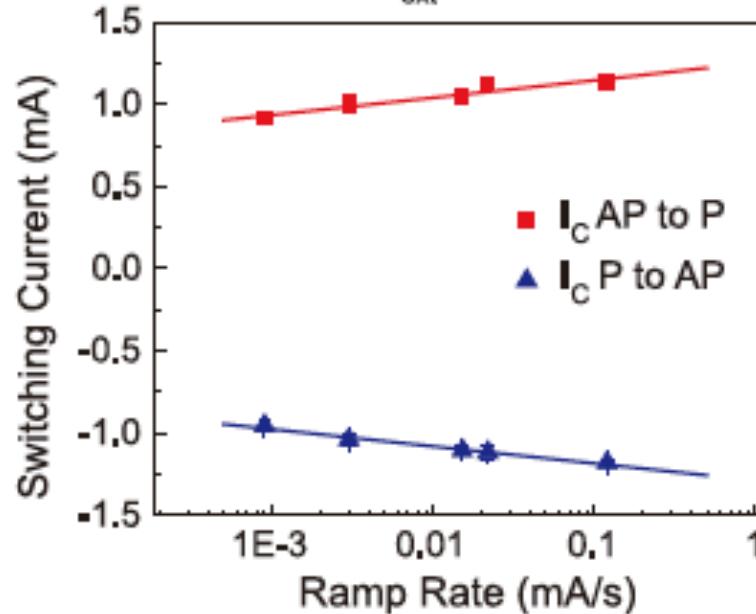
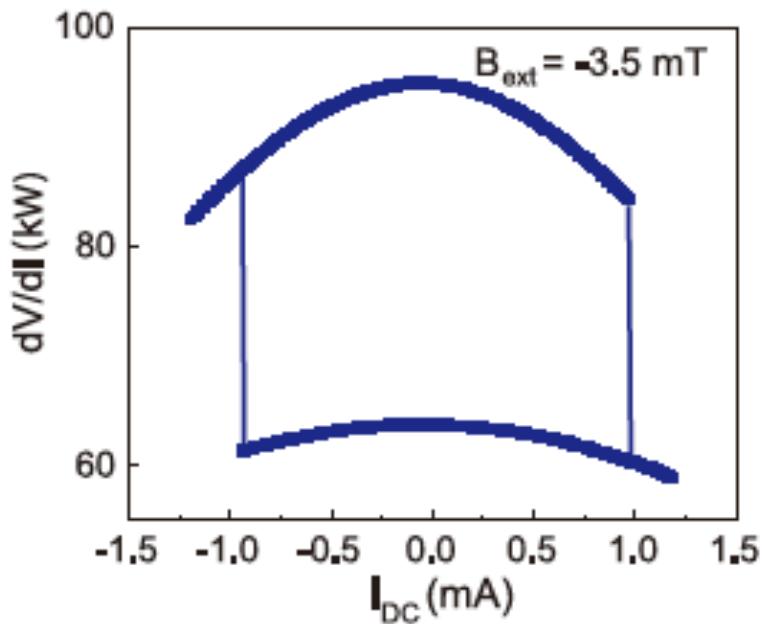
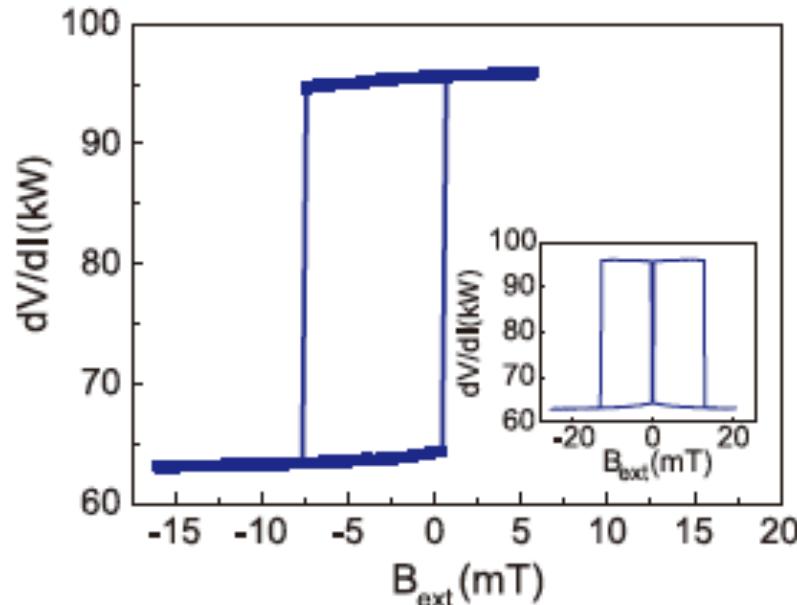
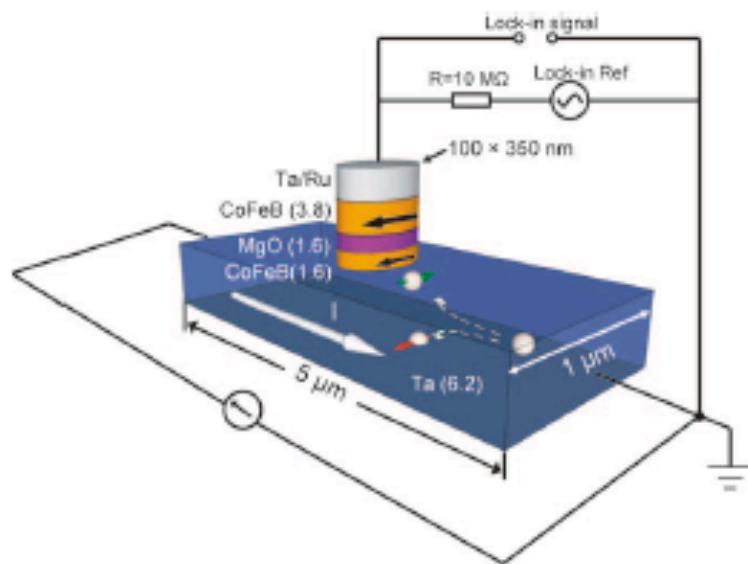


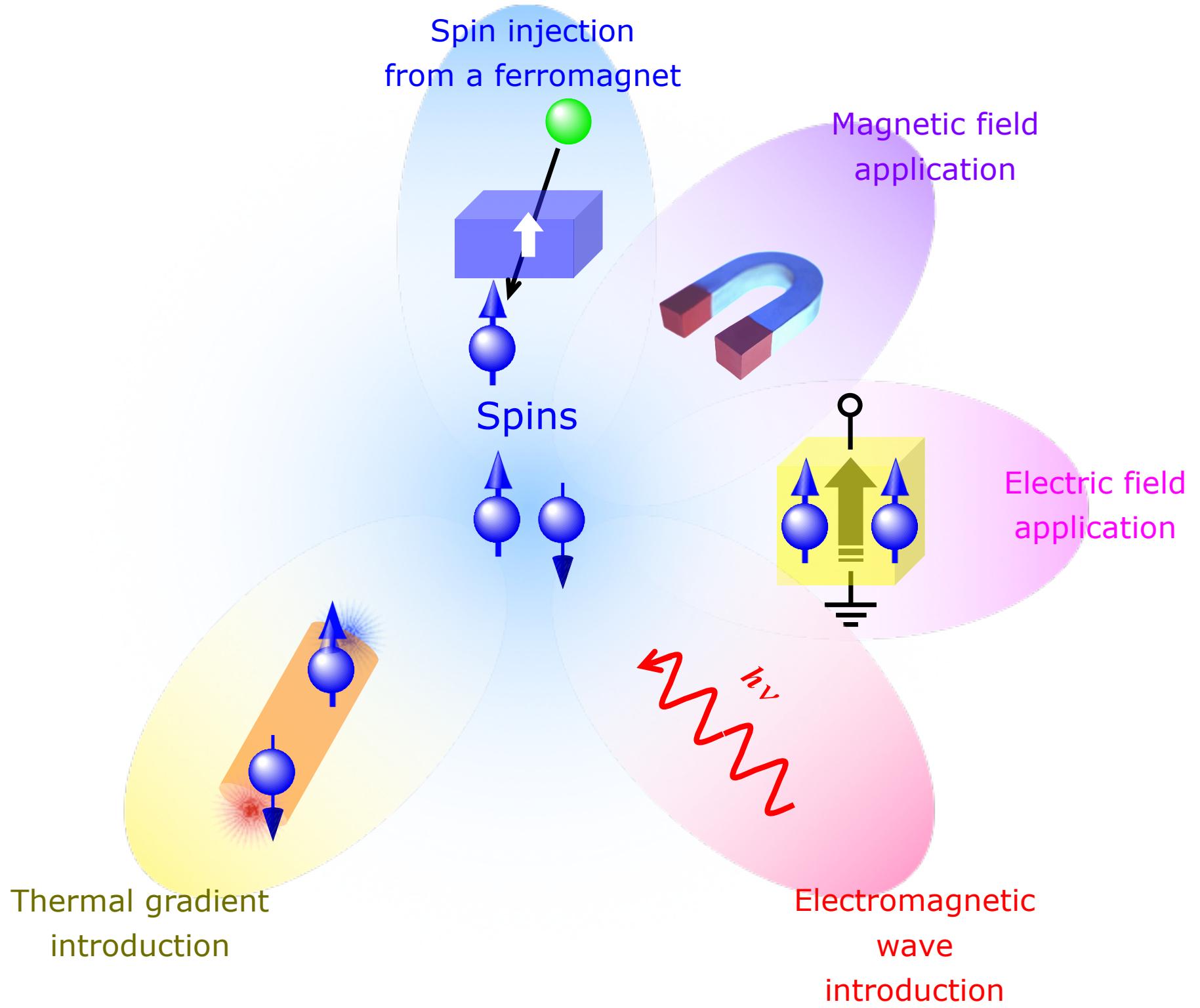
* S. O. Valenzuela and M. Tinkham, *Nature* **442**, 176 (2006).



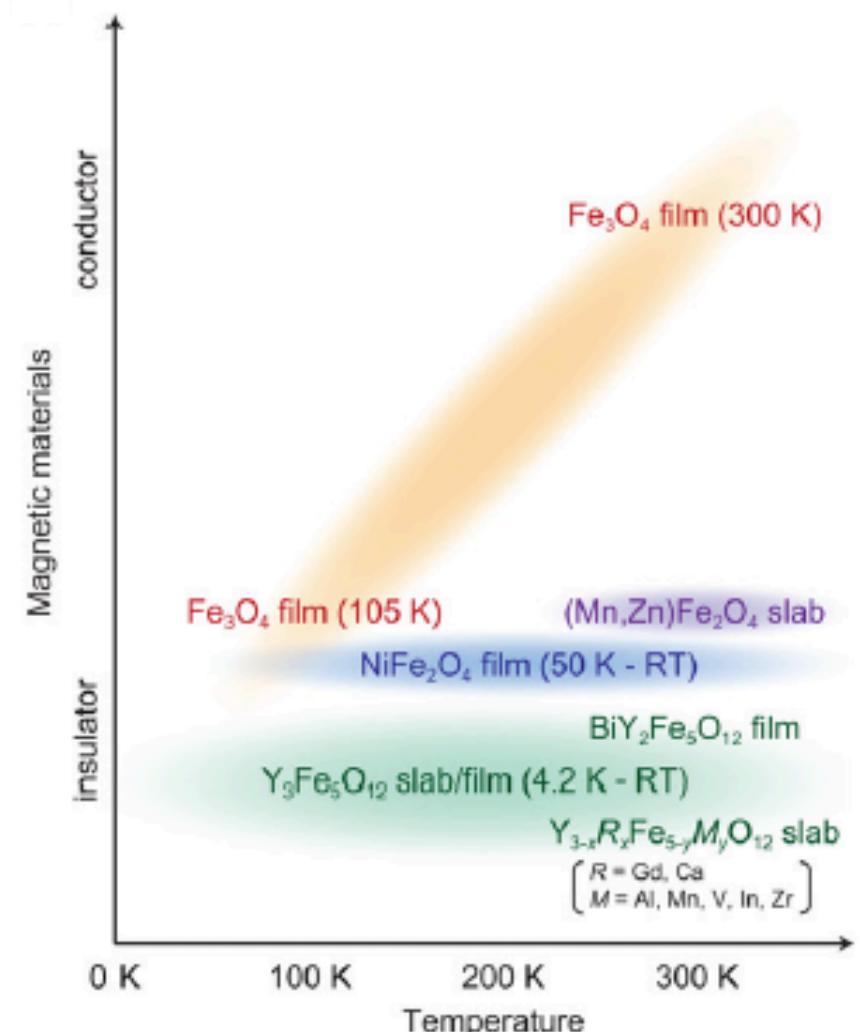
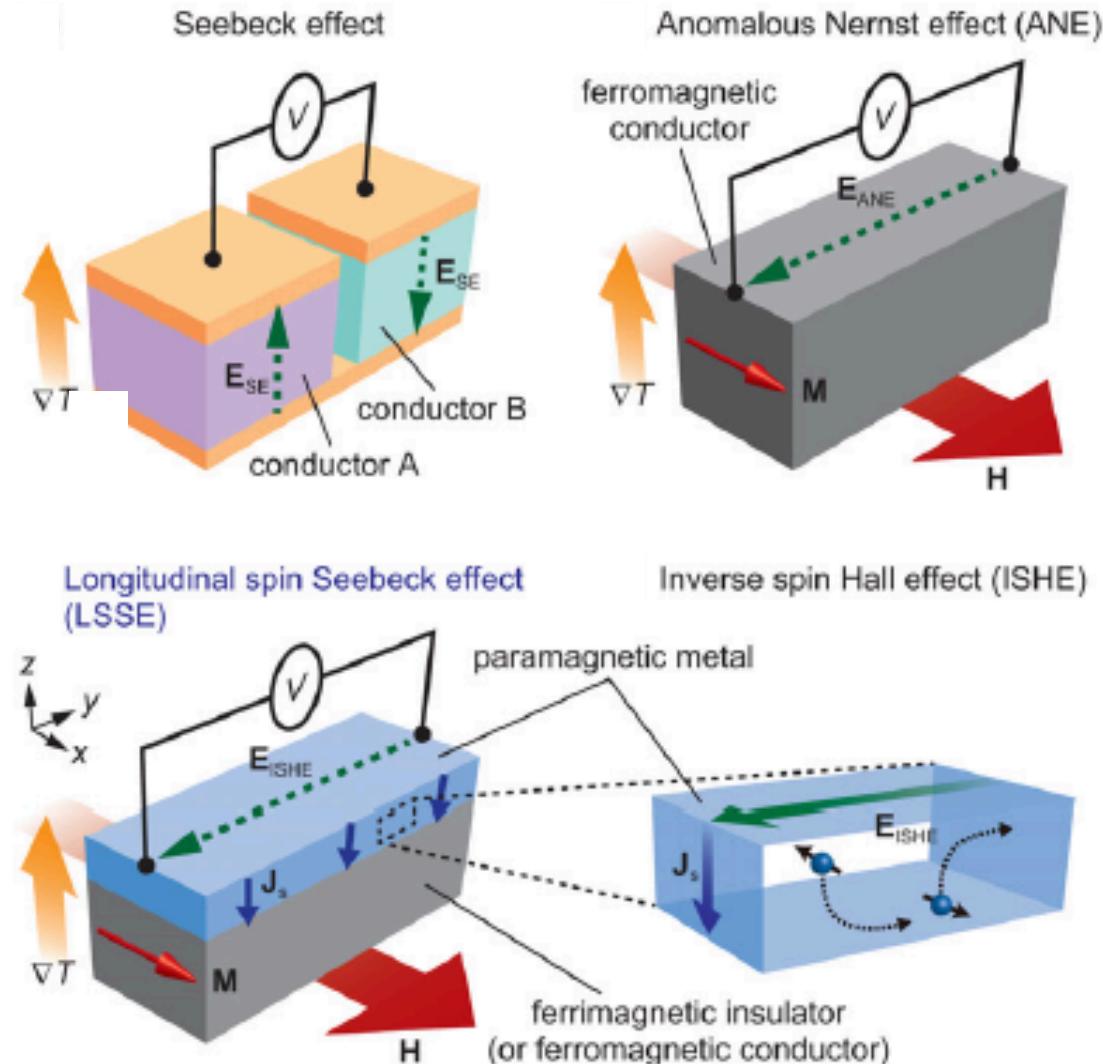
Magnetisation Reversal by the Spin Hall Effect

CoFeB / MgO / CoFeB nanopillar on Ta : *





Spin Seebeck Effect

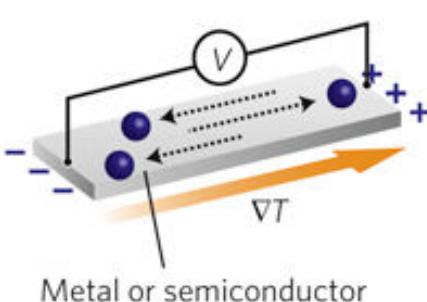
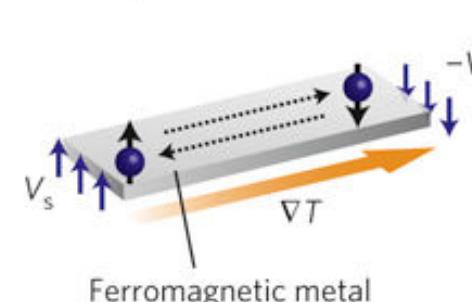
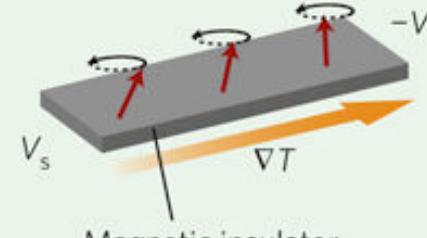


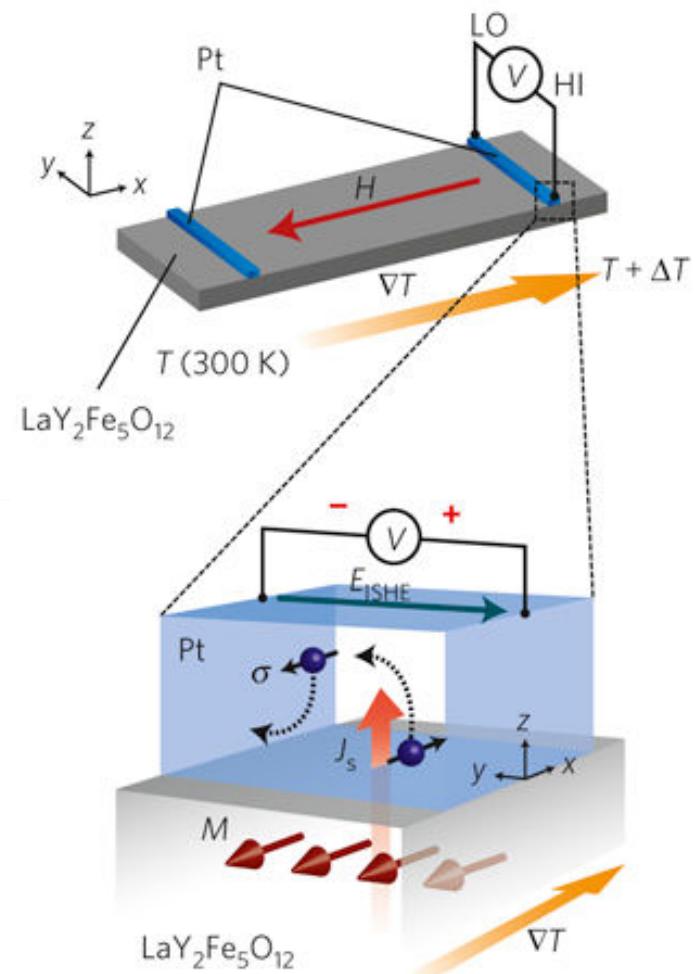
* K. Uchida et al., *Nature* **455**, 778 (2008);

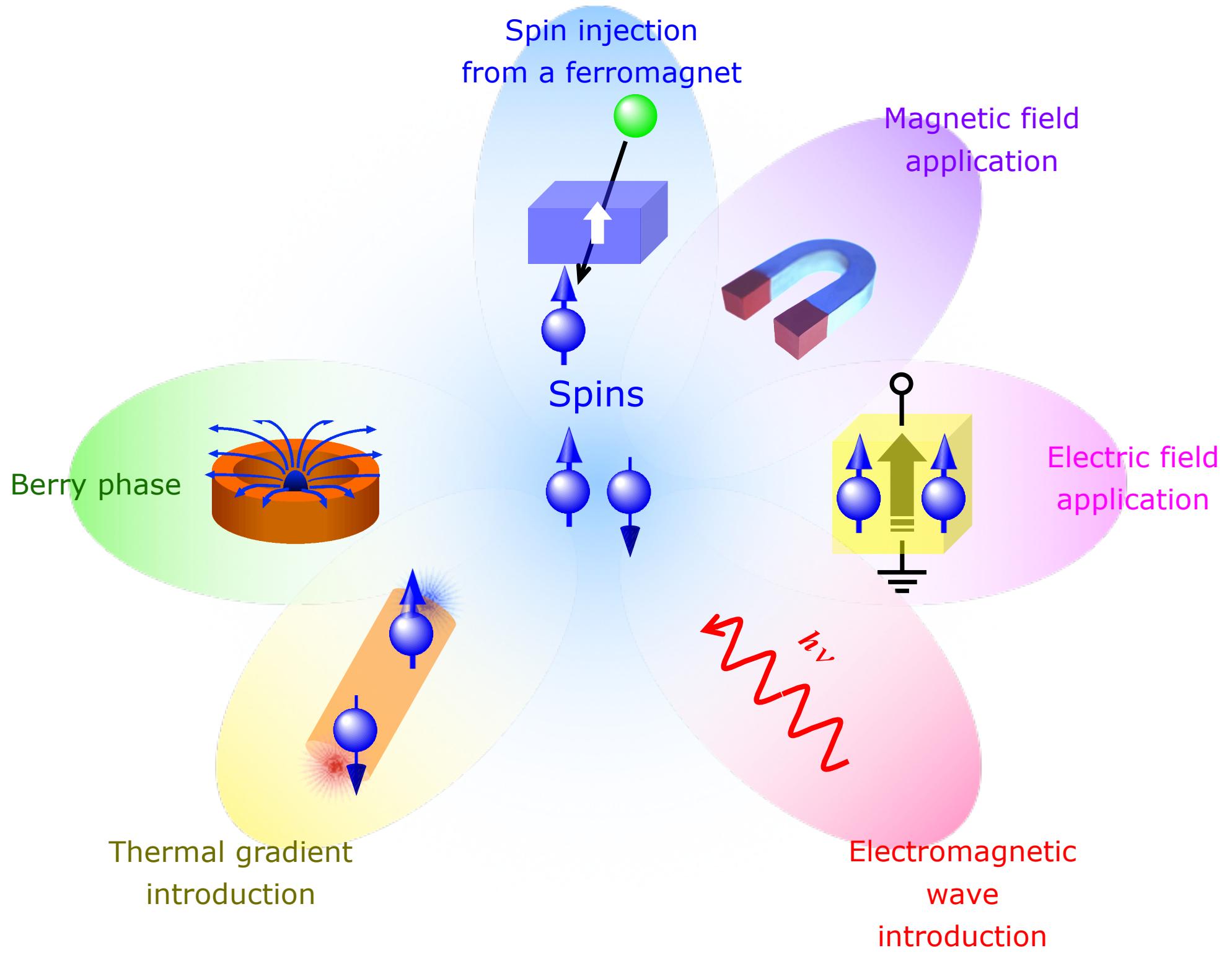
** K Uchida et al., *J. Phys.: Condens. Matter* **26**, 343202 (2014).



Spin Seebeck Effect

Material	Electricity	Magnetism
Conductor	<p>Seebeck effect</p>  <p>Metal or semiconductor</p>	<p>Spin Seebeck effect</p>  <p>Ferromagnetic metal</p>
Insulator		<p>Spin Seebeck effect</p>  <p>Magnetic insulator</p>







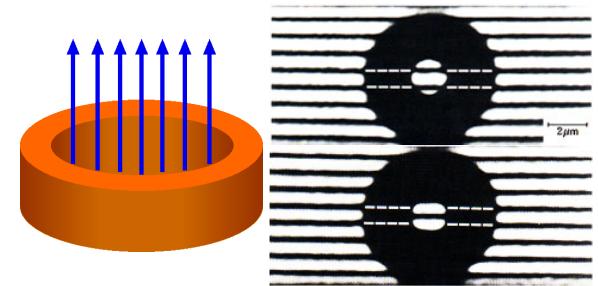
Theoretical Prediction on a Persistent Current

Persistent current :

induced by a magnetic flux threading a mesoscopic ring

→ *Aharonov-Bohm effect* *

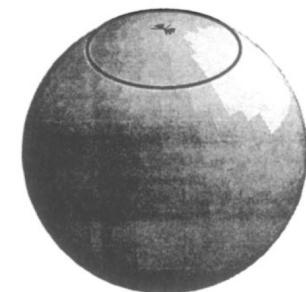
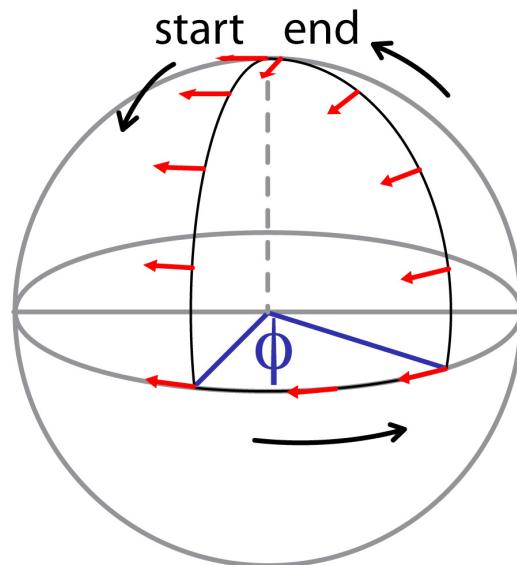
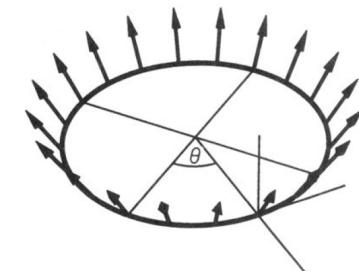
- The persistent current oscillates with the flux.



induced by a magnetic field rotating slowly in time **

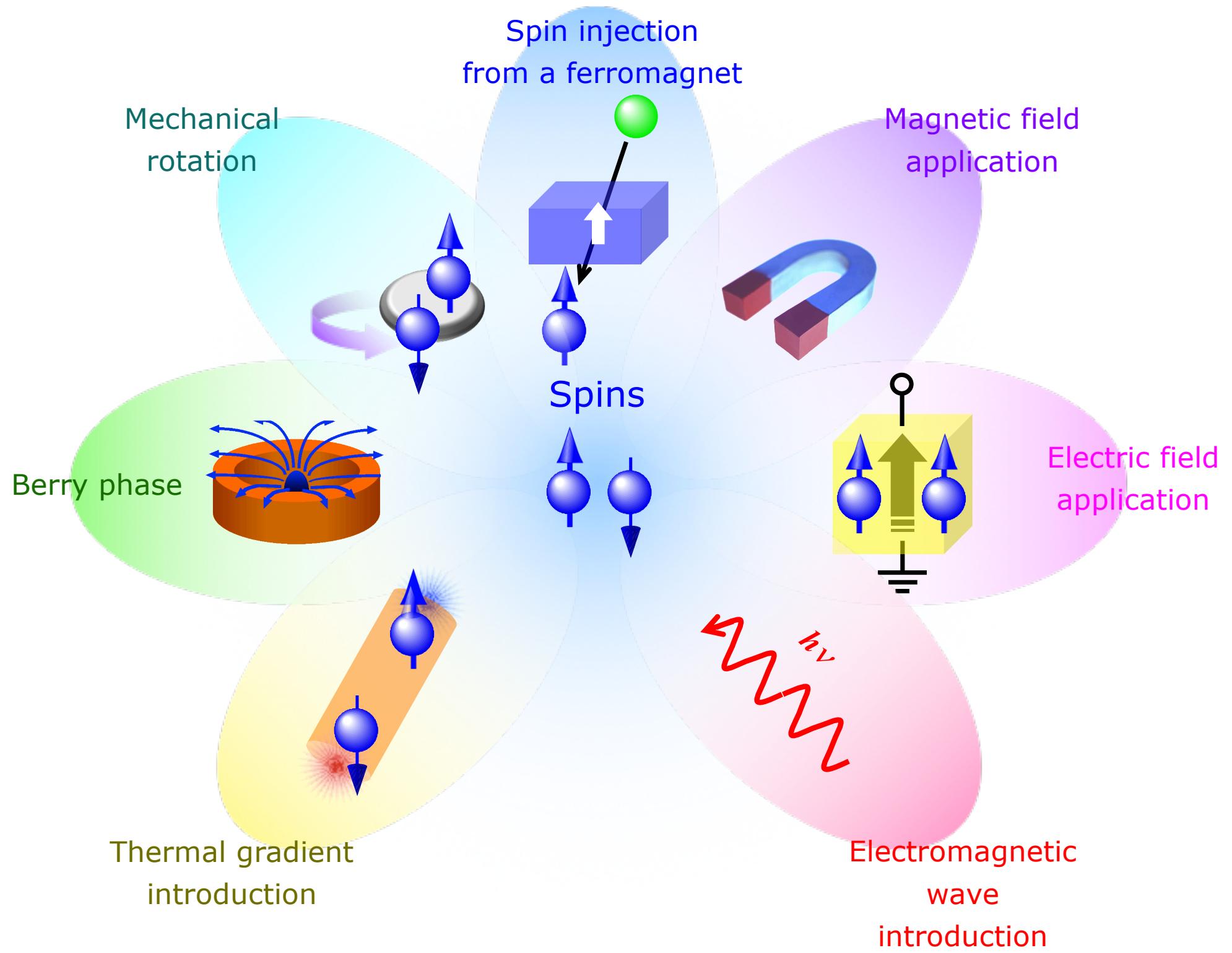
→ *Berry (geometrical) phase*

- Non-uniform external magnetic fields are required.
- Spin-polarised persistent current can be generated.



* Y. Aharonov and D. Bohm, *Phys. Rev.* 115, 485 (1959); A. Tonomura *et al.*, *Phys. Rev. Lett.* 56, 792 (1986);

** D. Loss and P. M. Goldbart, *Phys. Rev. B* 45, 13544 (1992).





Spin Current in a Rotating Body

- The Einstein de Haas effect describes the rotation of a magnetised body due to the conservation of angular momentum, by the application of a magnetic field.*
- The Barnett effect describes the inverse effect, where a body exhibits an increased magnetisation due to mechanical rotation.**
- The coupling between rotation and magnetisation and magnetisation and spin currents is well established.
- In 2011 Matsuo *et al.* proposed a new method for the direct generation of a *spin current* via mechanical rotation.***

$$J_S = 2enR\eta_{SO} \frac{\hbar 2\pi f}{2\epsilon_F} \omega_c$$

J_S = spin current density

e = electron charge

n = electron density

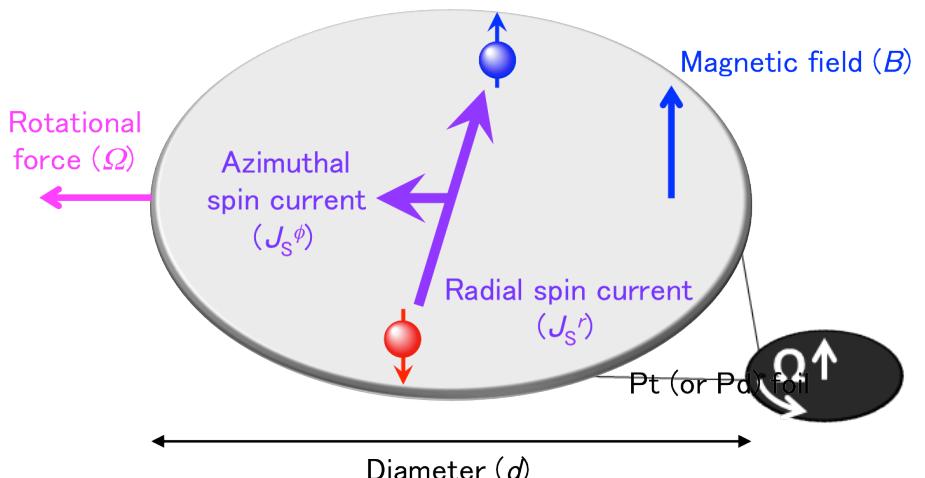
R = radius of rotation

η_{SO} = spin orbit coupling strength, 0.59

f = frequency

ϵ_F = Fermi energy

$\omega_c = qB/m$ for electron wave packet



* A. Einstein and W. J. de Haas, *KNAW Proc.* **18**, 696 (1915);

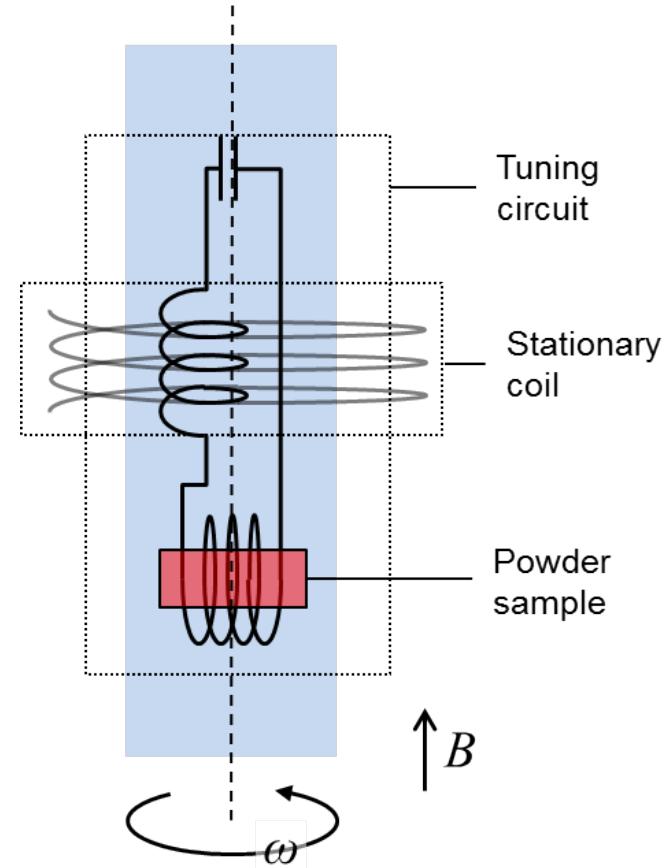
** S. J. Barnett, *Phys. Rev.* **6**, 239 (1915);

*** M. Matsuo *et al.*, *Phys. Rev. Lett.* **106**, 076601 (2011).



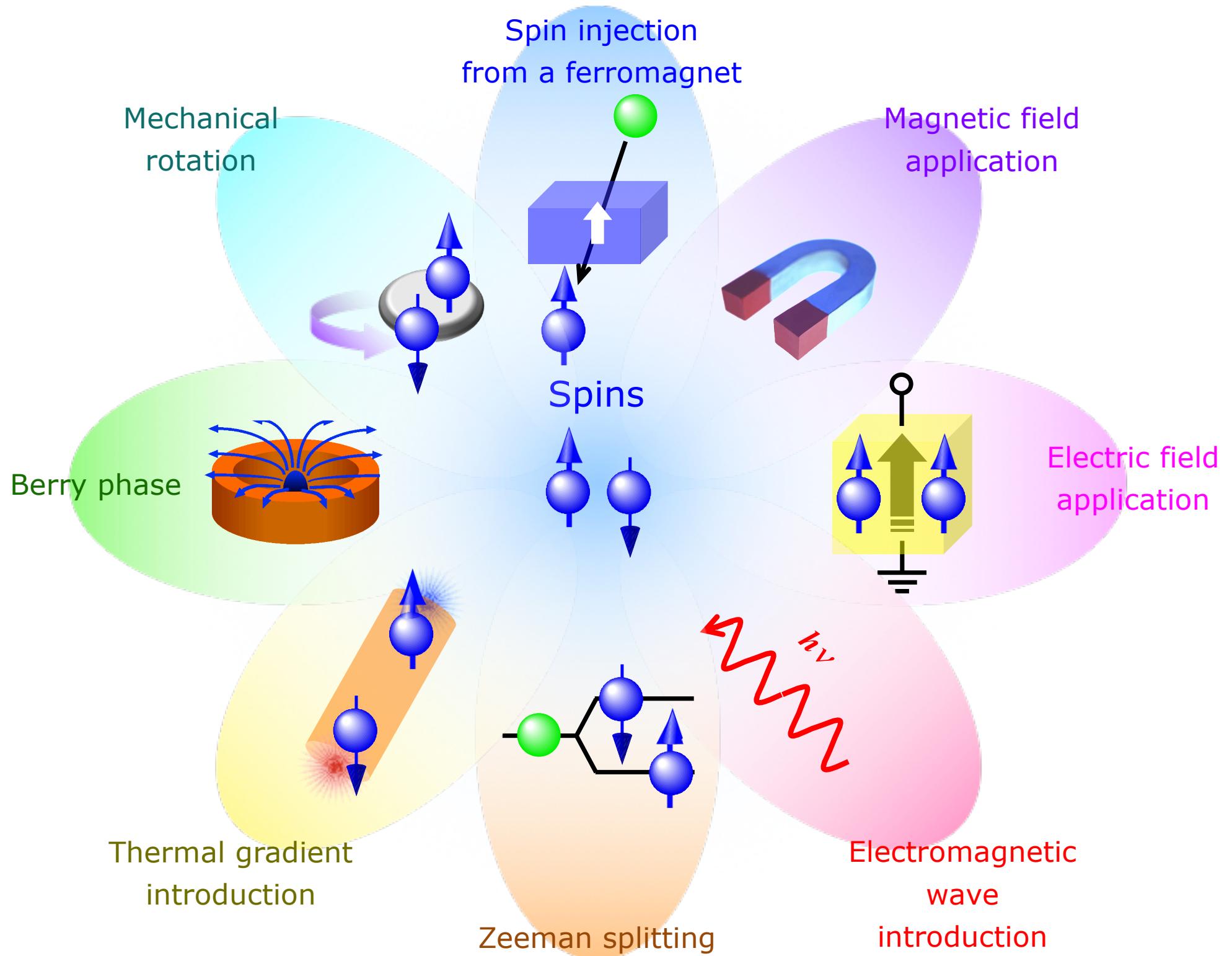
Spin Mechatronics Measurement

- In a similar vein, one can observe the Barnett field in a rotating body observing a shift in the NMR.
- The nuclear g factor dependence of the NMR shift is observed to measure the Barnett field.*
- The presence of a spin current may be detected by the magneto-optical Kerr effect (MOKE).
- This allows for direct probing of the conduction electrons.



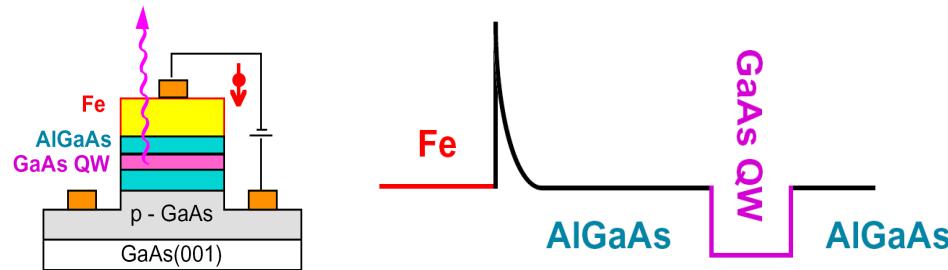
Schematic of the NMR measurement setup for the Barnett effect [6]

* H. Chudo *et al.*, *Appl. Phys. Exp.* **7**, 063004 (2014).



✓ Spin Transport - *Spin-pol'd electrons / holes* → SC → Circ.-pol'd photons

Spin LED structure



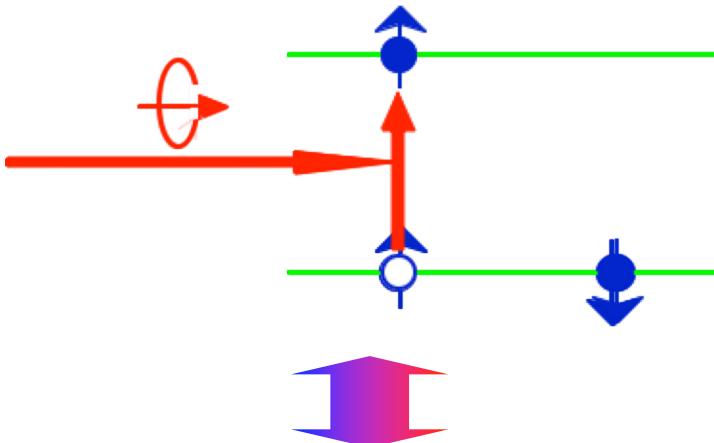
Structures	Spin polarisation	Refs.
Spin-polarised electron injection :		
300 nm BeMgZnSe + BeMnZnSe / 100 nm <i>n</i> -AlGaAs / 15 nm <i>i</i> -GaAs QW / ... / <i>p</i> -GaAs	~ 42% @ <5 K	R. Fiederling <i>et al.</i> , <i>Nature</i> 402 , 787 (1999).
360 nm CdMnTe / 1400 nm CdTe	~ 30% @ 5 K	M. Oestreich <i>et al.</i> , <i>Appl. Phys. Lett.</i> 74 , 1251 (1999).
<i>n</i> -ZnMnSe / AlGaAs / 10-15 nm GaAs QW / AlGaAs	~ 83% @ 4.5 K	B. T. Jonker <i>et al.</i> , <i>Phys. Rev. B</i> 62 , 8180 (2000); <i>Appl. Phys. Lett.</i> 81 , 265 (2002).
20 nm Fe / GaAs / InGaAs QW / GaAs	~ 2% @ 25 K	H. J. Zhu <i>et al.</i> , <i>Phys. Rev. Lett.</i> 87 , 016601 (2001).
12.5 nm Fe / AlGaAs / GaAs QW / GaAs	~ 13% @ 4.5 K ~ 8% @ 240 K	A. T. Hanbicki <i>et al.</i> , <i>Appl. Phys. Lett.</i> 80 , 1240 (2002).
8 nm NiFe + 2 nm CoFe / 1.4 nm AlO _x / 15 nm AlGaAs / 100 nm GaAs QW / GaAs	>9.2% @ 80 K	V. F. Motsnyi <i>et al.</i> , <i>Appl. Phys. Lett.</i> 81 , 265 (2002).
20 nm (Co, Fe & NiFe) / 2 nm Al ₂ O ₃ / 50 nm <i>n</i> -AlGaAs / 50 nm si-AlGaAs / 20 nm si-GaAs QW / ... / GaAs	0.8%, 0.5% & 0.2% @ RT	T. Manago <i>et al.</i> , <i>Appl. Phys. Lett.</i> 81 , 694 (2002).
Spin-polarised hole injection :		
300 nm <i>p</i> -GaMnAs / 20-220 nm GaAs / 10 nm InGaAs QW	~ 1% @ <31 K	Y. Ohno <i>et al.</i> , <i>Nature</i> 402 , 790 (1999).



Optically-Induced Spin-Polarised Electrons

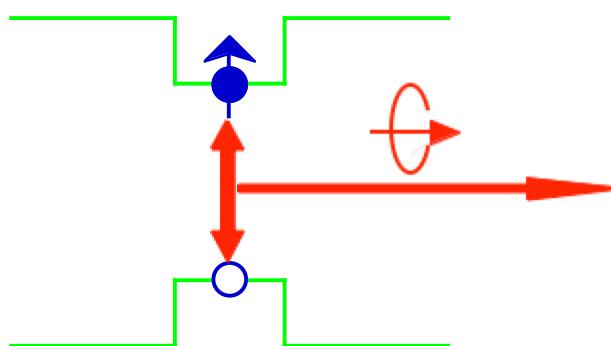
Photoexcitation :

Electrons spin-polarised by introducing **circularly polarised light**



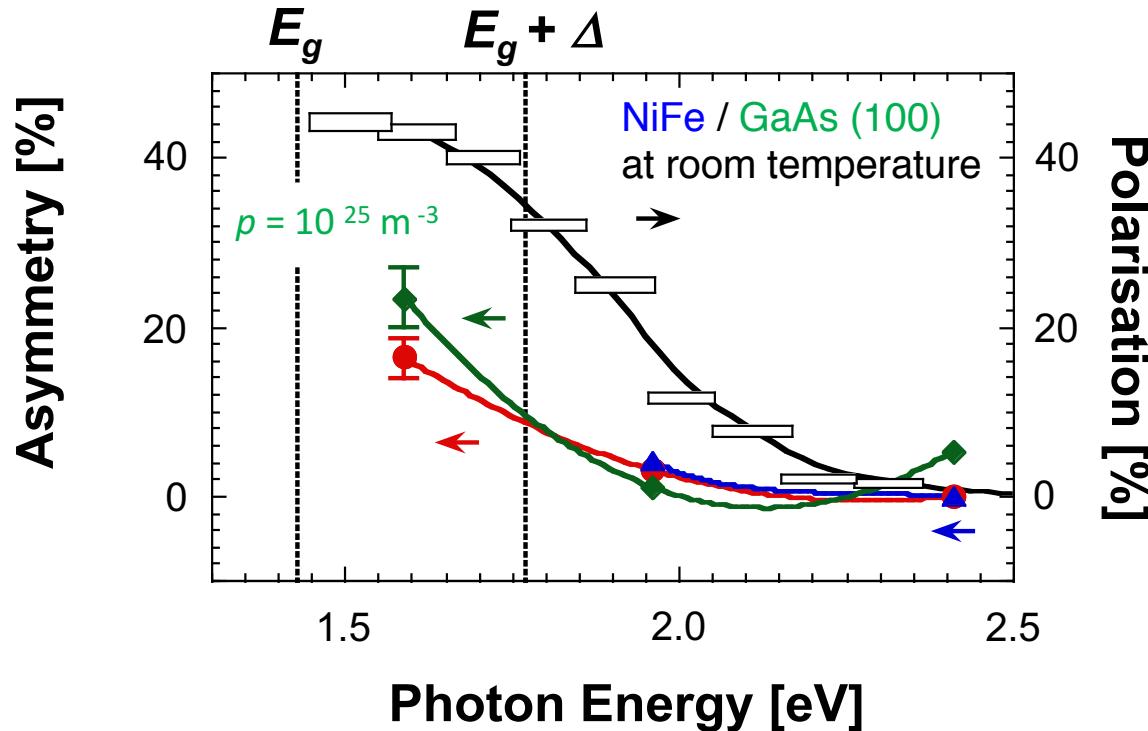
Circularly polarised electroluminescence (EL) :

Circularly polarised light generated by **spin-polarised electrons** at a quantum well (QW)





Photon Energy Dependence

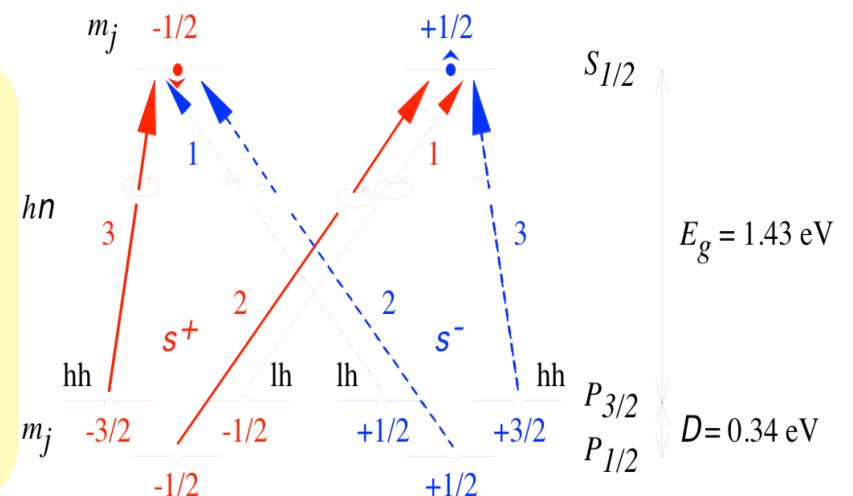


Spin polarisation \propto asymmetry in spin transport effect :

$$A = (\textcolor{blue}{I^n} - \textcolor{red}{I^0}) / (\textcolor{blue}{I^n} + \textcolor{red}{I^0})$$

A decreases with increasing photon energy.

\propto spin polarisation in GaAs

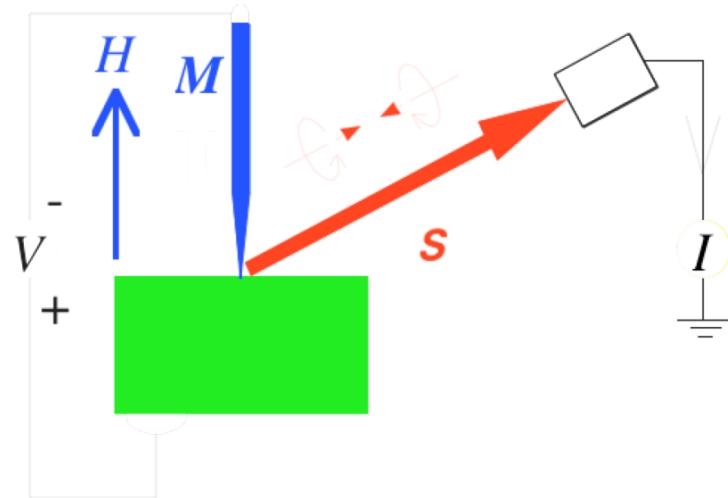


* D. T. Pierce *et al.*, *Phys. Lett.* **51A**, 465 (1975); A. Hirohata *et al.*, *Phys. Rev. B* **63**, 104425 (2001).

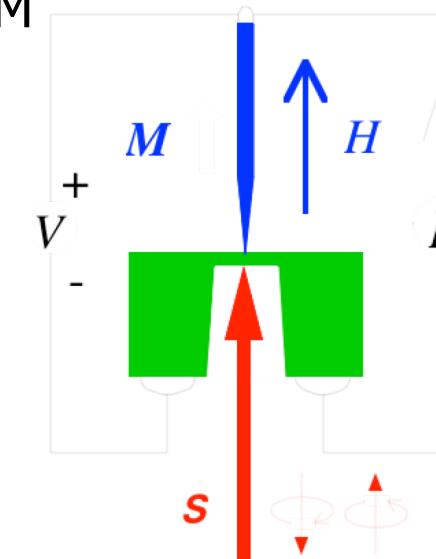


Spin Electronics with Optical Methods

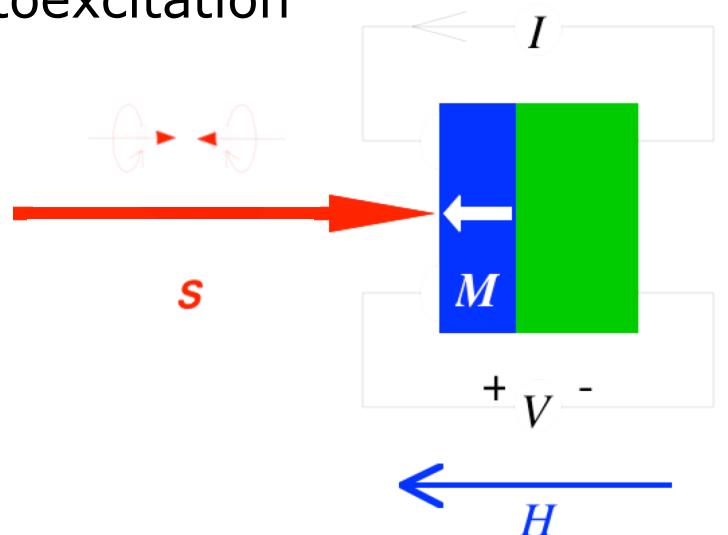
Spin-polarised inverse photoemission



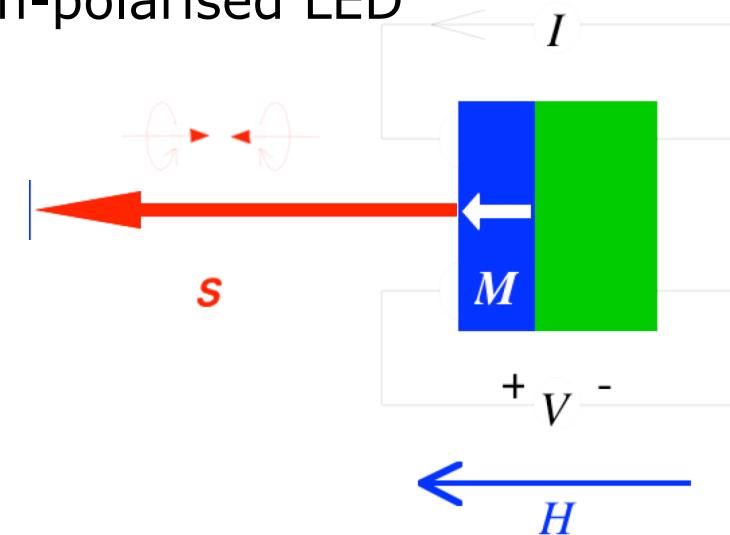
Spin-polarised STM



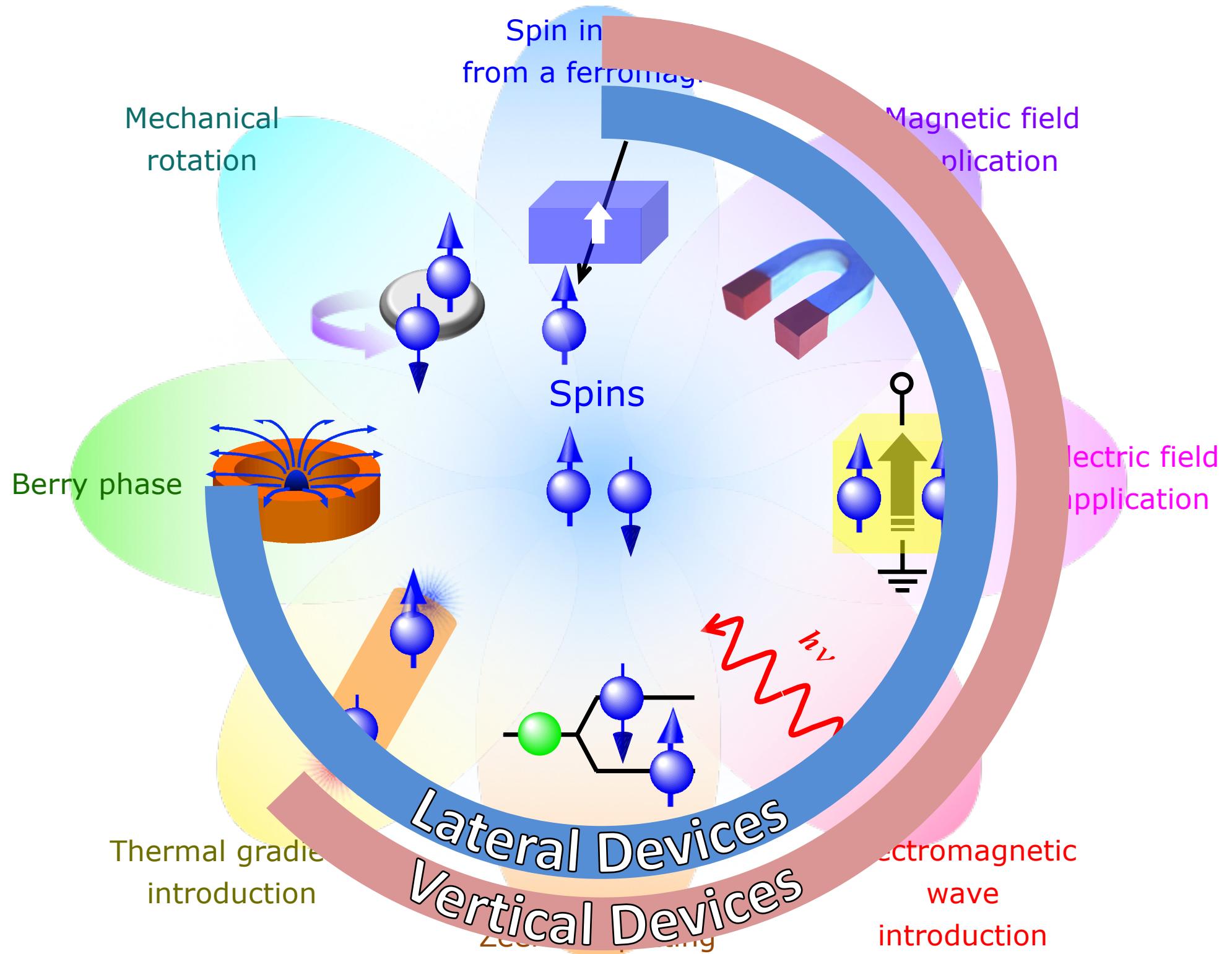
Photoexcitation



Spin-polarised LED



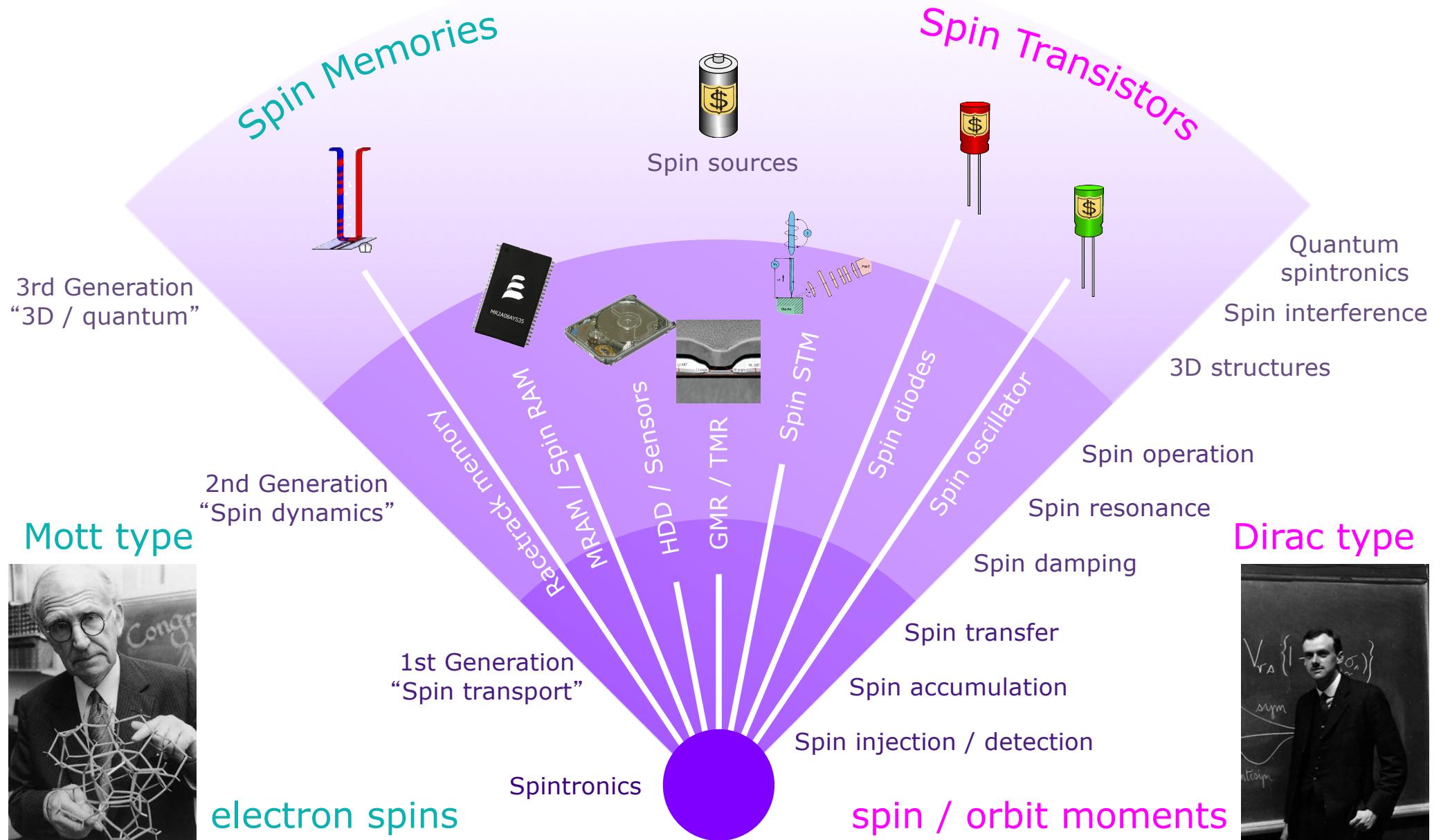
* A. Hirohata, "Optically induced and detected spin current," in S. Maekawa *et al.* (Eds.) *Spin Current* (Oxford University Press, Oxford, 2012) pp. 49-64.



Nano-Spintronic Devices



Development of nano-spintronic devices : *



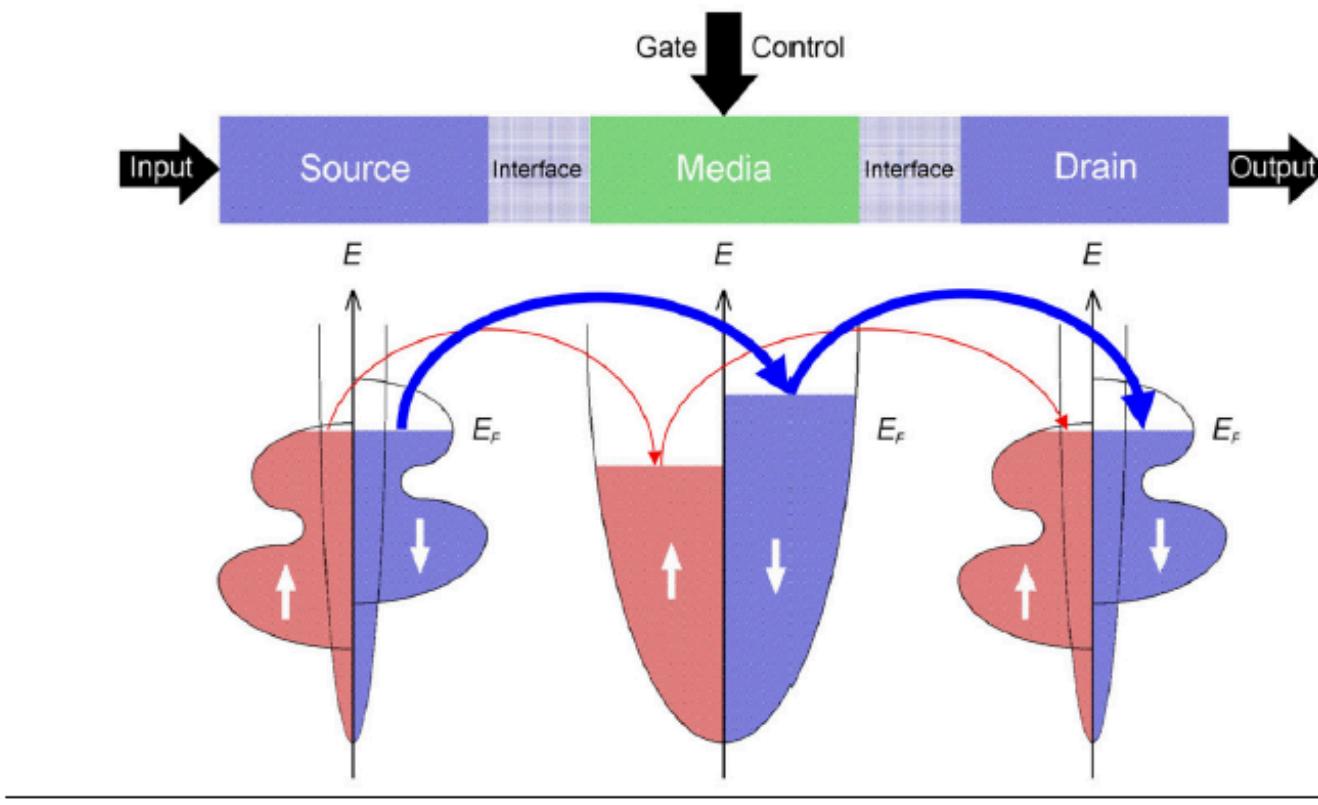
* A. Hirohata and K. Takanashi, *J. Phys. D: Appl. Phys.* **47**, 1930001 (2014).



Major Spin-Polarised Three-Terminal Devices

	Spin FET	Spin LED	Spin RTD	Coulomb blockade
Input	Spin-polarised electrons / holes	Spin-polarised electrons / holes	Spin-polarised electrons / holes	Spin-polarised electrons
Source	Ferromagnets (FM)	Dilute magnetic semiconductors (DMS)	Double tunnel barriers	Ferromagnets (FM)
Gate	Bias voltage	Bias voltage	Bias voltage	Bias voltage
Drain	Ferromagnets (FM)	Quantum wells (QW)	Quantum wells (QW)	Ferromagnets (FM)
Output	Electrical signals - Spin-polarised electrons / holes	Circularly polarised electroluminescence (EL)	Circularly polarised electroluminescence (EL)	Electrical signals
Notes		<ul style="list-style-type: none"> Low temperature High magnetic field 	<ul style="list-style-type: none"> Low temperature 	<ul style="list-style-type: none"> Low temperature
Refs.	S. Datta and B. Das, <i>Appl. Phys. Lett.</i> 56 , 665 (1990).	Y. Ohno <i>et al.</i> , <i>Nature</i> 402 , 790 (1999).	T. Gruber <i>et al.</i> , <i>Appl. Phys. Lett.</i> 78 , 1101 (2001).	K. Yakushiji <i>et al.</i> , <i>Appl. Phys. Lett.</i> 78 , 515 (2001).

Nano-Spintronic Devices

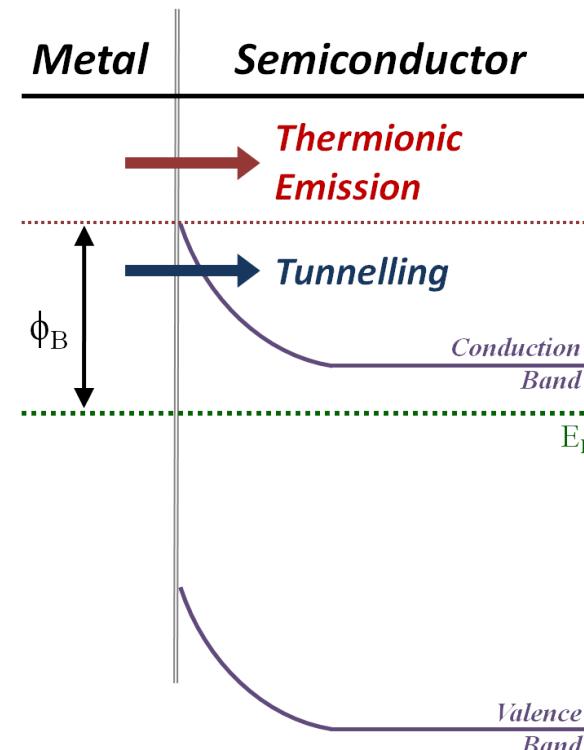
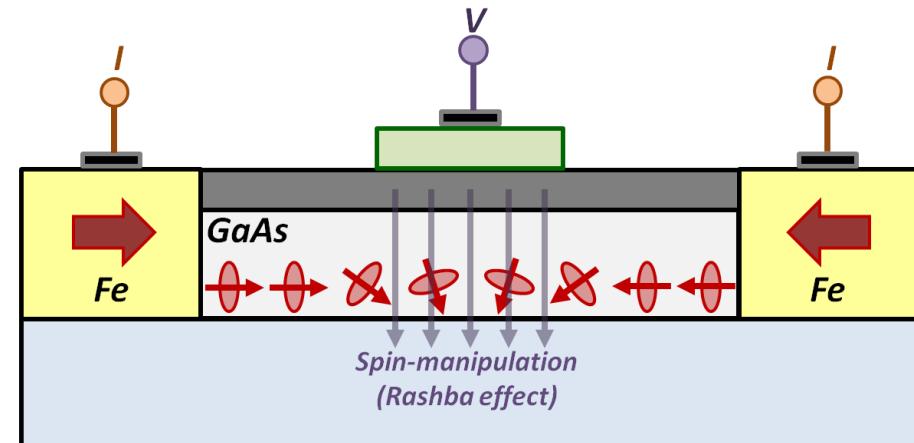


	Spin-valve structures	Magnetic tunnel junctions	FM/SC hybrid structures	Organic structures
Effects	GMR	TMR	Diodes	TMR/GMR
Interfaces	Ohmic contacts Diffusive	Tunnel barriers Ballistic	Ohmic/Schottky barriers Diffusive/ballistic (hot electrons)	Ohmic/tunnel barriers Diffusive/ballistic
Spin media	Non-magnetic metals	Tunnel barriers	Semiconductor	Organic materials
Spin coherence	30 nm–1 μ m	~ a few nm	$\leq 100 \mu\text{m}$	~ 200 μm
Device applications	Johnson transistors Spin-valve transistors Lateral spin valves	MOS junctions Coulomb blockade structures MRAM Superconducting point contacts Spin RTD Magnetic tunnel transistors SP-STM	FM/2DEG Schottky diodes Spin FET Spin LED Spin RTD	Lateral spin valves



Spin-Polarised Field Effect Transistor

- Spin transistor was originally proposed by Datta and Das.
- Fe/GaAs is one of the leading systems for obtaining efficient spin-polarised injection into a semiconductor (SC). **
- GaAs has long carrier spin lifetimes and large spin diffusion lengths.
- Fe is an ideal injector as it has:
 - high Curie temperature
 - low coercivity
 - good lattice matching with GaAs
- The intrinsic Schottky barrier that forms at the Fe/SC interface overcomes the limitations due to the conductivity mismatch.



* S. Datta and S. Das, *Appl. Phys. Lett.* **56**, 665 (1990);

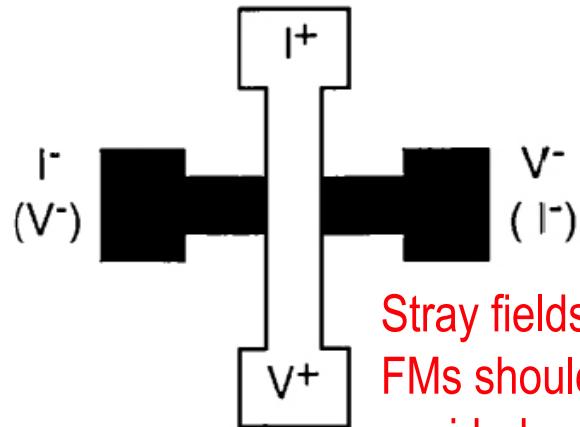
** G. Wastlauer and J. A. C. Bland, *Adv. Phys.* **54**, 137 (2005); D. Hagele et al., *Appl. Phys. Lett.* **73**, 1580 (1998); J. M. Kikkawa and D.D. Awschalom, *Nature* **397**, 139 (1999); E. I. Rashba, *Phys. Rev. B* **62**, R16267 (2000).



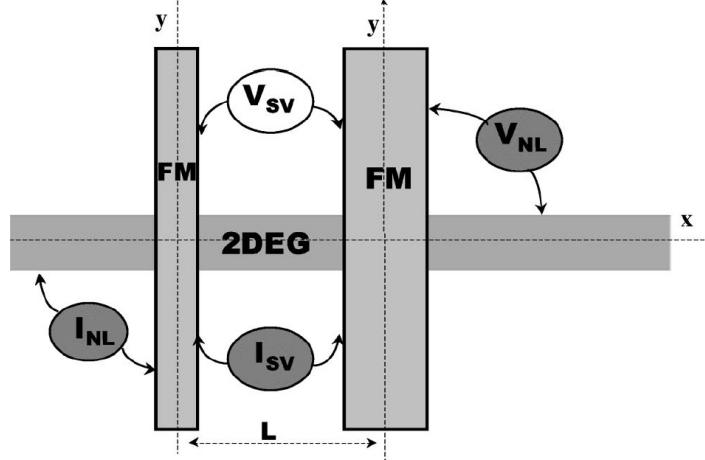
Spin Transport - *Spin-pol'd electrons* → *SC* → *Spin-pol'd electrons*

Spin FET structures :

Hall bar geometry



Asymmetric multi-terminal geometry

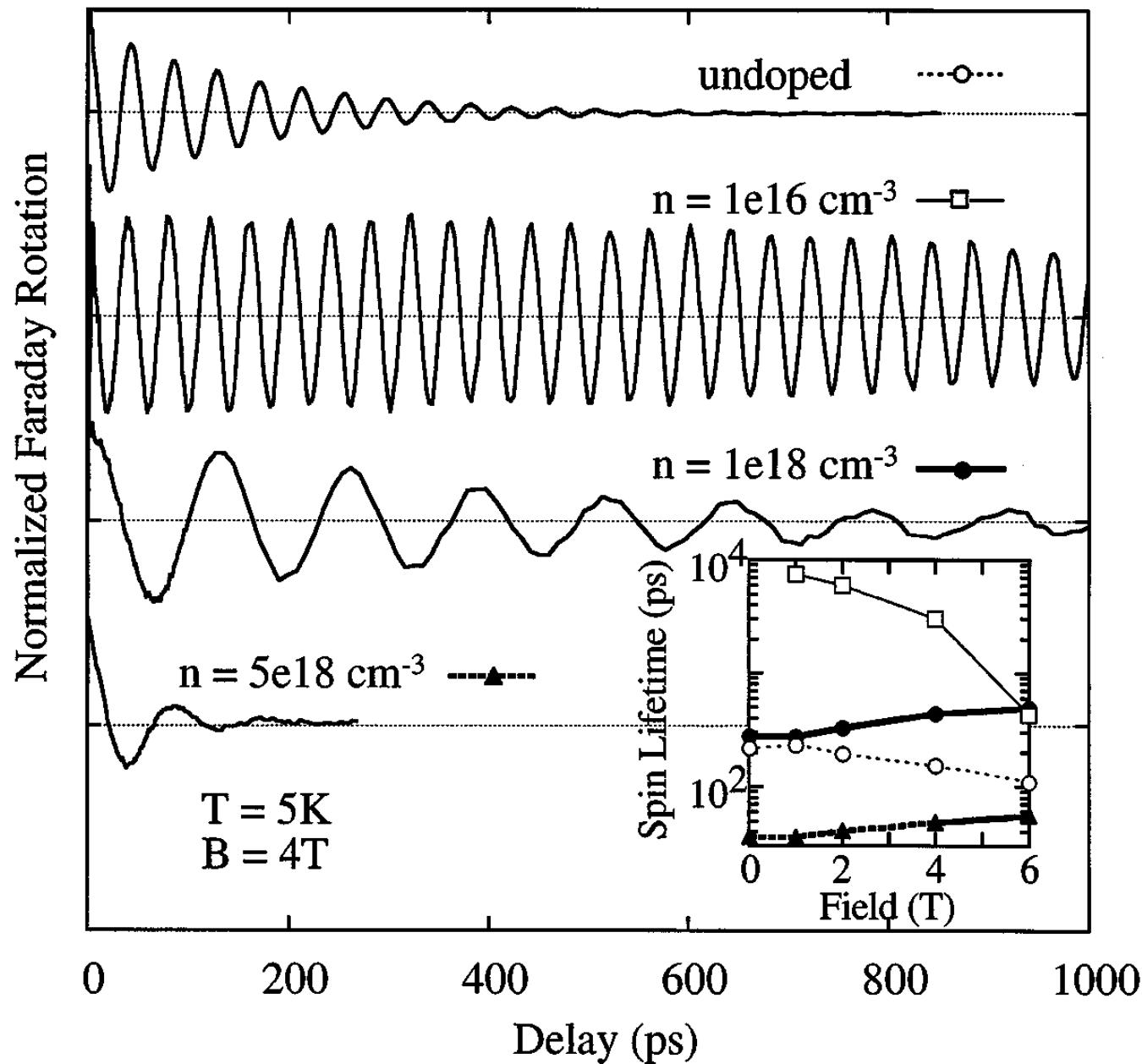


Structures	Spin polarization	Refs.
FM / 2DEG Hall-bar-type structures :		
86 nm NiFe / 25 nm AlGaSb / 15 nm InAs 2DEG / ... / GaAs	~ 1% @ 75 K	P. R. Hammar <i>et al.</i> , <i>Phys. Rev. Lett.</i> 83 , 203 (1999); <i>Phys. Rev. B</i> 61 , 7207 (2000).
NiFe / 750-6400 nm InAs QW / NiFe	Hall effect @ 4.2 K	F. G. Monzon and M. L. Roukes, <i>J. Magn. Magn. Mater.</i> 198-199 , 632 (1999).
FM / 2DEG asymmetric structures :		
NiFe & Co / InAs 2DEG / NiFe & Co	AMR @ 4.5 K	A. T. Filip <i>et al.</i> , <i>Phys. Rev. B</i> 62 , 9996 (2000).
60 nm NiFe / InAs 2DEG / GaAs	~ 0.2% @ < 10 K	C.-M. Hu <i>et al.</i> , <i>Phys. Rev. B</i> 63 , 125333 (2001).
Schottky (tunnel) diodes (FM / SC) :		
3.5 nm Fe / 2 nm Oxide / n-GaAs	~ 5% @ < RT	A. Filipe <i>et al.</i> , <i>Phys. Rev. Lett.</i> 80 , 2425 (1998).



Spin-Polarised Electrons in GaAs

> 100 μm spin diffusion length : *

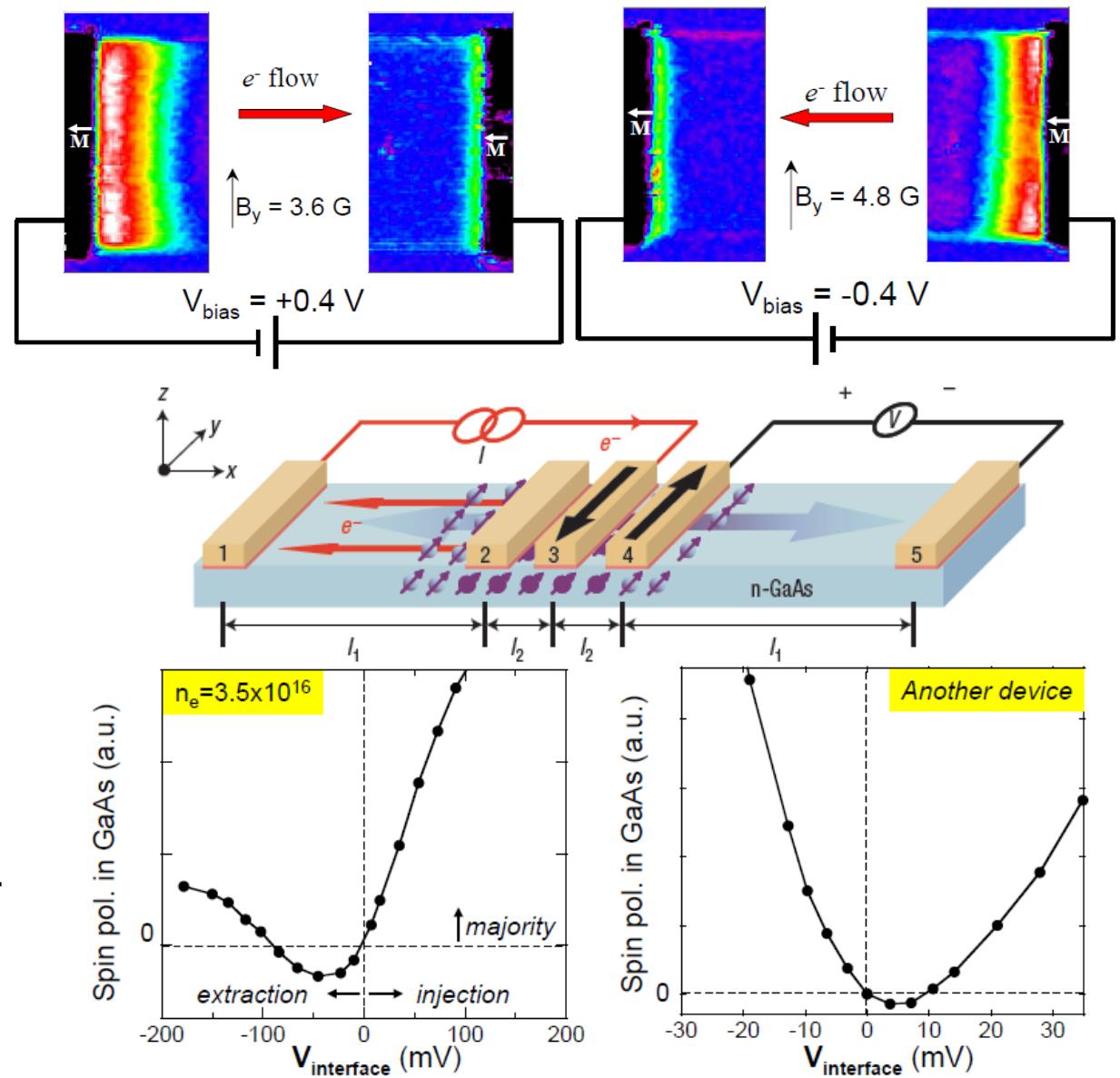


* J. M. Kikkawa and D. D. Awschalom, *Phys. Rev. Lett.* **80**, 4313 (1998).



Spin Transport Measurements in GaAs

- Experimental studies have shown that spin injection can be achieved leading to a majority spin accumulation.
- Spin injection / extraction has been observed using both optical * and electrical ** techniques.
- A bias dependant polarisation inversion has been observed, the origin of which remains unknown.
- Knowledge of the mechanism(s) responsible for the polarisation inversion required for the development of future devices.



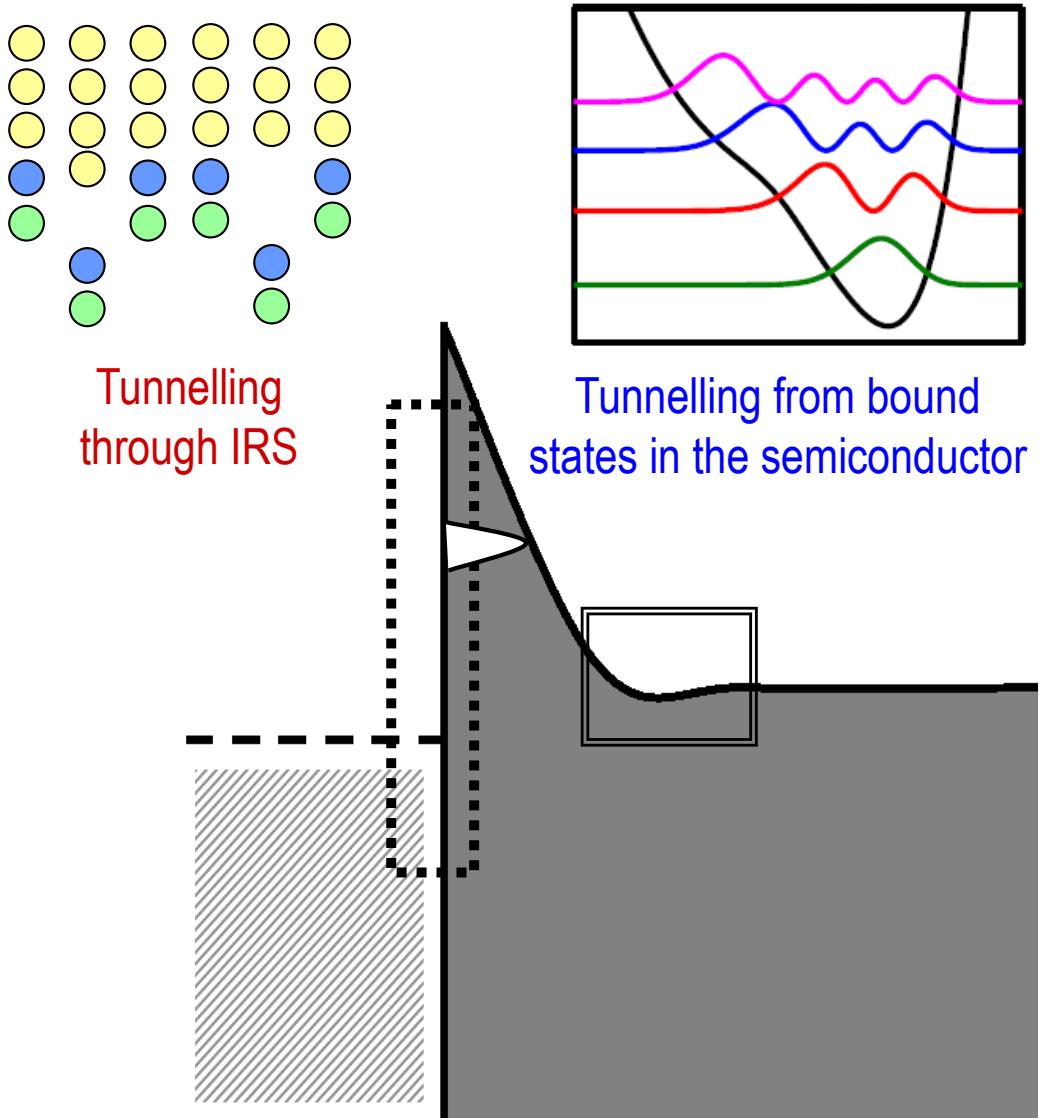
* S.A. Crooker *et al.*, *Science* **309**, 2191 (2005);

** X. Lou *et al.*, *Nature Phys.* **3**, 197 (2007).



Possible Origins of Spin Polarisation Reversal

- There are two promising candidates to explain the polarisation inversion:
 - Tunnelling through interface resonance states (IRS). *
 - Tunnelling from bound states in the semiconductor. **
- It has been shown that the contribution arising from bound states can be varied through control of the doping profile.
- The strength and position of IRS is sensitive to the atomic interface structure. *



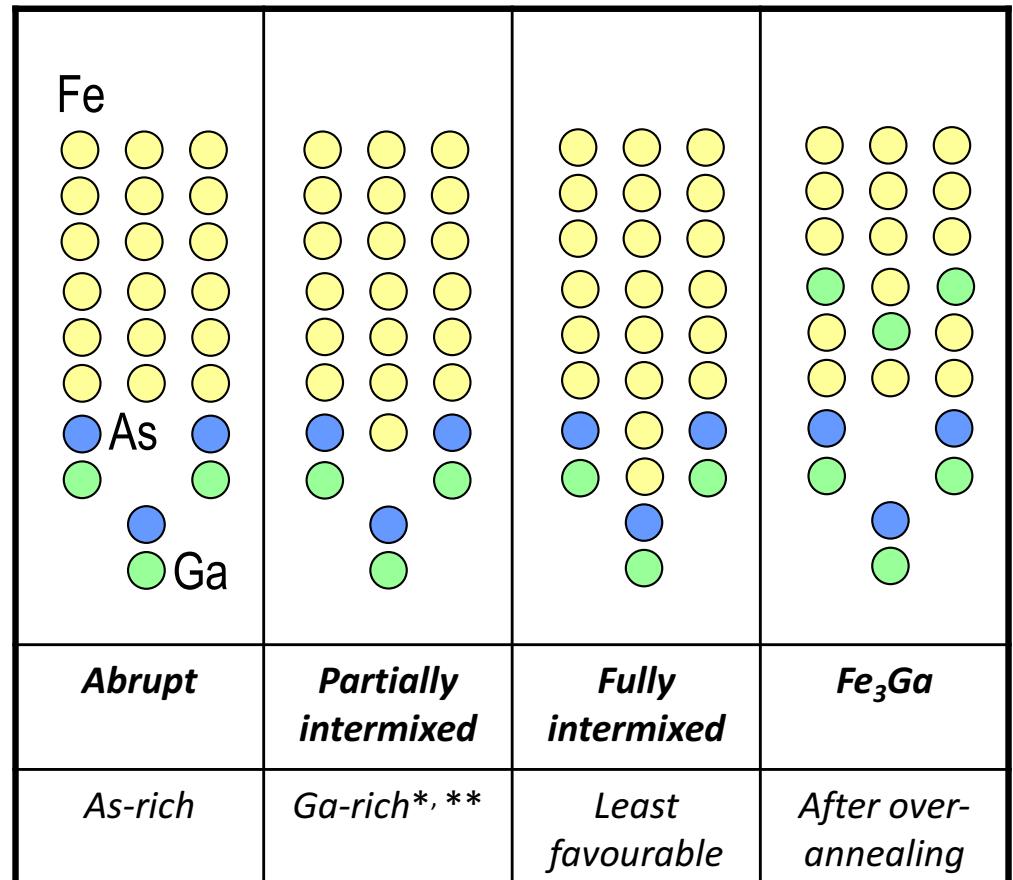
* S Honda *et al.*, *J. Phys. D: Appl. Phys.* **43**, 135002 (2010);

** H. Dery and L.J. Sham, *Phys. Rev. Lett.* **98**, 046602 (2007).



Fe / GaAs (001) Interface Structures

- There are several proposals for the interface structure of Fe / GaAs (001) films.
- Calculations suggest that the abrupt interface is energetically favourable for As-terminated surfaces (often used to limit diffusion).
- Previous calculations predict that minority carrier interface states lie 0.3 eV below the top of the Schottky barrier.
 - - *These are yet to be observed experimentally.*
- Calculations are yet to be performed for inter-atomic spacings measured experimentally.



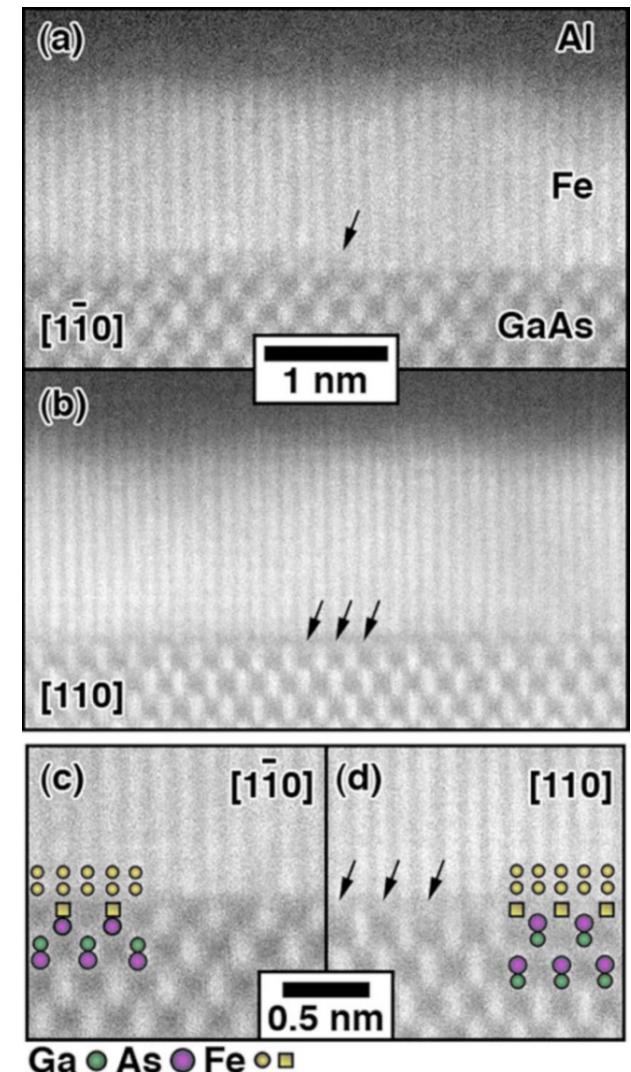
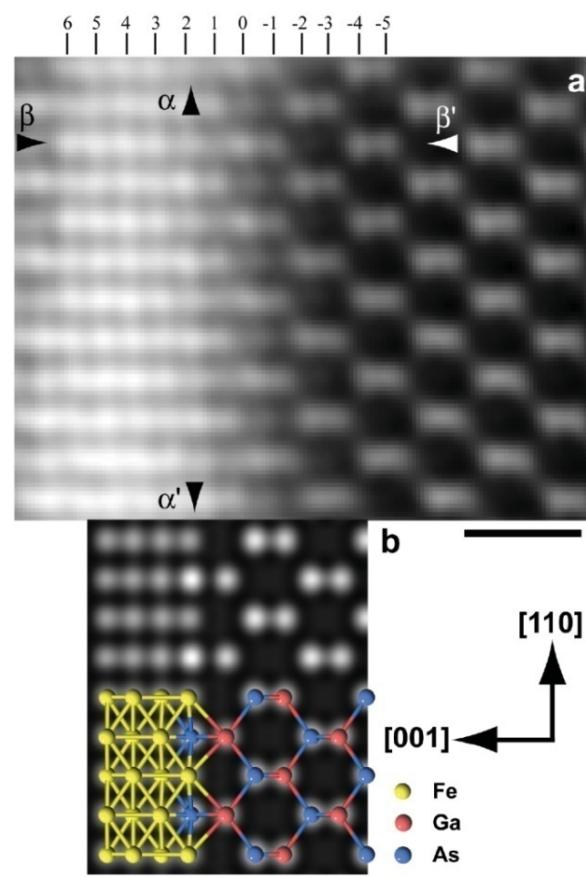
* T. J. Zega *et al.*, *Phys. Rev. Lett.* **96**, 196101 (2006);

** J. M. LeBau *et al.*, *Appl. Phys. Lett.* **93**, 121909 (2008).



Previous Experimental Observations

- There have been two previous reports on experimental observations of the Fe/GaAs interface. *,**
- The two studies reported different interfacial structures.
- Both reports did not observed the abrupt interface.
- Experimental values for the Schottky barrier height range from 0.2 to 0.8 eV. ***,****



* T. J. Zega *et al.*, *Phys. Rev. Lett.* **96**, 196101 (2006);

** J. M. LeBau *et al.*, *Appl. Phys. Lett.* **93**, 121909 (2008);

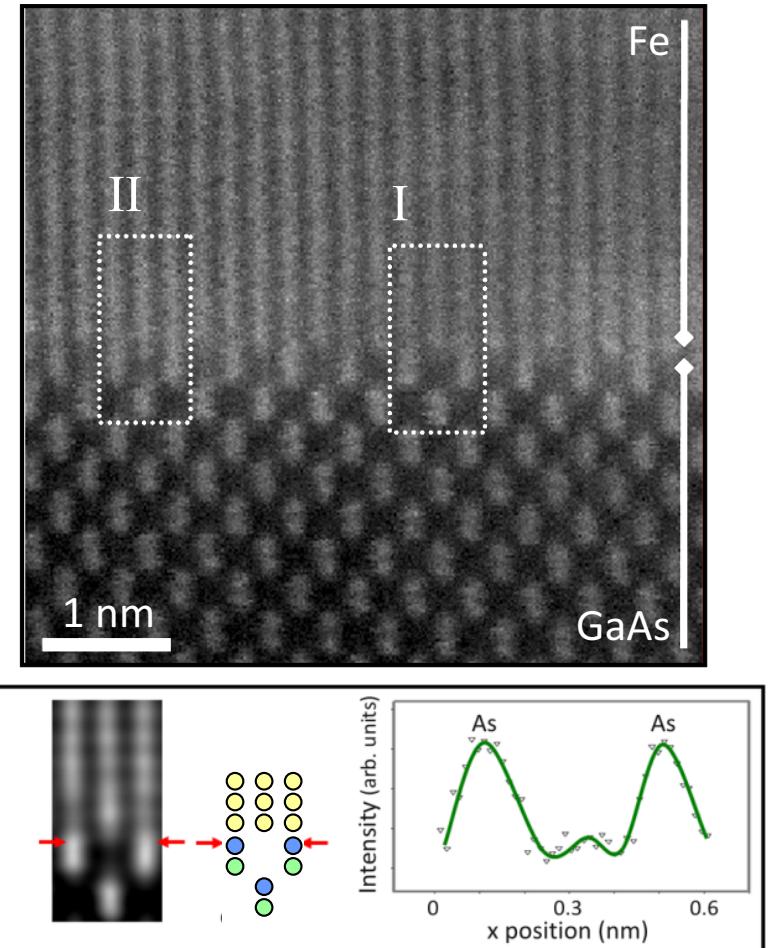
*** H. Kurebayashi *et al.*, *Appl. Phys. Lett.* **91**, 102114 (2007);

**** B. T. Jonker *et al.*, *J. Appl. Phys.* **81**, 4362 (1997).



HAADF STEM Observation on Fe/GaAs Interfaces

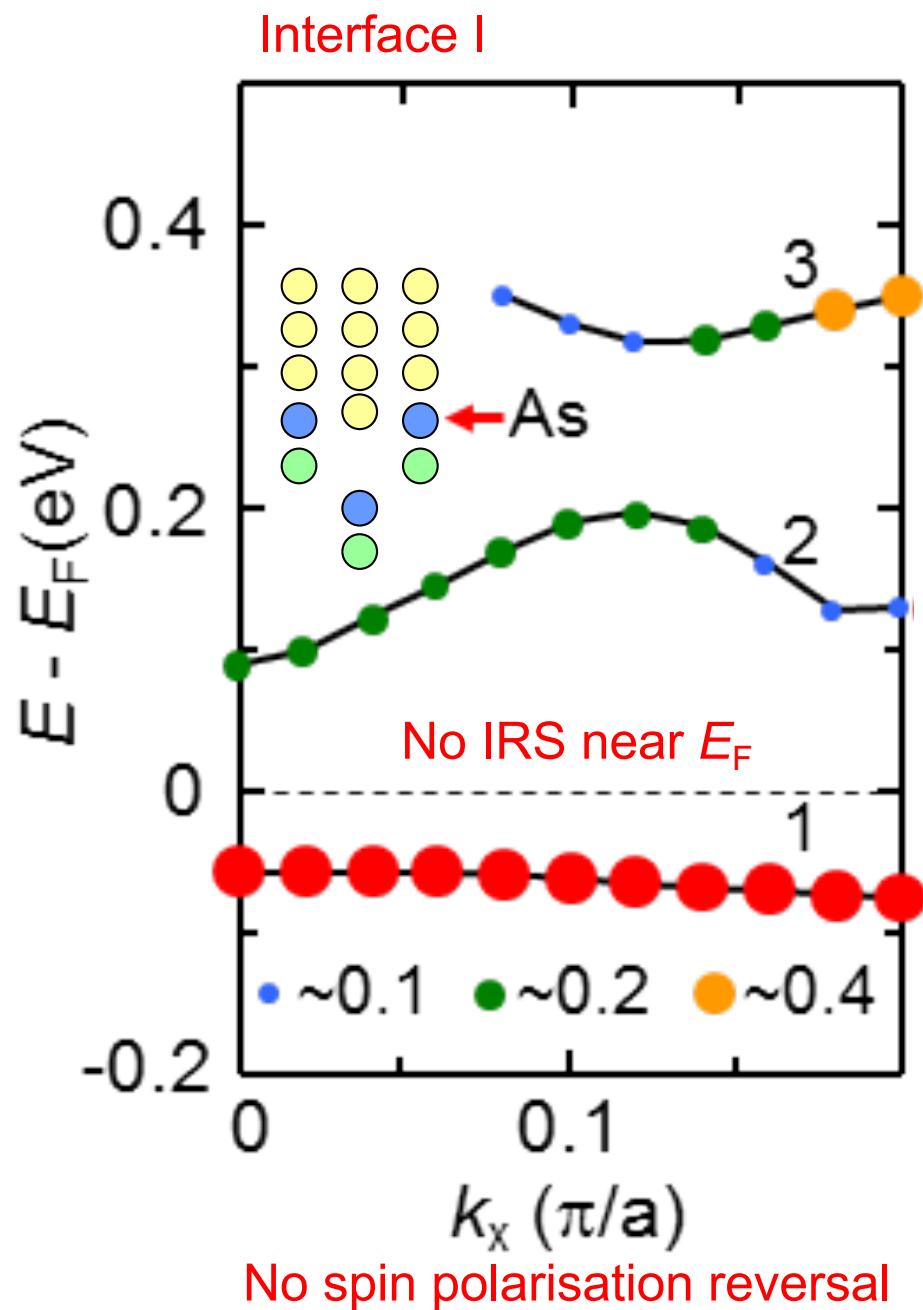
- The figure shows an **unfiltered** HAADF-STEM image the Fe / GaAs interface.
- Two different interfacial structures are observed.
 - Abrupt (first report) **
 - Partially mixed (as reported previously) *
- Analysis of the intensity profiles (z-contrast) taken across the interfaces suggest that Fe is responsible for the partially mixing.
- From the areas observed the film is $\sim 95\%$ abrupt.



* L. R. Fleet *et al.*, *IEEE Trans. Magn.*, **47**, 2756 (2011);
** L. R. Fleet *et al.*, *Phys. Rev. B* **87**, 024401 (2012).



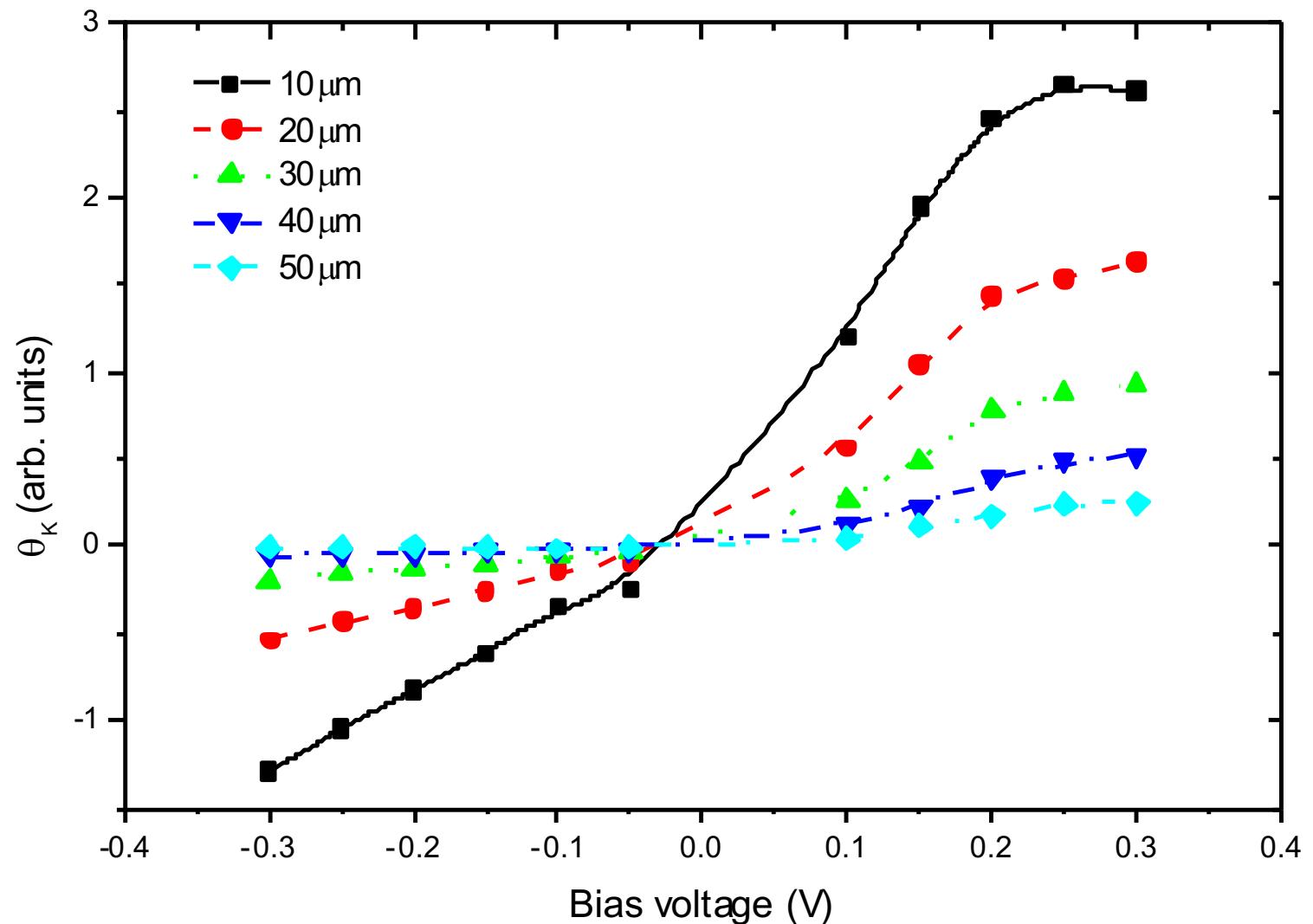
Peak Positions of IRSs





Bias Dependence

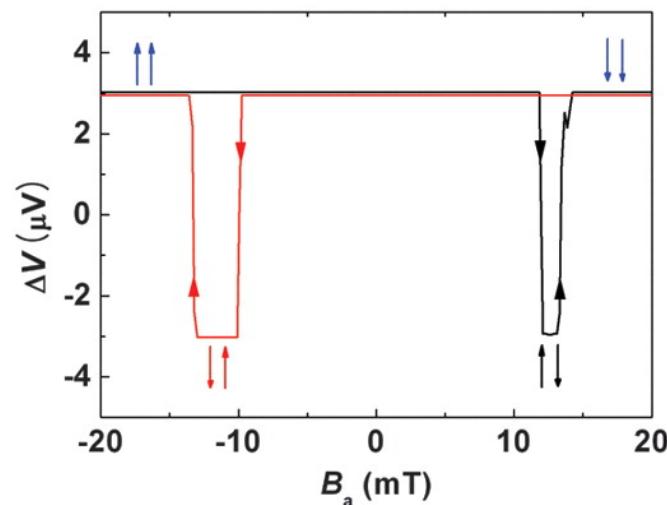
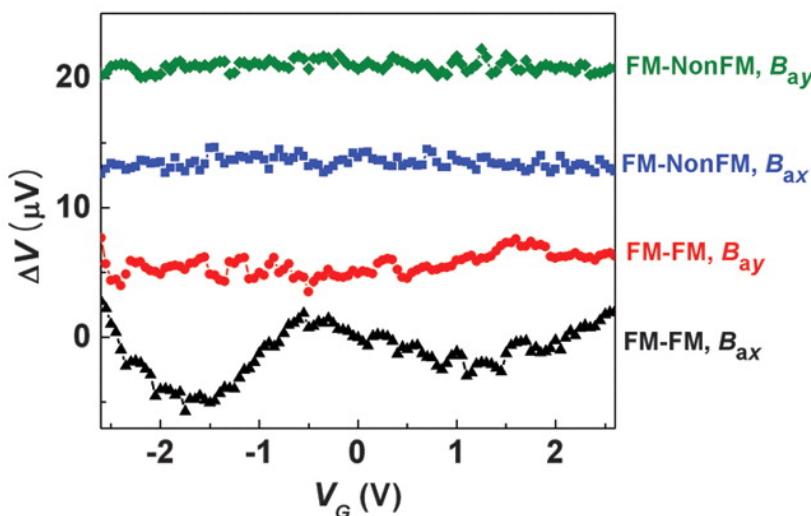
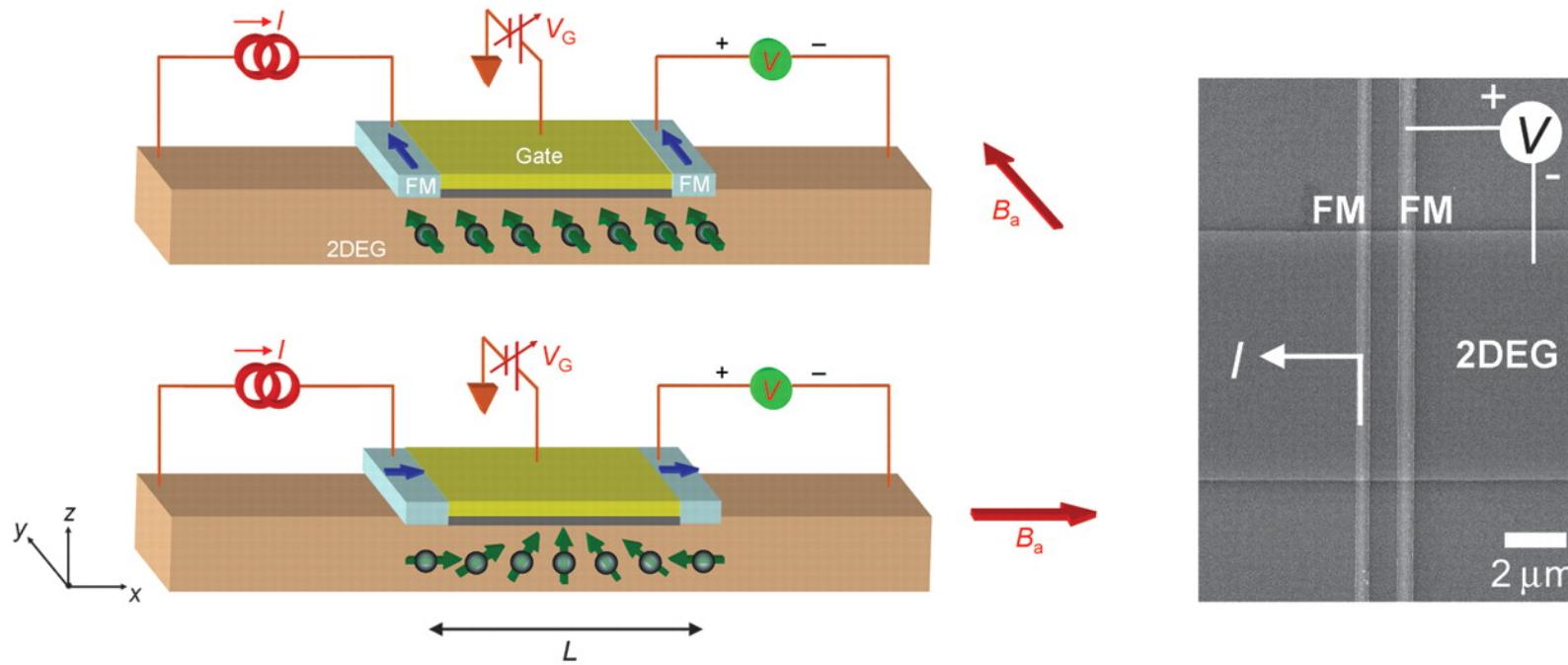
- No spin polarisation reversal induced by a bias voltage.
→ Agrees with calculations.





Recent Demonstration of Spin FET Operation

Gate operation in a NiFe / InGaAs / NiFe spin FET : *



* H. C. Koo et al., *Science* **325**, 1515 (2009).



Theoretical Studies - $FM \rightarrow SC$

FM / SC Interfaces :

Ohmic contacts :

- Diffusive process : 100 % spin polarisation in FM is crucial.
→ DMS, Heusler compounds and half-metallic FM as FM

G. Schmidt *et al.*, *Phys. Rev. B* **62**, R4790 (2000).

Schottky / tunnel barrier contacts :

- Ballistic process : $R_{SC} \ll R_{tunnel}$

E. I. Rashba, *Phys. Rev. B* **62**, 16267 (2000).

P. Mavropoulos *et al.*, *Phys. Rev. B* **66**, 024416 (2002).

Spin coherence length :

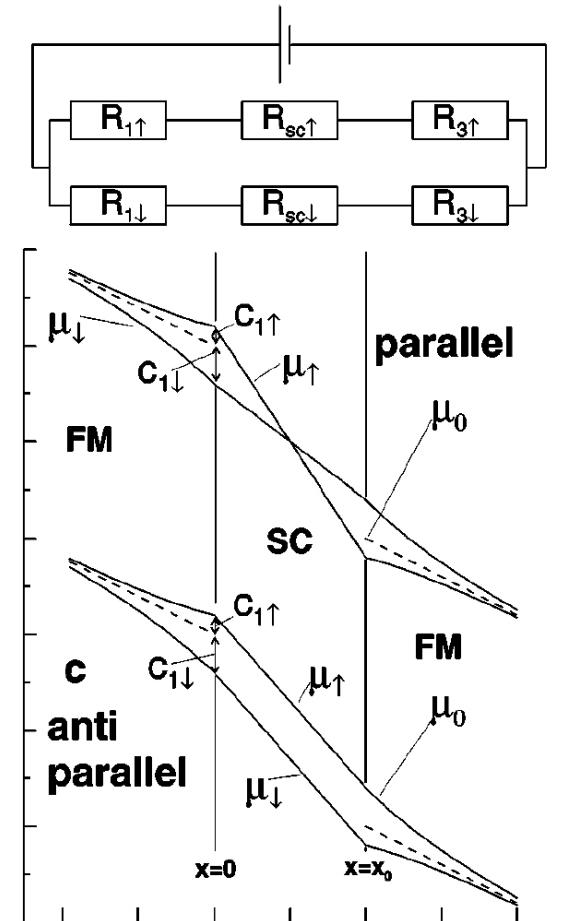
- Spin life time : electrons \gg holes

M. E. Flatté and G. Vignale, *Appl. Phys. Lett.* **78**, 1273 (2001).

Spin modulation :

- Spin orientation \propto gate voltage

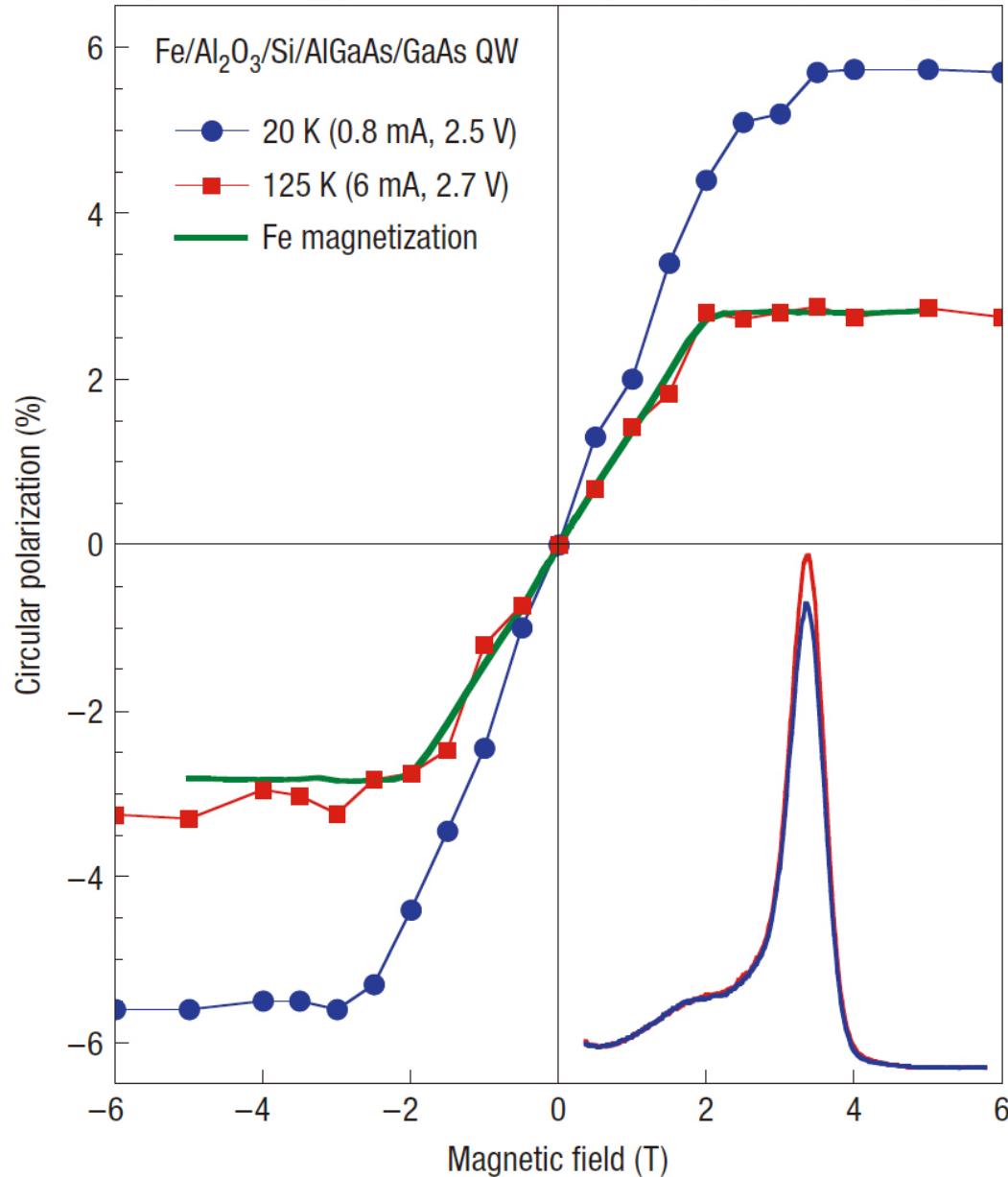
A. Bournel *et al.*, *Mater. Sci. Forum* **297**, 205 (1999).





Spin Injection into Si

Ballistic spin injection into Si : *

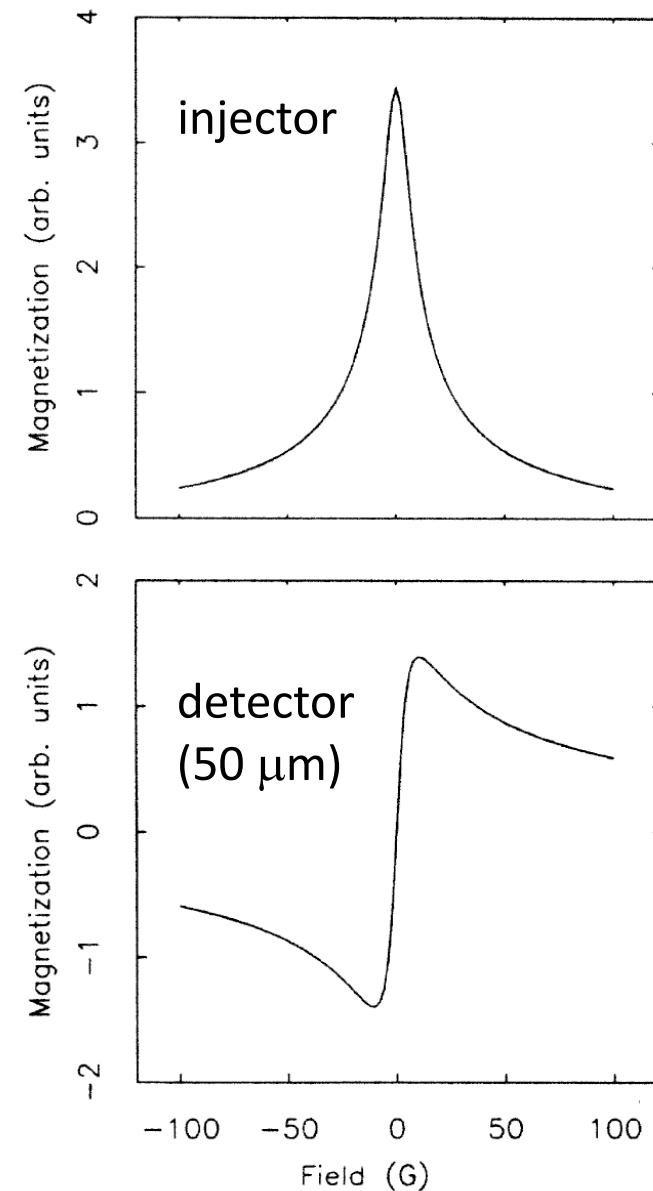
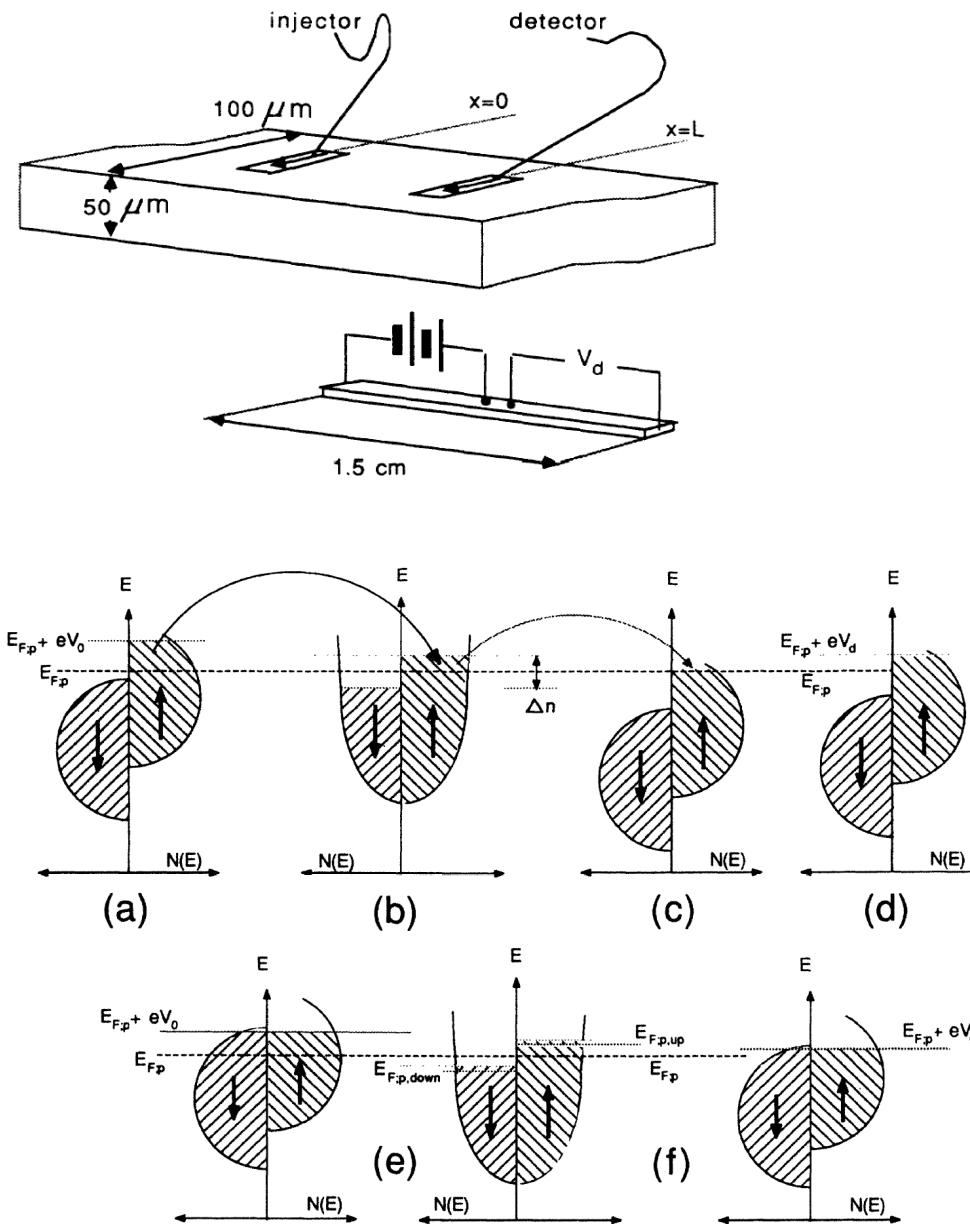


* B. T. Jonker *et al.*, *Nature Phys.* **3**, 542 (2007).



Johnson Transistors

All-metallic transistors : *

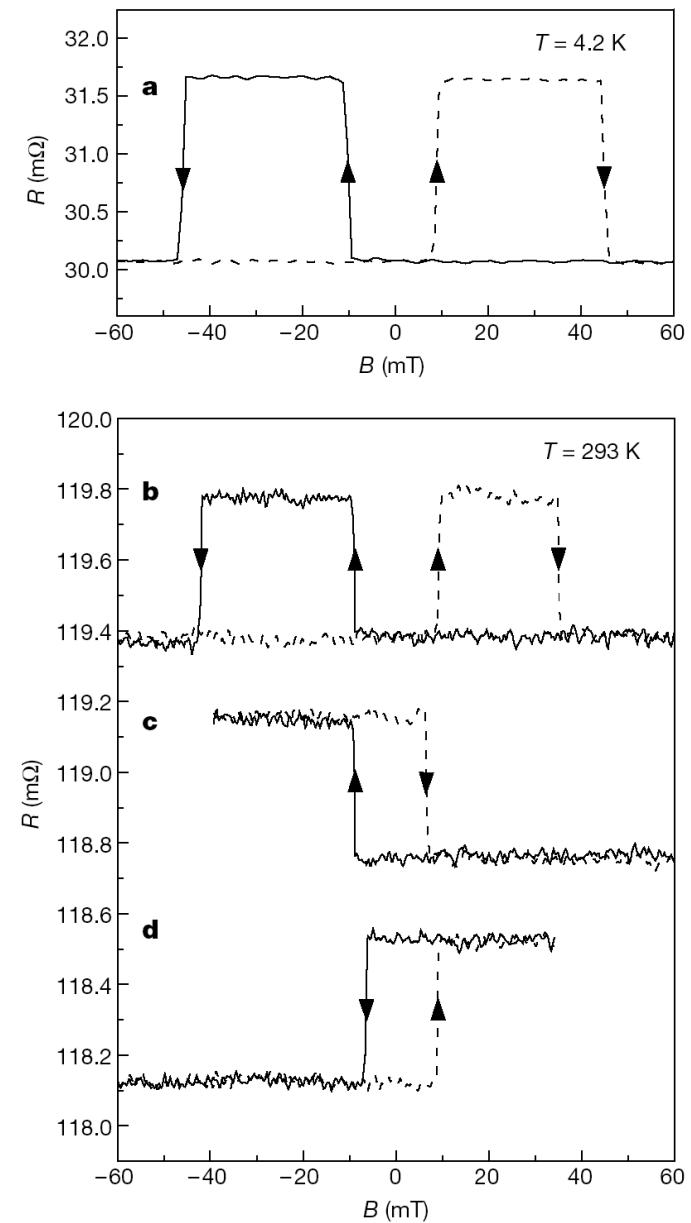
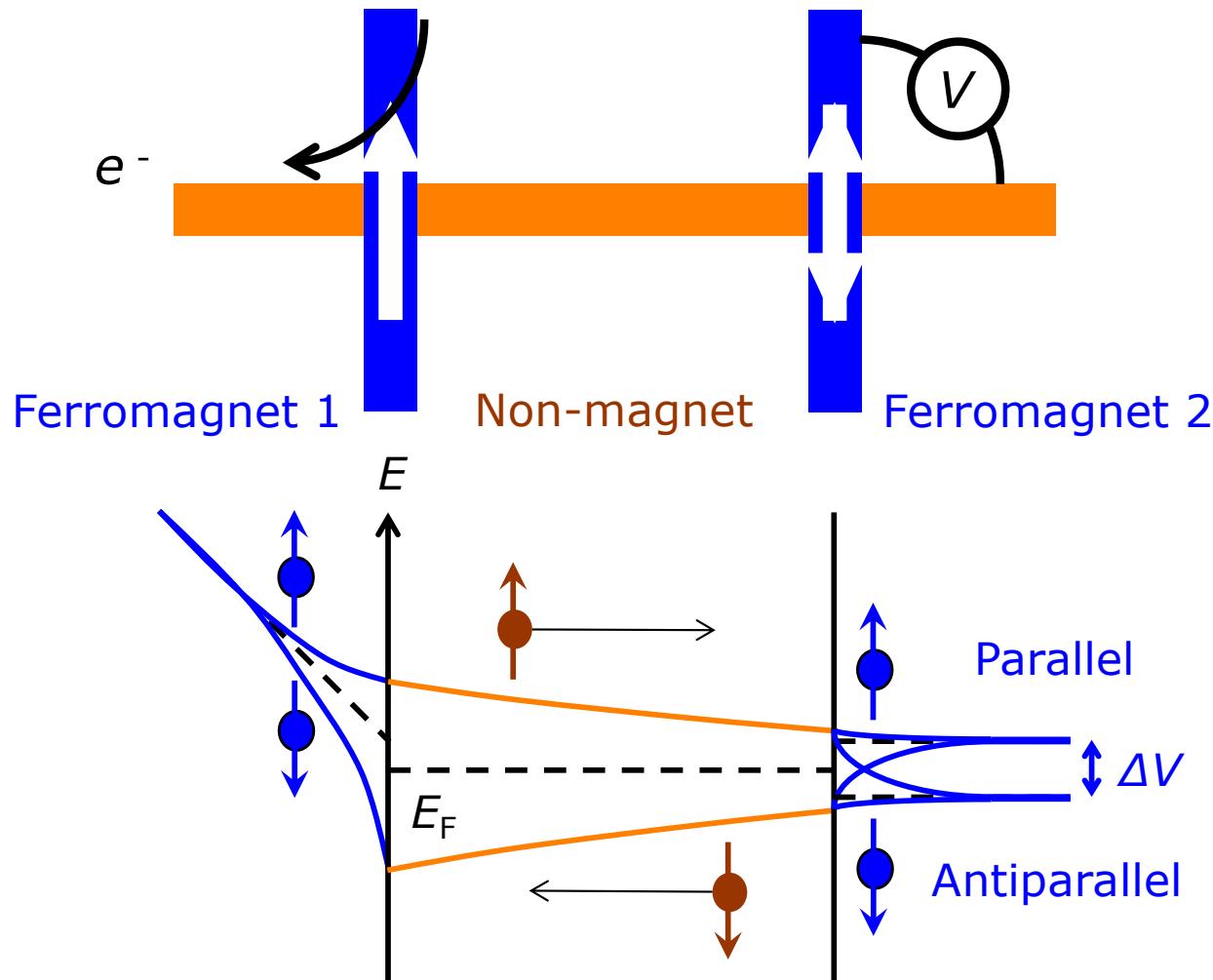


* M. Johnson and R. H. Silsbee, *Phys. Rev. Lett.* **56**, 1790 (1985), *Phys. Rev. B* **37**, 5312 (1988).



Recent Improvement

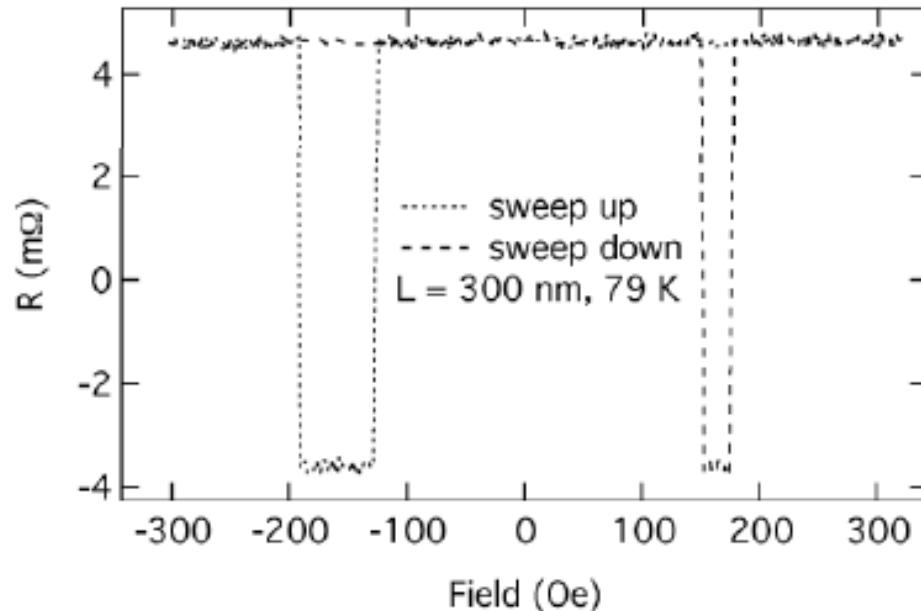
Lateral spin-valve structures with Co / Al / Co nano-wires : *





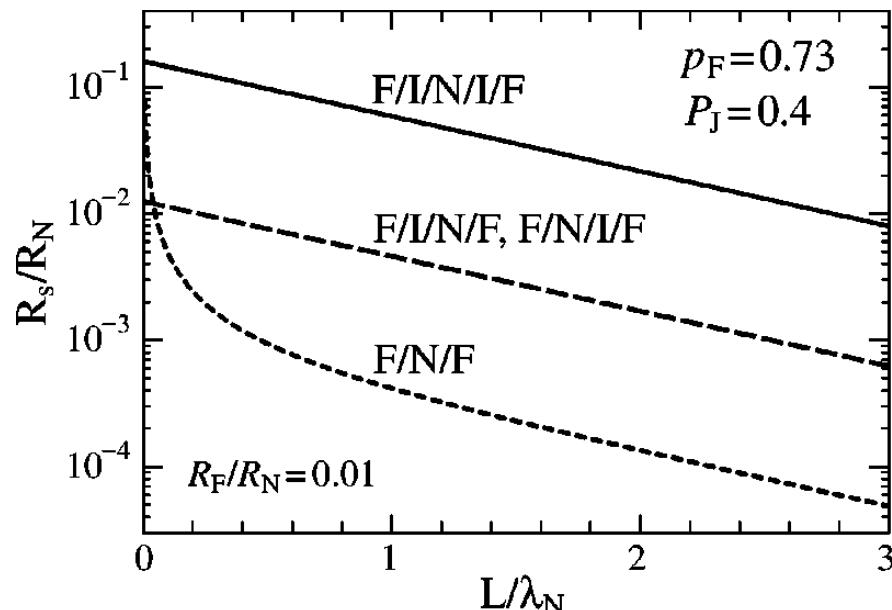
Further Enhancement in Spin-Valve Signals

Spin injection into Ag : *



Increase by one order of magnitude.

Interfacial control : **



Increase spin injection efficiency
by insulator insertion (ballistic injection).

Increase spin detection efficiency
by insulator insertion (spin voltage).
by Ohmic contact (spin current).

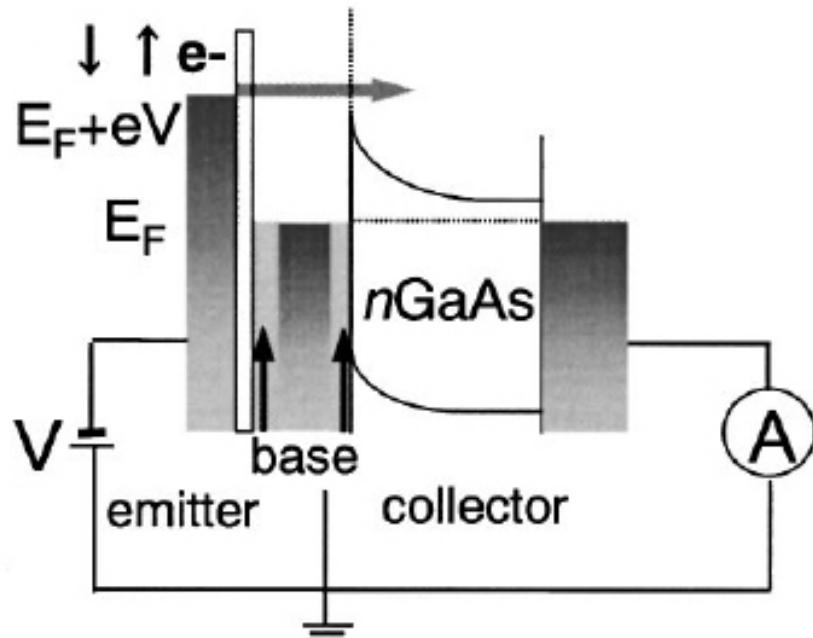
* R. Godfrey and M. Johnson, *Phys. Rev. Lett.* **96**, 136601 (2006);

** S. Takahashi and S. Maekawa, *Phys. Rev. B* **67**, 052409 (2003).

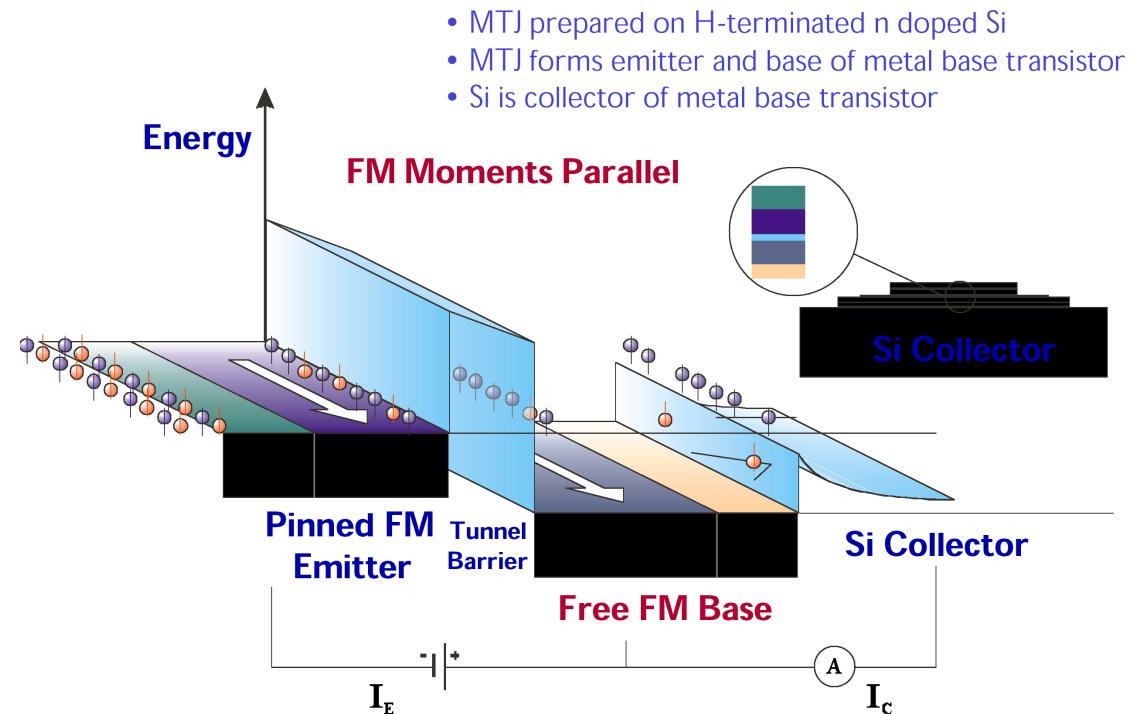


Spin Valve / Magnetic Tunnel Transistors

Spin valve transistor : *



Magnetic tunnel transistor : **



Combining semiconductor with GMR / TMR devices :
→ First step towards all metal devices

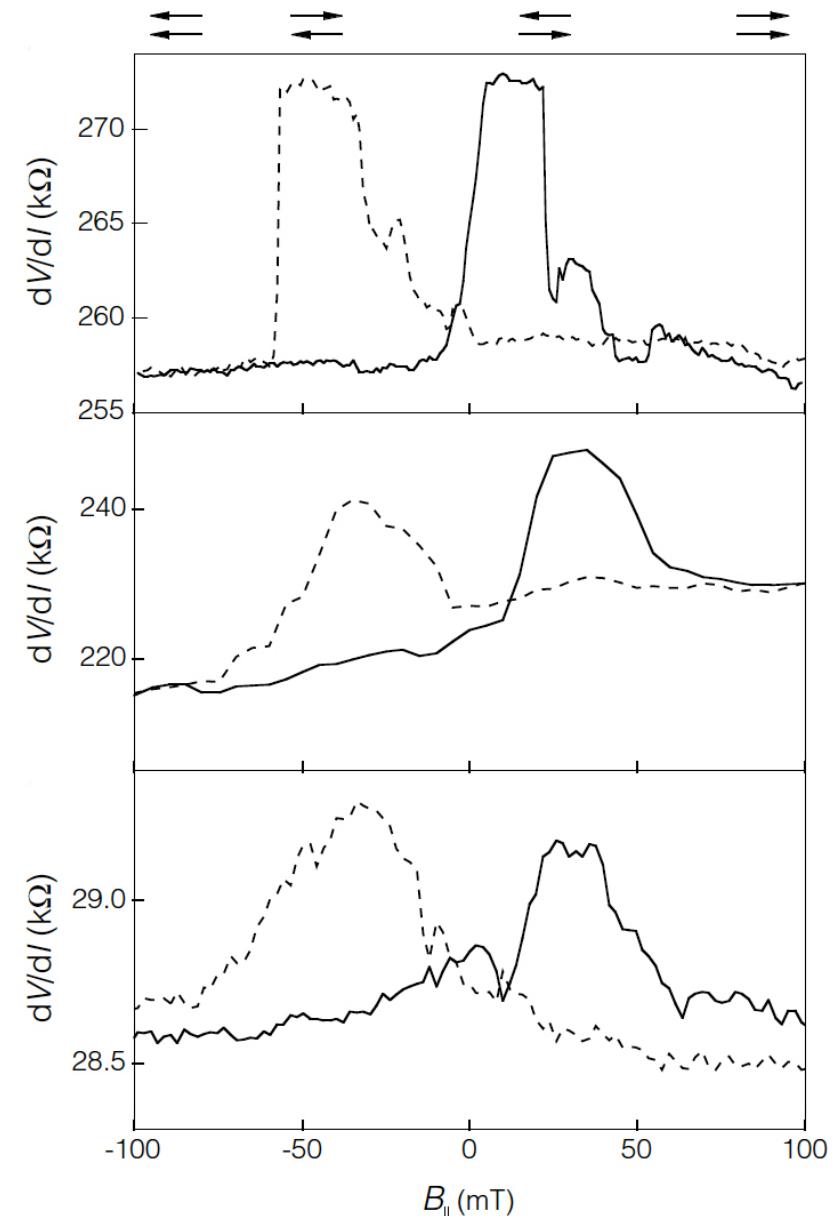
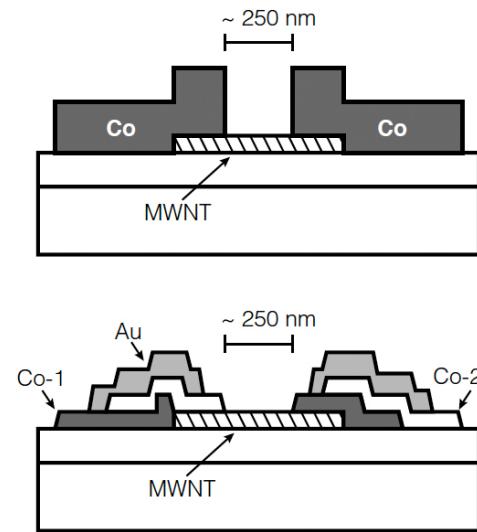
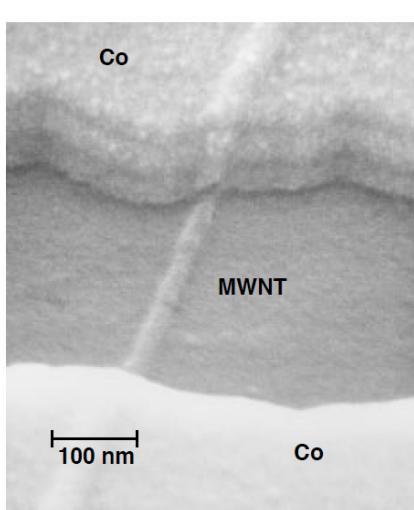
* R. Sato and K. Mizushima, *Appl. Phys. Lett.* **79**, 1157 (2001); D. J. Monsma et al., *Science* **281**, 407 (1998);

** S. S. P. Parkin, *1st Int'l Sch. on Spintronics and Quantum Info. Tech.*, May 13-15, 2001 (Maui, HI, USA).

Spin Transport in a CNT



Magnetoresistance in a multi-wall (MW) CNT :



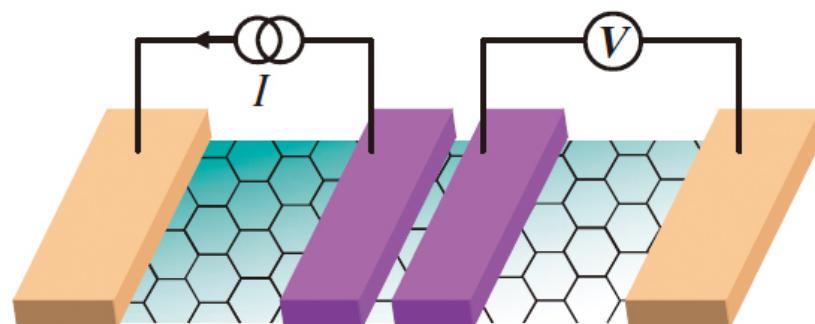
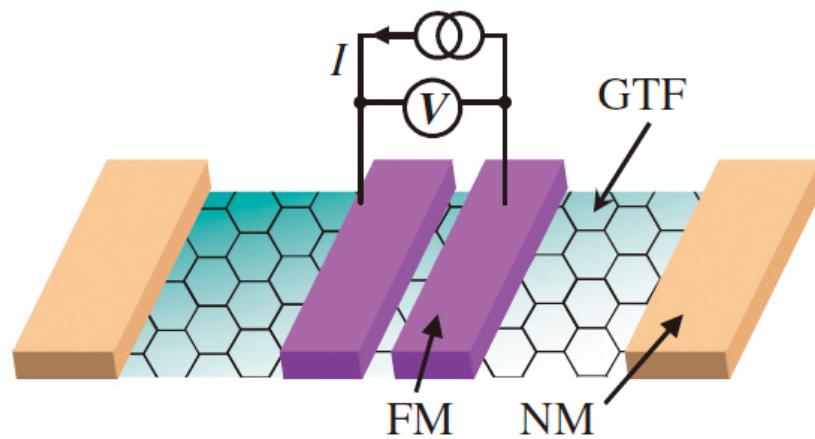
* K. Tsukagoshi *et al.*, *Nature* **401**, 572 (1999).



Spin Transport in Graphene

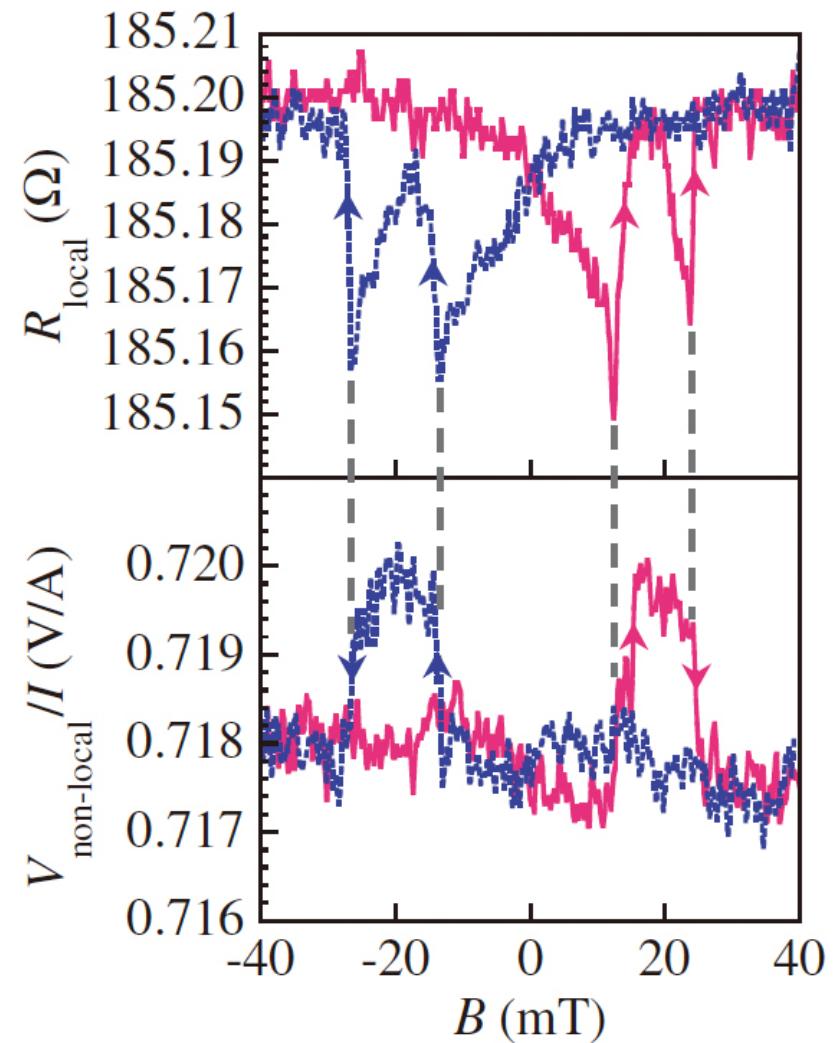
Spin transport in graphene at room temperature :

Local 2-terminal measurement



Non-local 4-terminal measurement

Anisotropic magnetoresistance (AMR)

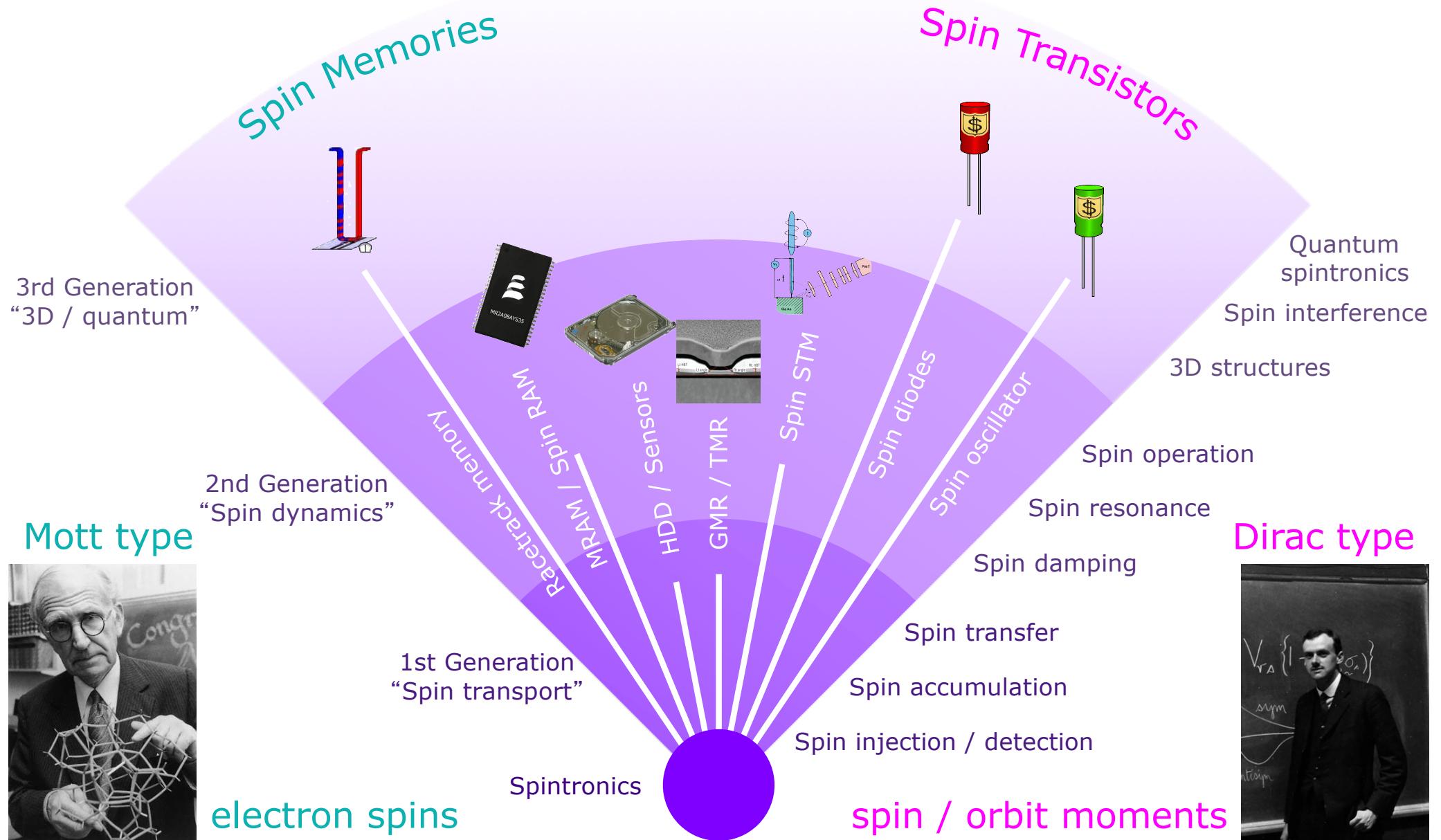


Spin transport signals

Nano-Spintronic Devices



Development of nano-spintronic devices : *



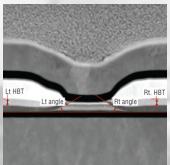
* A. Hirohata and K. Takanashi, *J. Phys. D: Appl. Phys.* **47**, 1930001 (2014).



Two Categories for Spintronic Devices

Mott-type

Electron (hole) spins



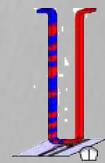
GMR / TMR



HDD / Sensors



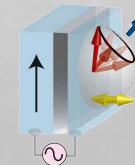
MRAM / Spin RAM



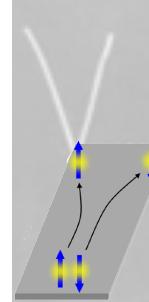
Racetrack memory

Dirac-type

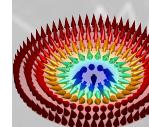
Spin and orbital moments



TAMR



Spin Hall



Skyrmions

Spin transistor



Spin LED

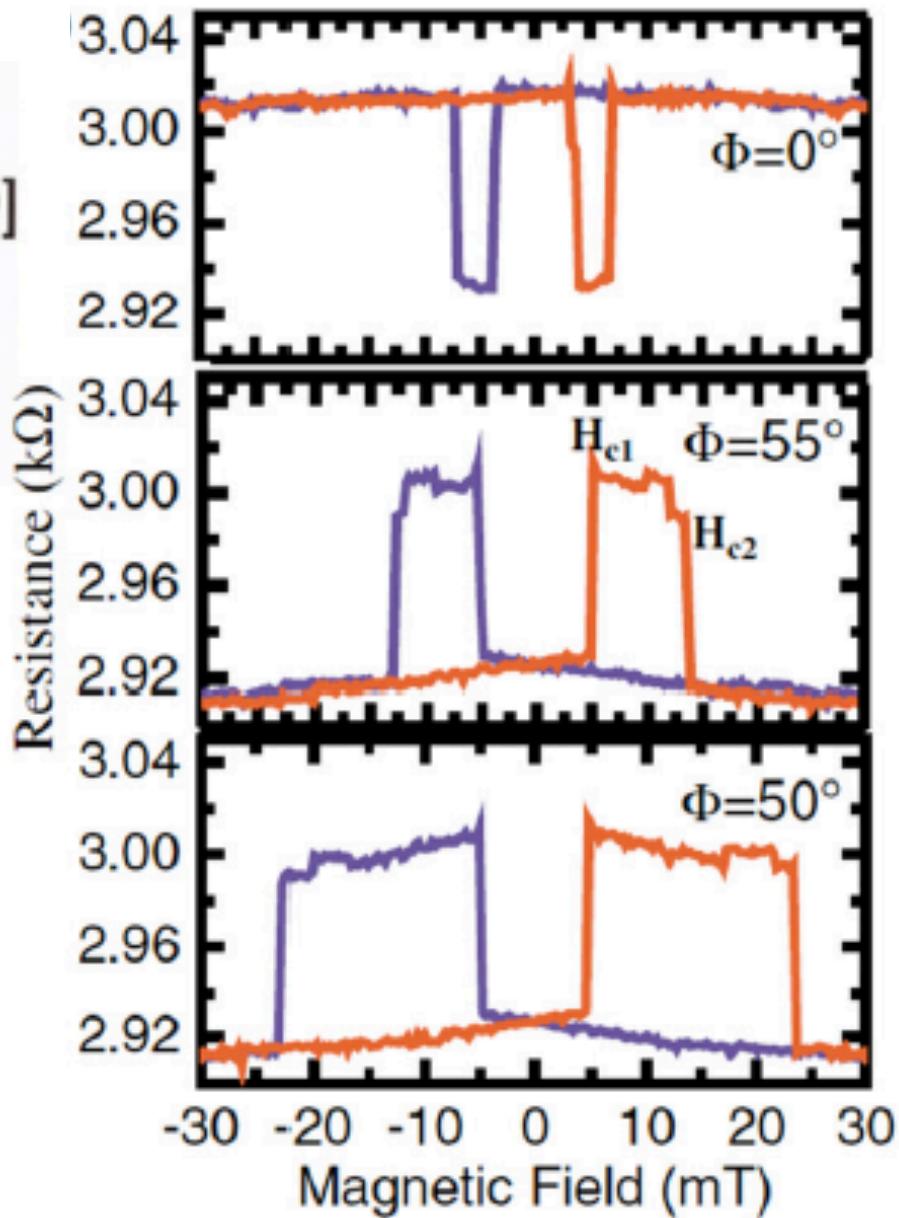
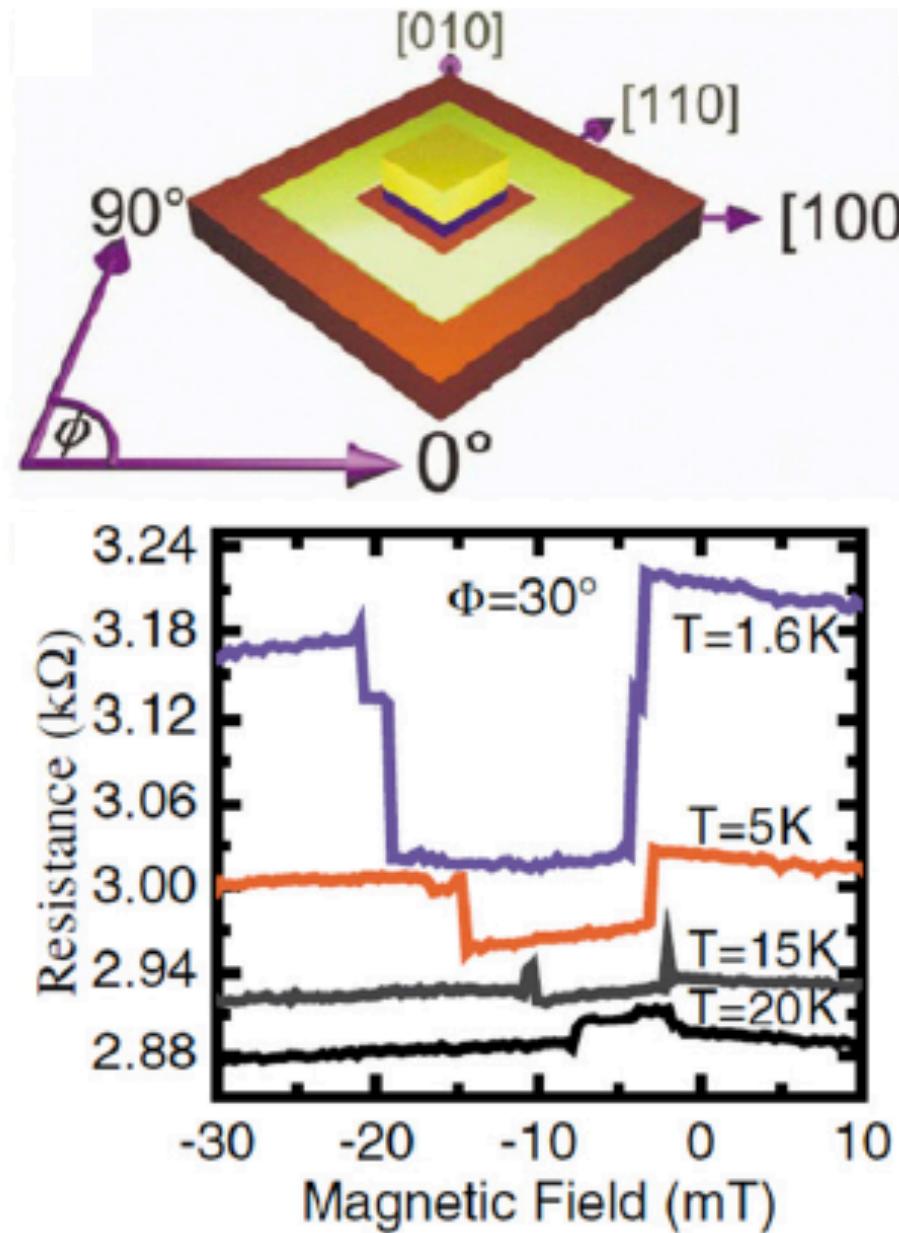


* After J. Sinova and I. Zutic, *Nature Mater.* **11**, 368 (2012).



Tunnelling Anisotropic Magnetoresistance

70 nm GaMnAs / GaAs (001) : *

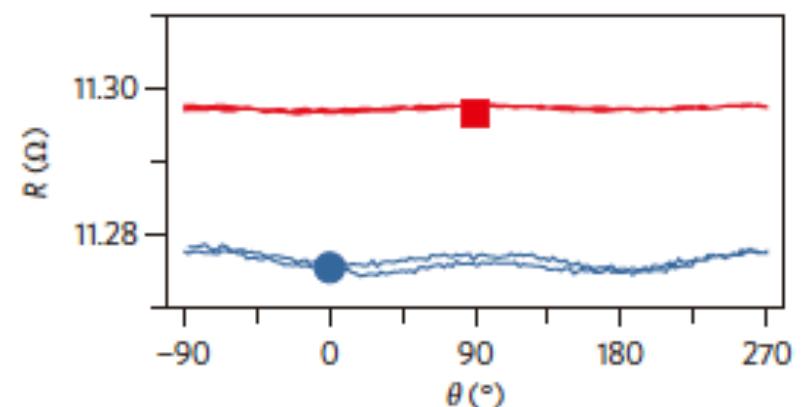
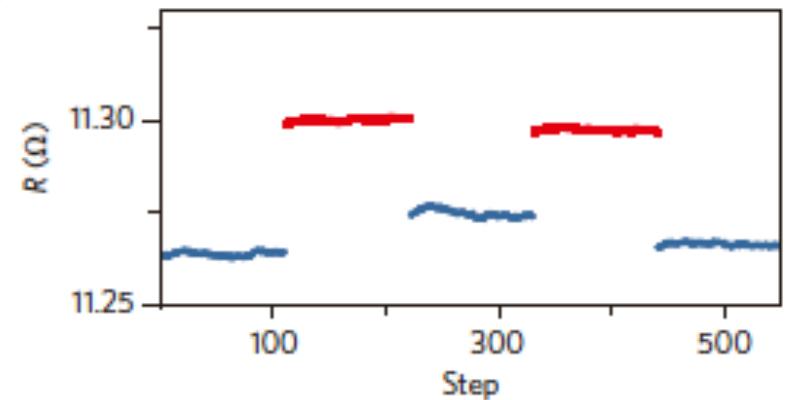
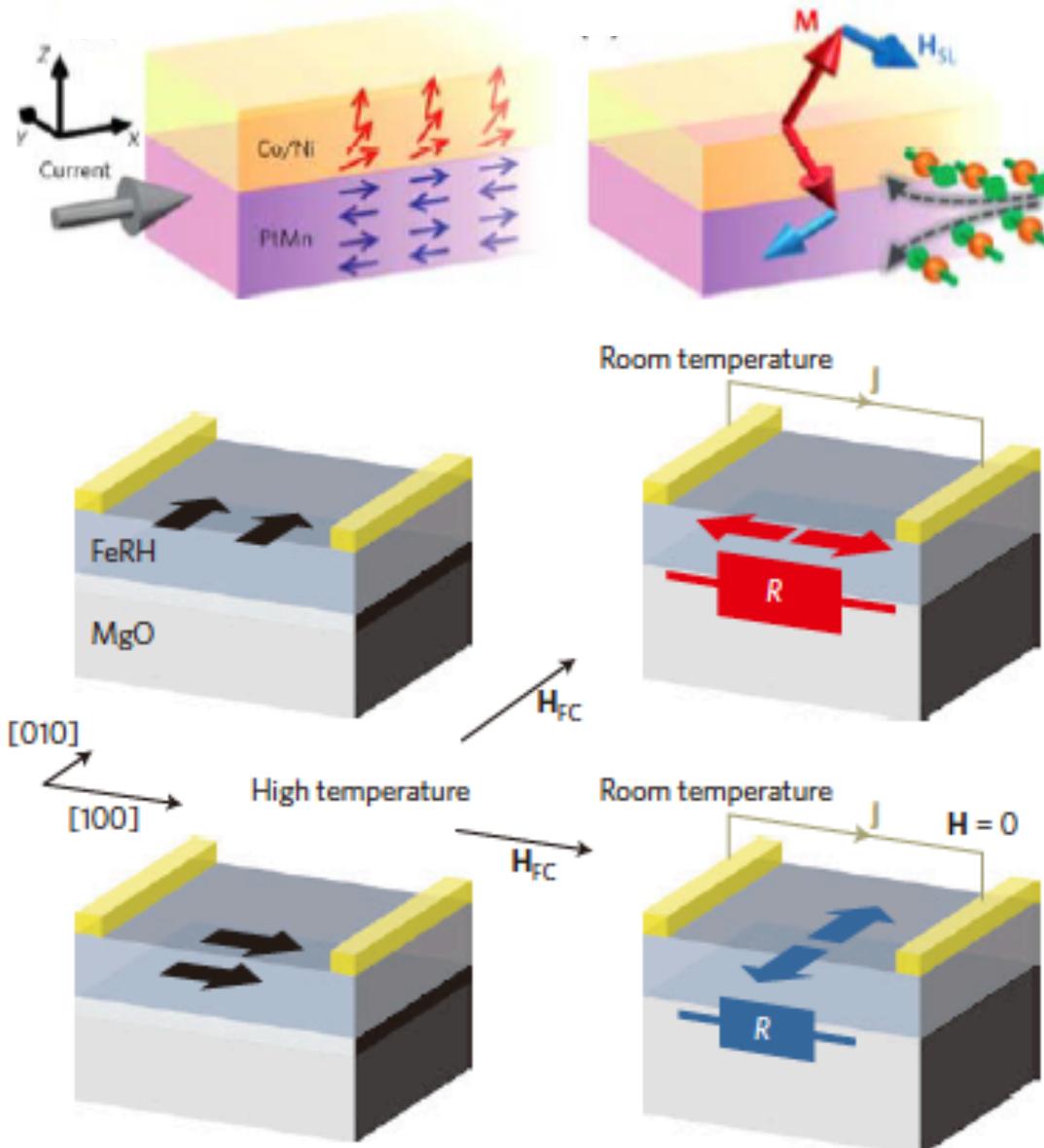


* C. Gould *et al.*, *Phys. Rev. Lett.* **93**, 117203 (2004).



Antiferromagnetic Spintronics

Similar spin-current generation can be achieved with an antiferromagnet : *



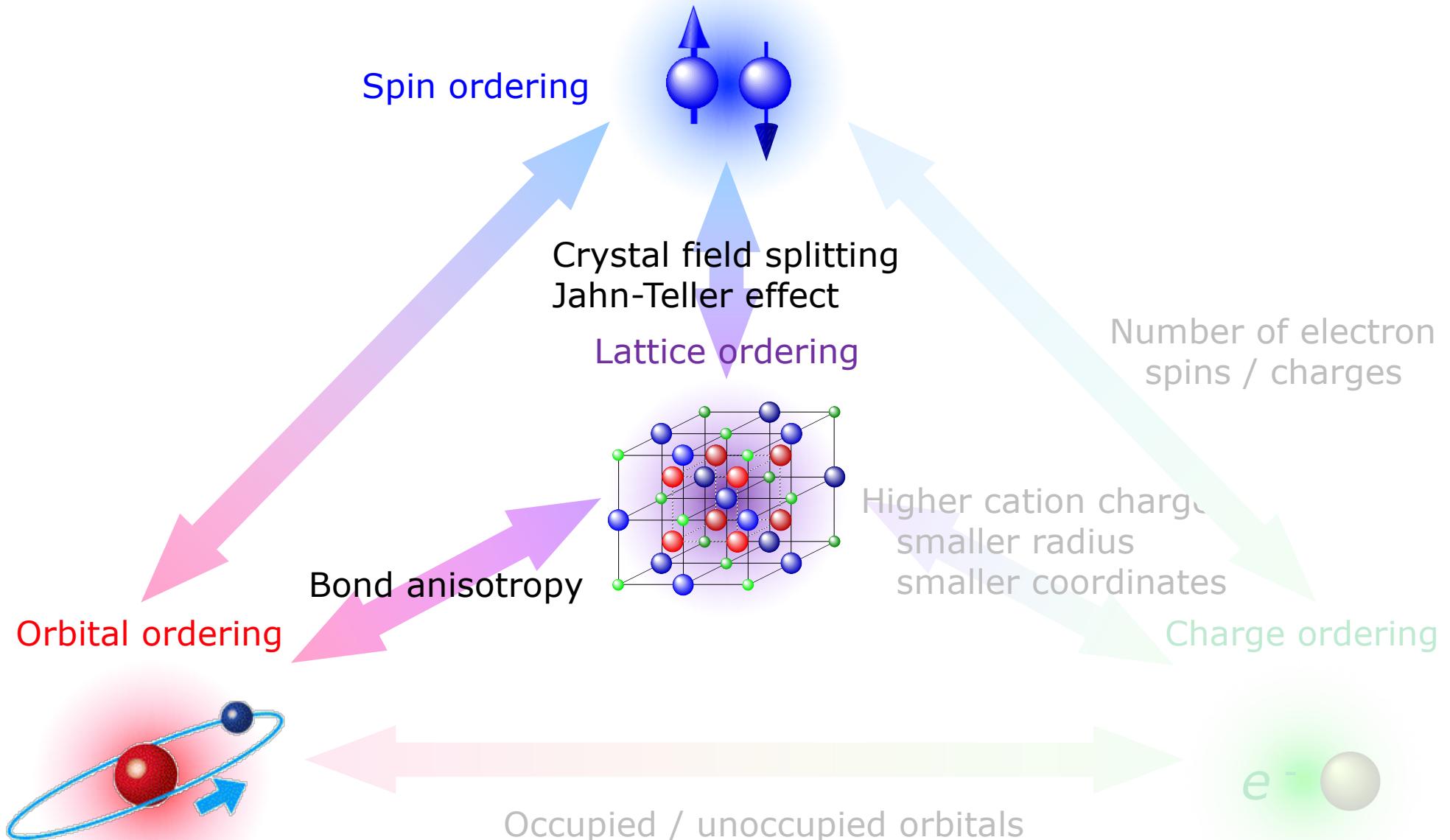
* O. Gomonay et al., *Phys. Status Solidi* **11**, 1700022 (2017);

** T. Jungwirth et al., *Nature Nanotechnol.* **11**, 231 (2016).



Spin-Orbit Interaction

In strongly correlated systems : *

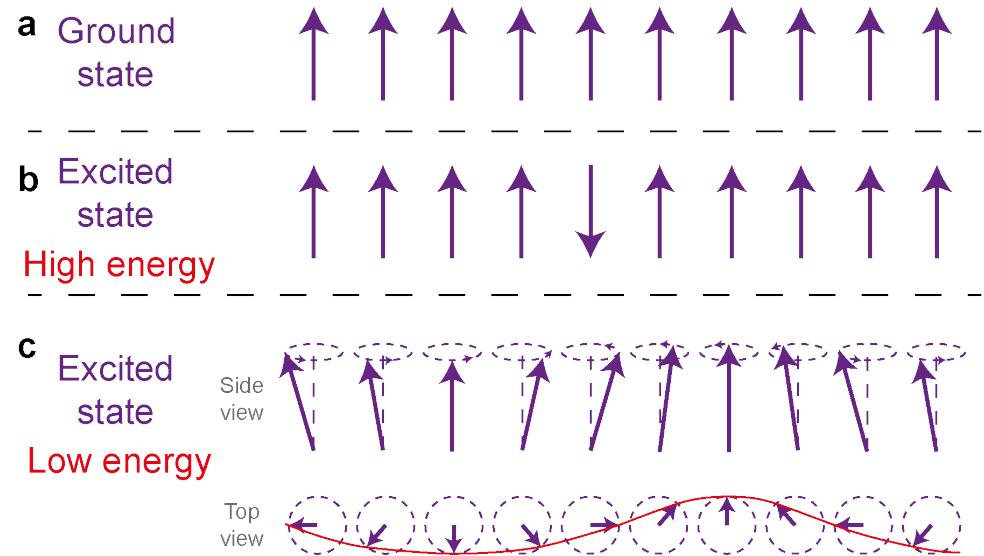
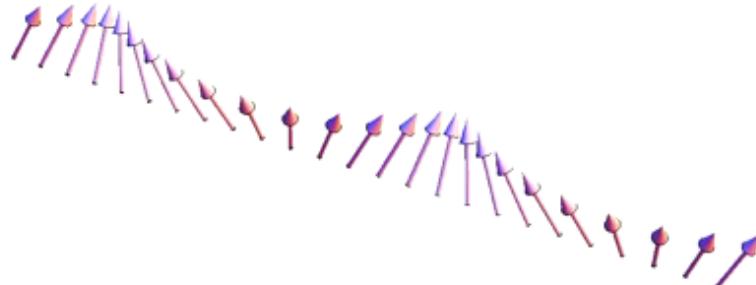


* After <https://www.slideshare.net/algerien1970/electrical-transport-and-magnetic-interactions-in-3d-and-5d-transition-metal-oxides>.

Spin Wave

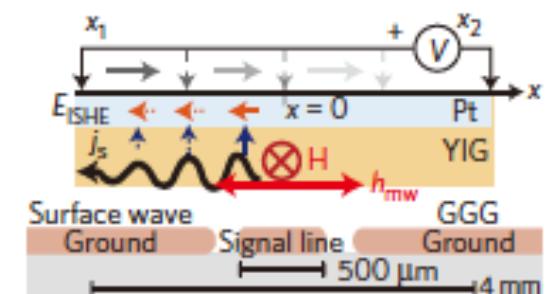
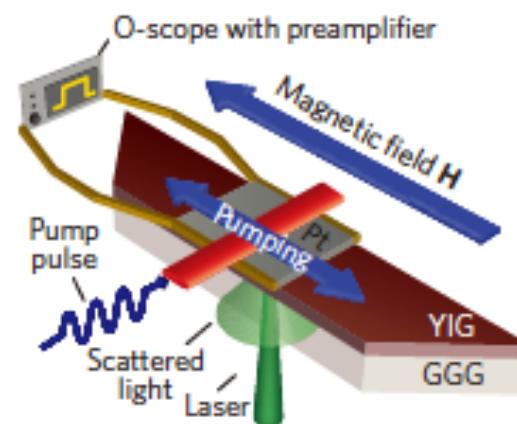
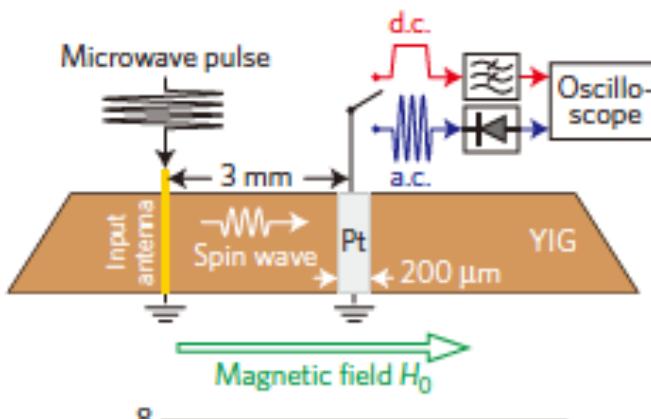


Spin wave (magnon) : *



Analogous to phonon, quantised crystalline lattice.

Magnon introduction : **



* <https://www.youtube.com/watch?v=pWQ3r-2Xjeo>

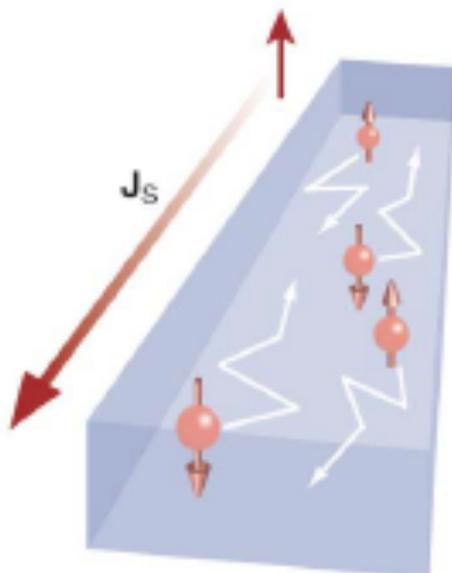
** A. V. Chumak *et al.*, *Nature Phys.* **11**, 453 (2015).



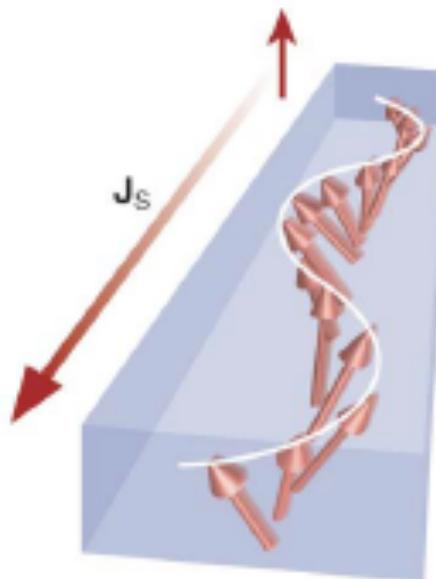
Microwave-Induced Spin Currents

Spin-polarised currents can be introduced by electromagnetic wave : *

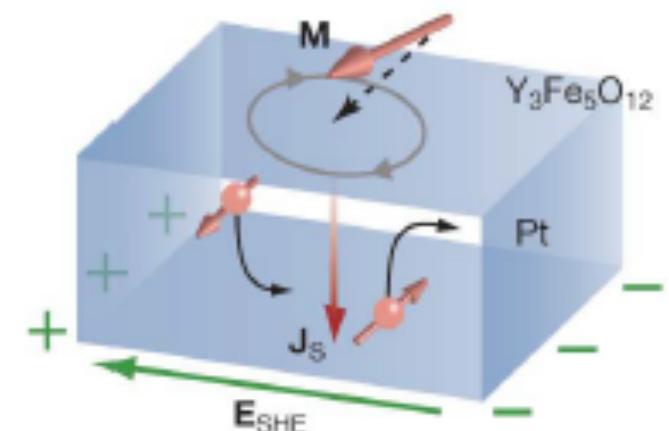
Conduction-electron spin current



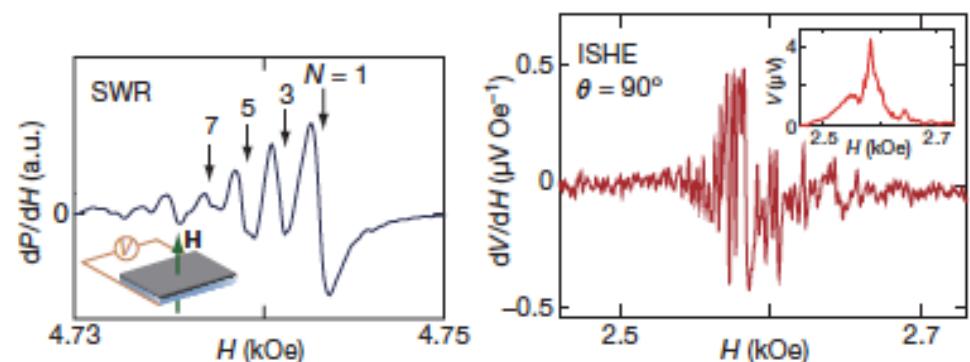
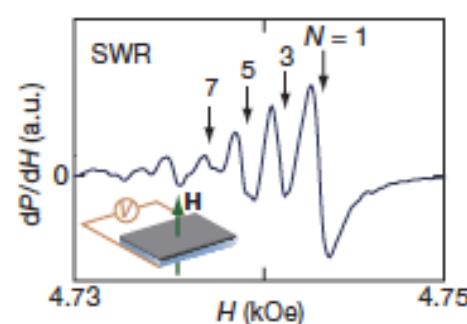
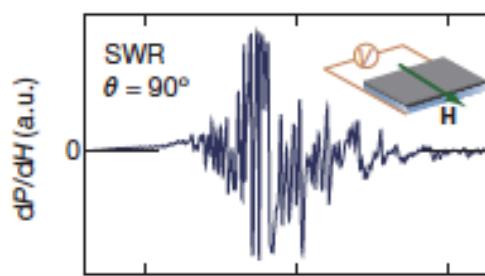
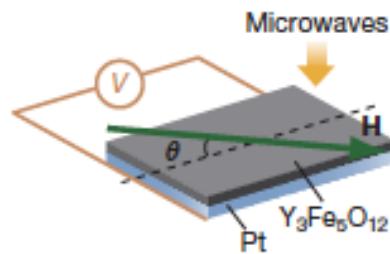
Spin-wave spin current



Inverse spin-Hall effect



$$E_{SHE} \parallel J_S \times \sigma$$

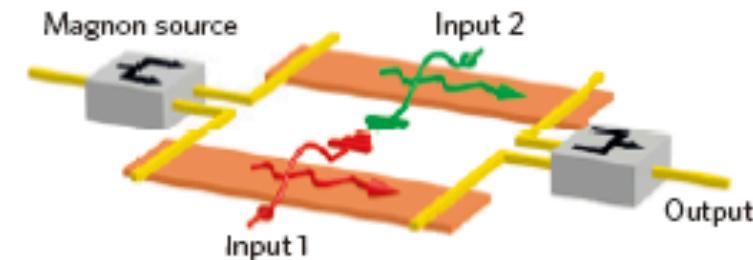


* Y. Kajiwara et al., *Nature* **464**, 262 (2010).

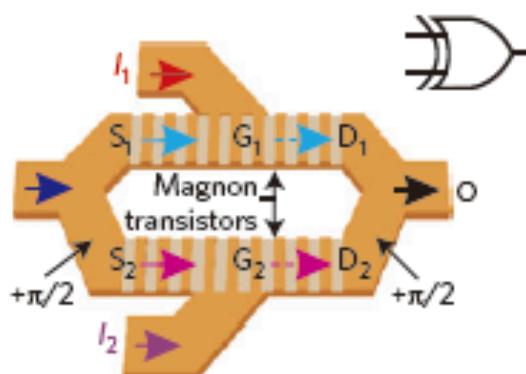
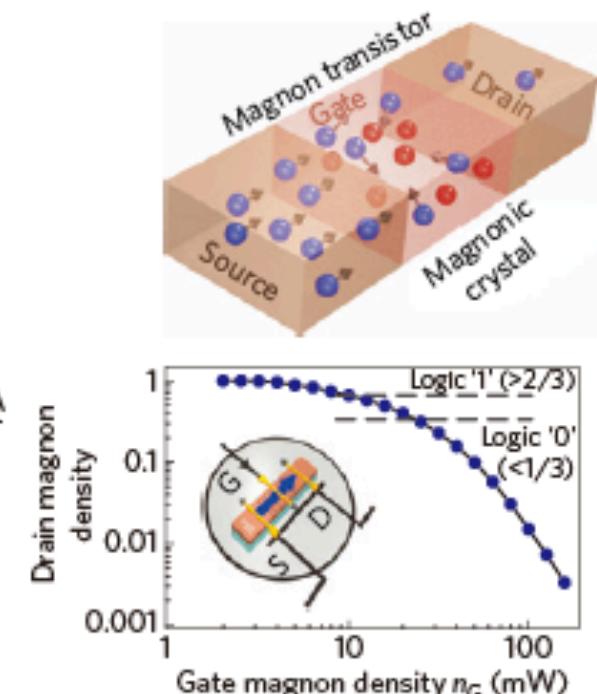
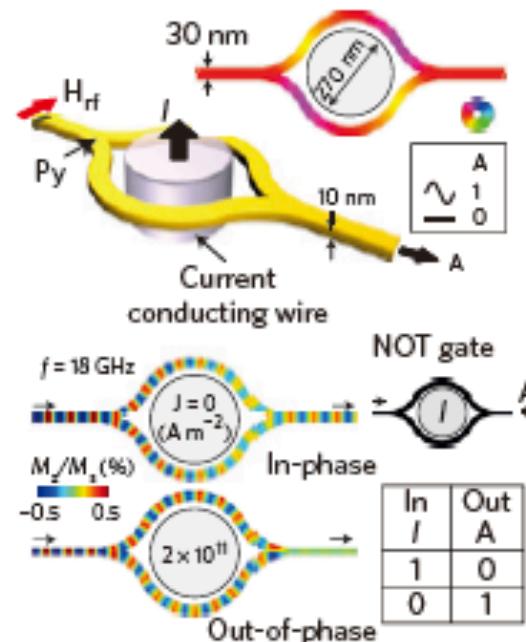
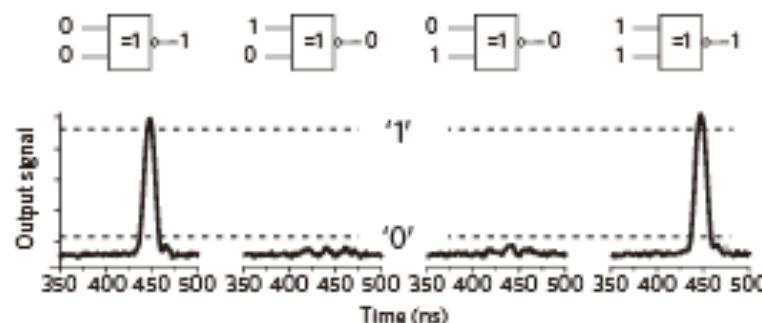
Spin Wave Logics



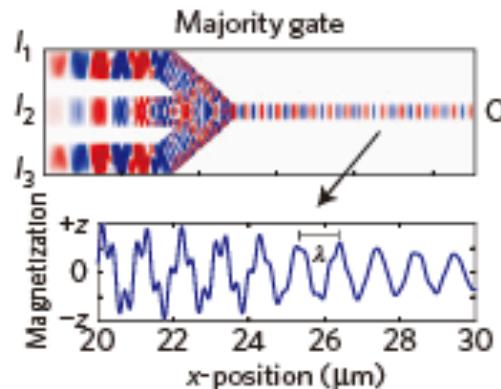
Magnonics : *



XNOR



I_1	I_2	O
0	0	0
0	1	1
1	0	1
1	1	0



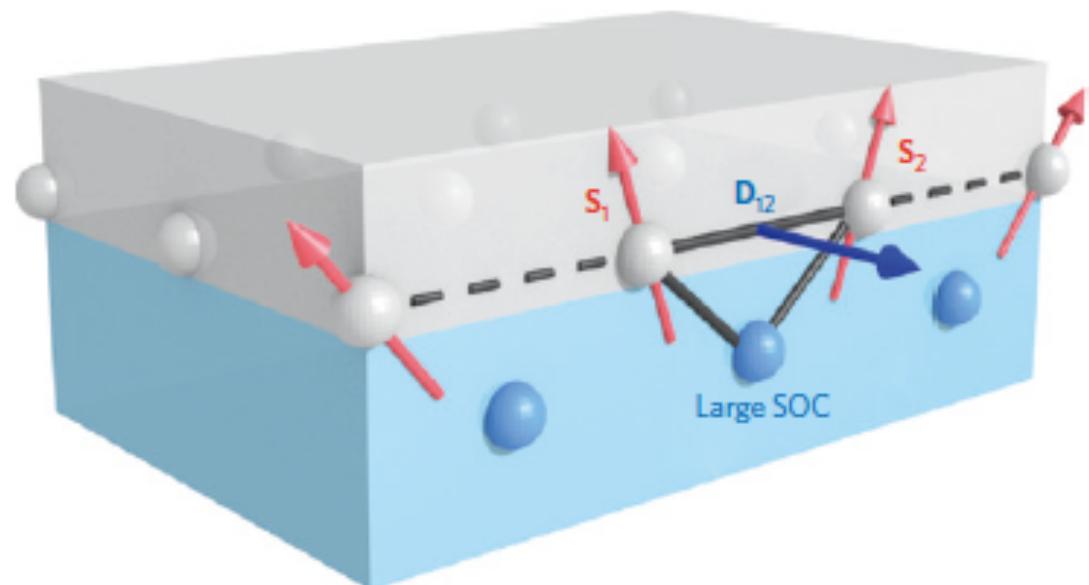
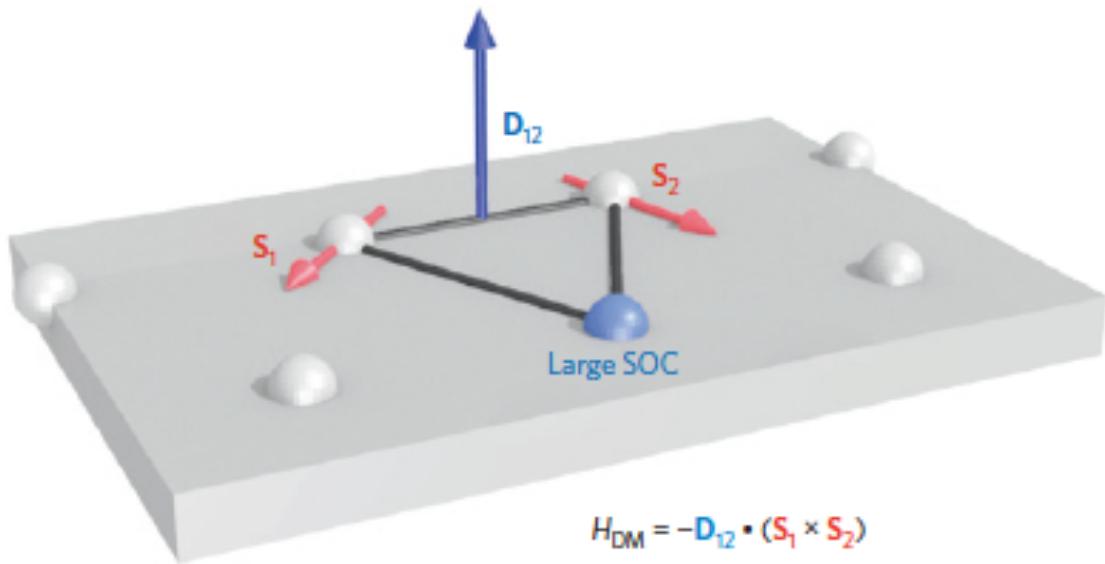
I_1	I_2	$I_3 = I_c$	O
0	0	0	0
1	0	0	0
0	1	0	0
1	1	0	1
0	0	1	0
1	0	1	1
0	1	1	1
1	1	1	1

AND OR



Dzyaloshinskii-Moriya Interactions

Dzaloshinskii-Moriya interactions (DMI) between canted spins : *



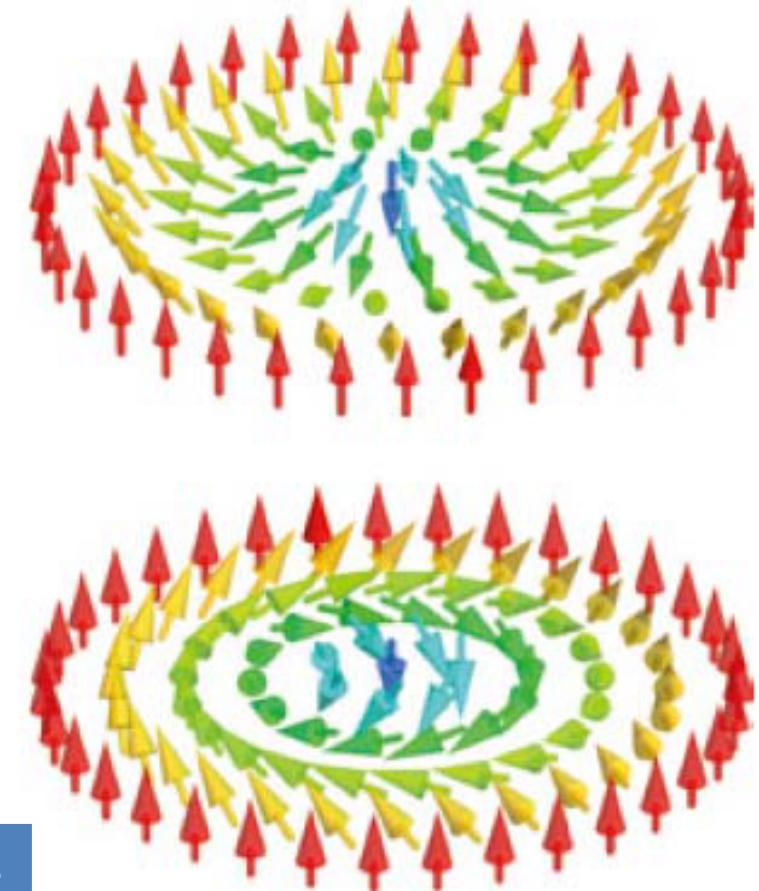
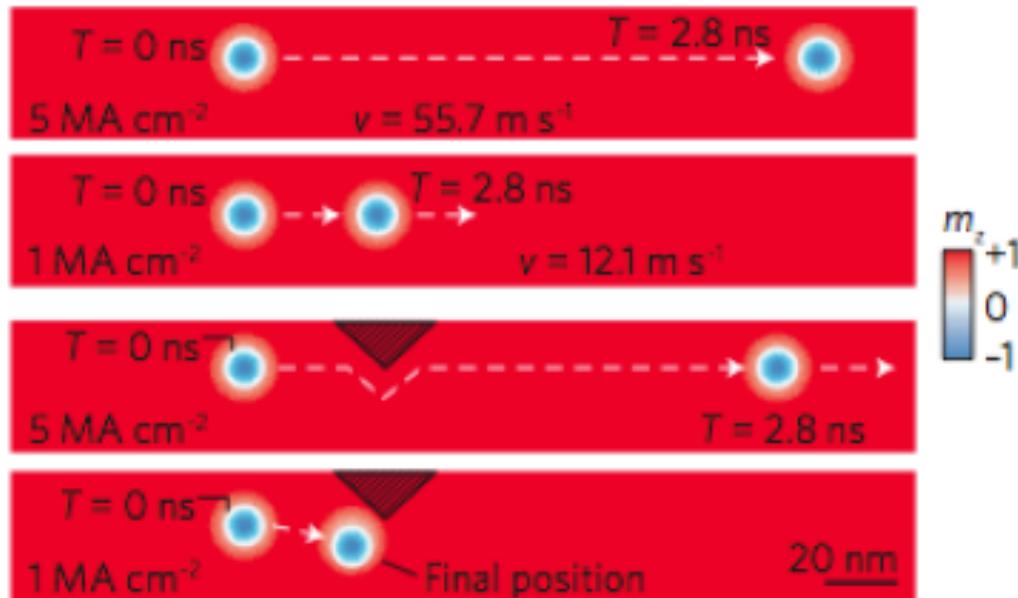
* I. Dzyaloshinskii, *J. Phys. Chem. Solids* **4**, 241 (1958); T. Moriya, *Phys. Rev.* **120**, 91 (1960);

** A. Fert *et al.*, *Nature Nanotechnol.* **8**, 152 (2013).



Skrymion Motion by a Current

$500 \times 40 \times 0.4 \text{ nm}^3$ Co stripes with DMI of 1.4 meV per atom : *



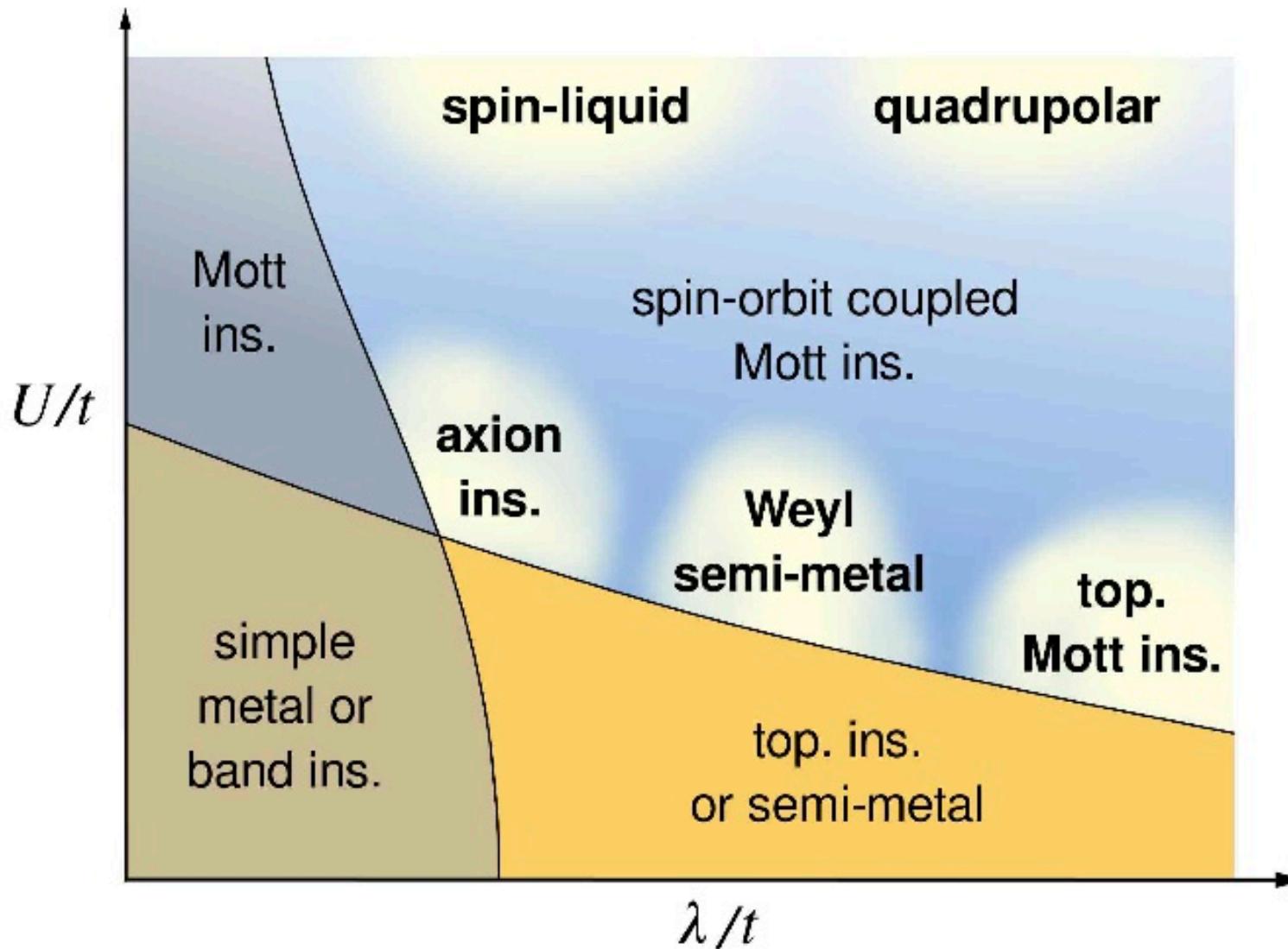
	Skrymions	Domain walls
Size [nm]	1~10	100~1,000
Velocity [m/s]	~100	~500
Critical current density [A/cm]	10^2	$\sim 10^7$

* A. Fert *et al.*, *Nature Nanotechnol.* **8**, 152 (2013);

** N. Romming *et al.*, *Phys. Rev. Lett.* **114**, 177203 (2015).

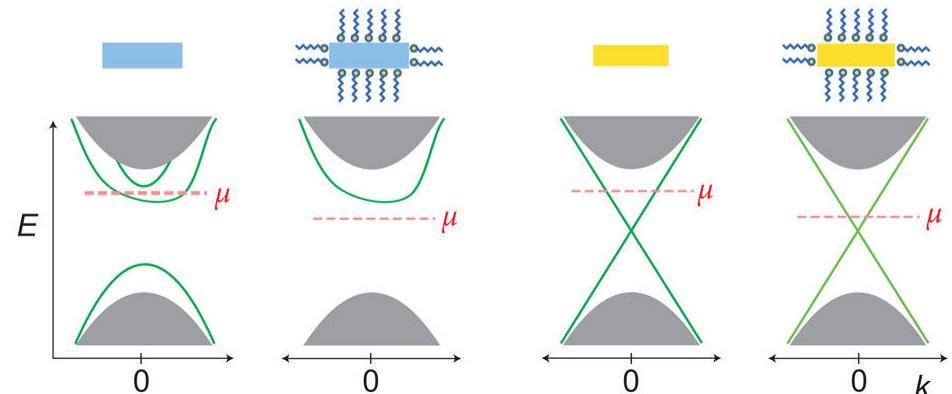
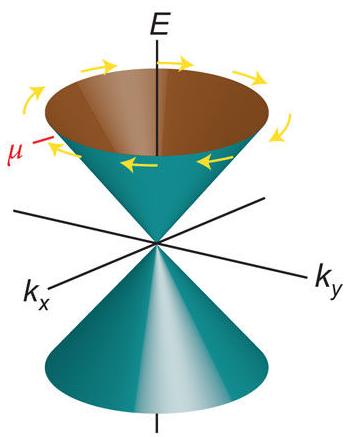
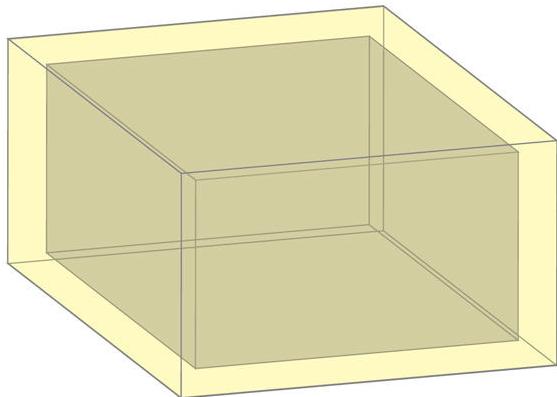
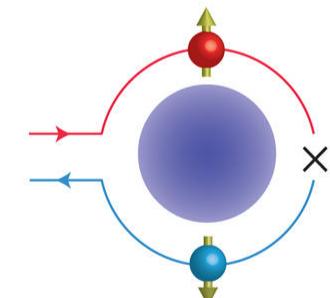
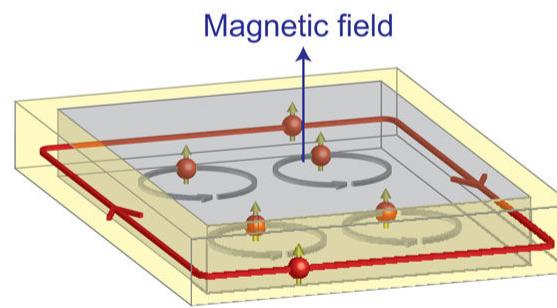
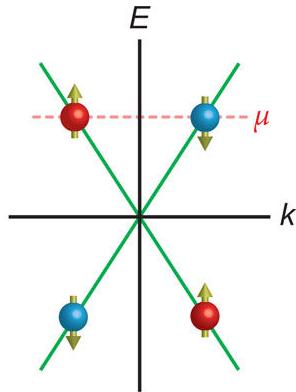
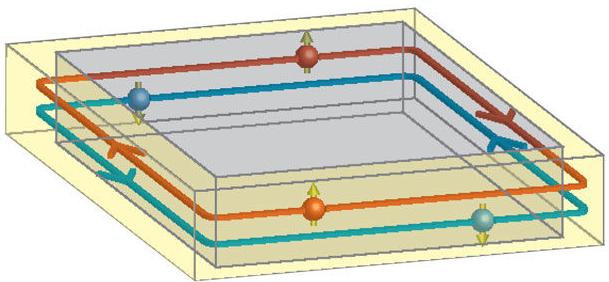


Spin-Orbit Coupling Energy





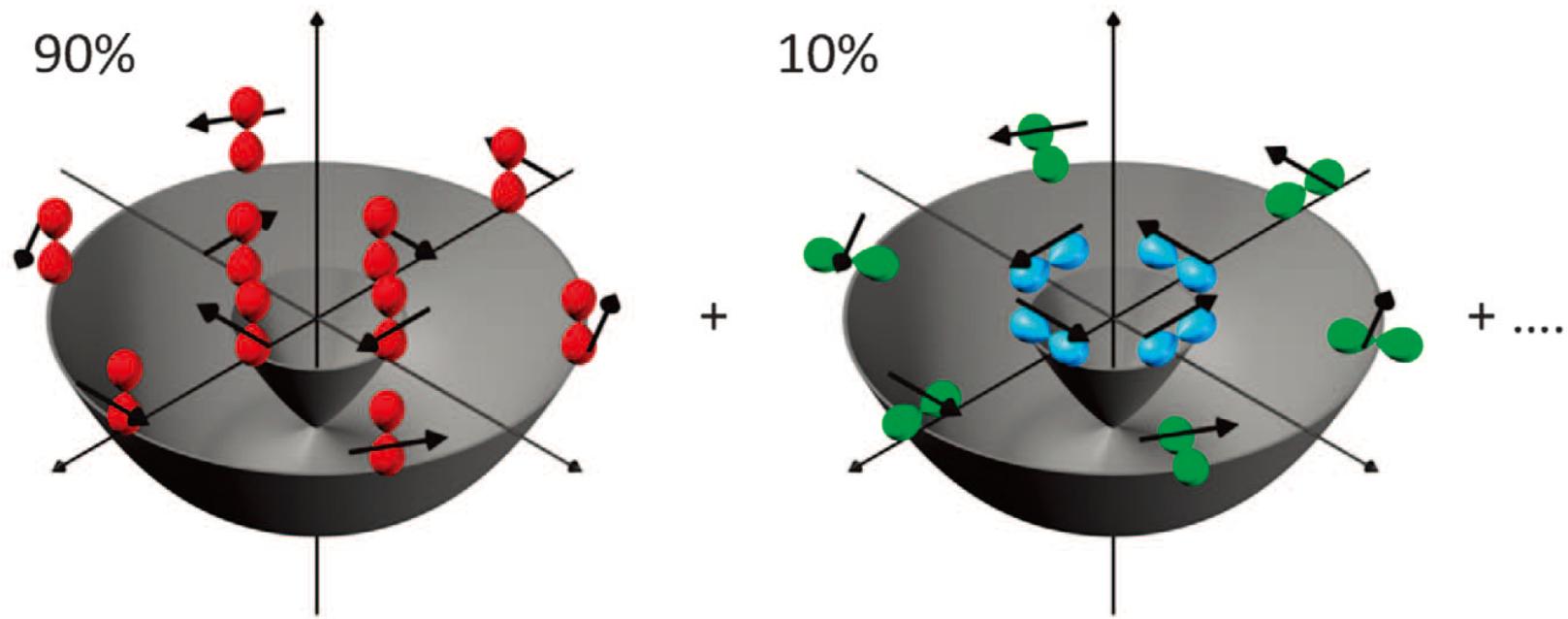
Topological Insulators



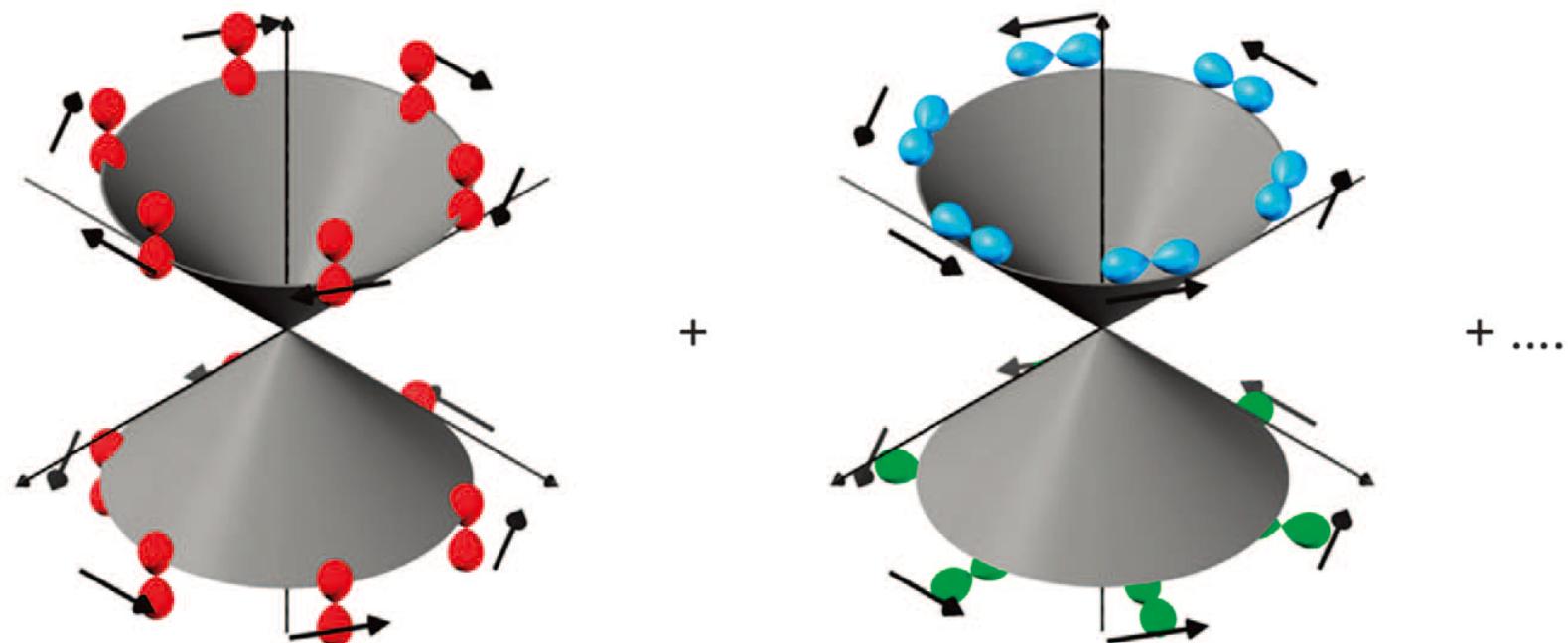


Spin Coupled to In-Plane Orbit

Rashba



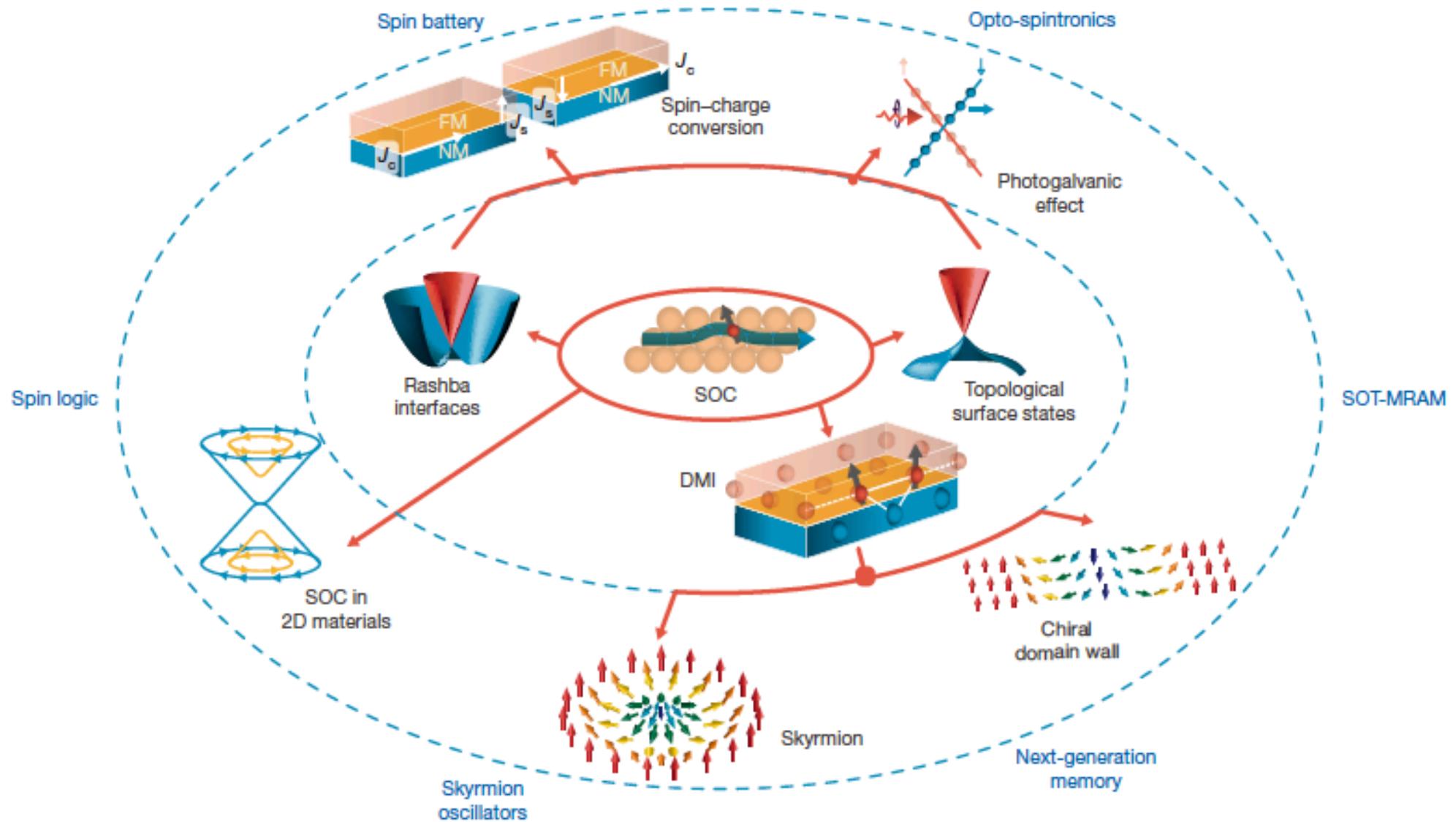
Topological Insulator





Phenomena with the Spin-Orbit Coupling

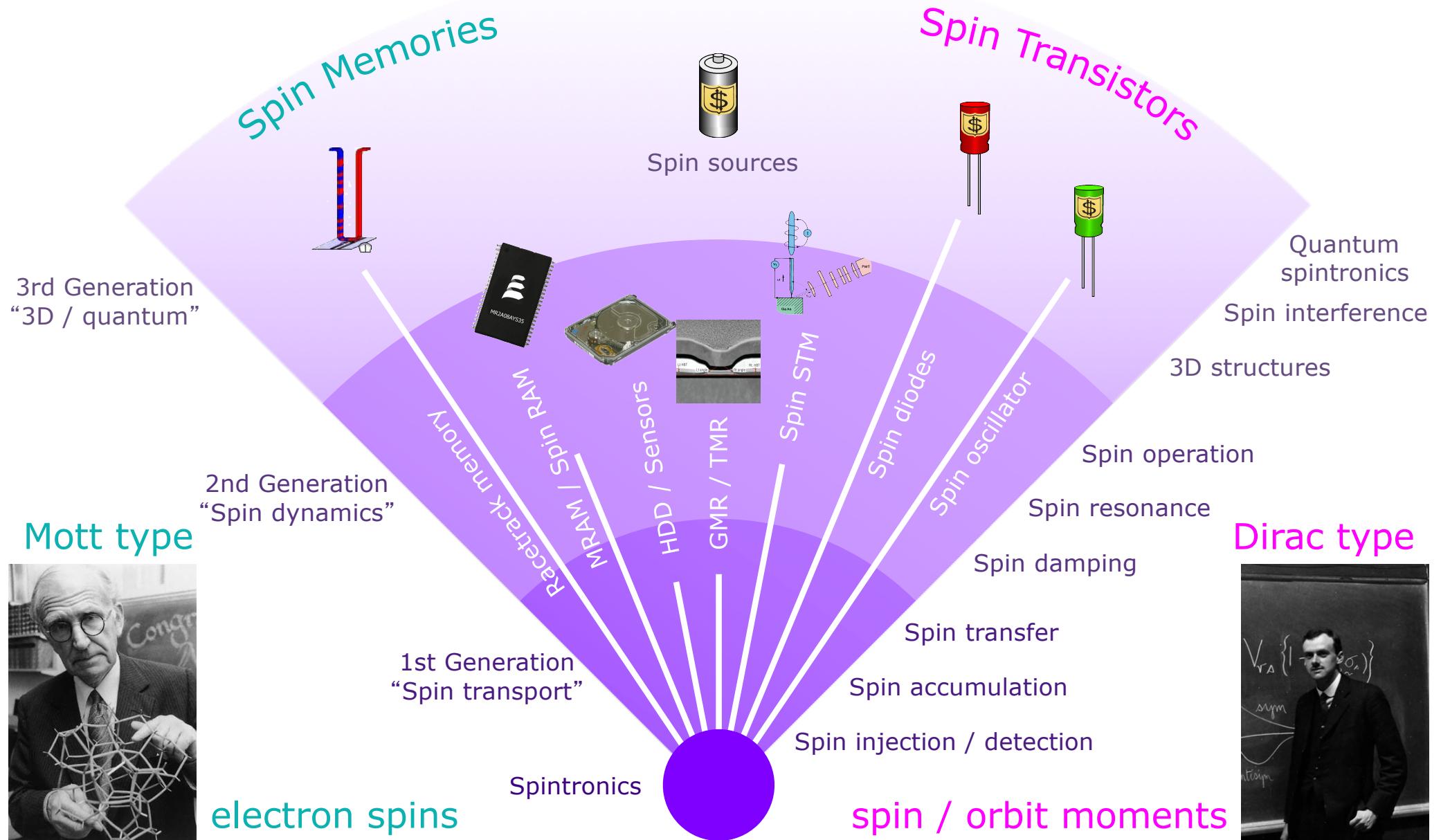
Spin-orbitronics : *



Nano-Spintronic Devices



Development of nano-spintronic devices : *

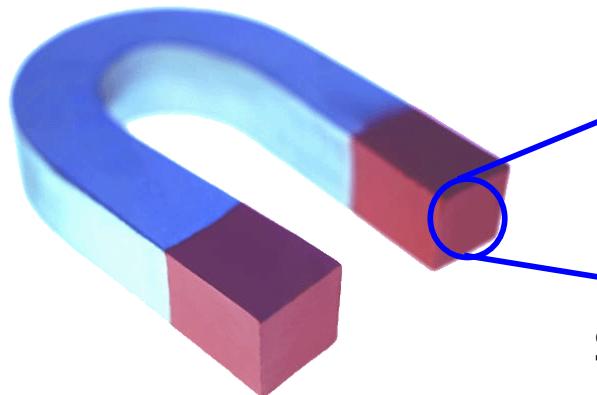


* A. Hirohata and K. Takanashi, *J. Phys. D: Appl. Phys.* **47**, 1930001 (2014).

Half-Metallic Ferromagnet



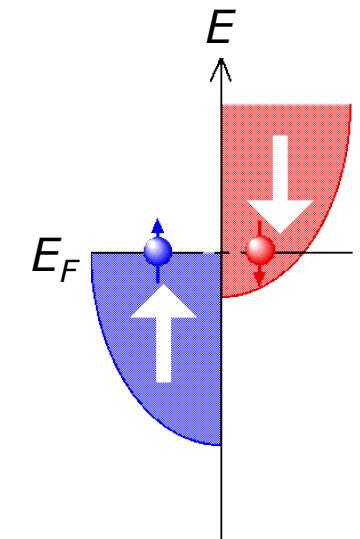
Conventional ferromagnet :



Multi-spin states



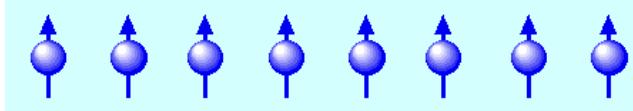
Spin polarisation : 40 ~ 45 %



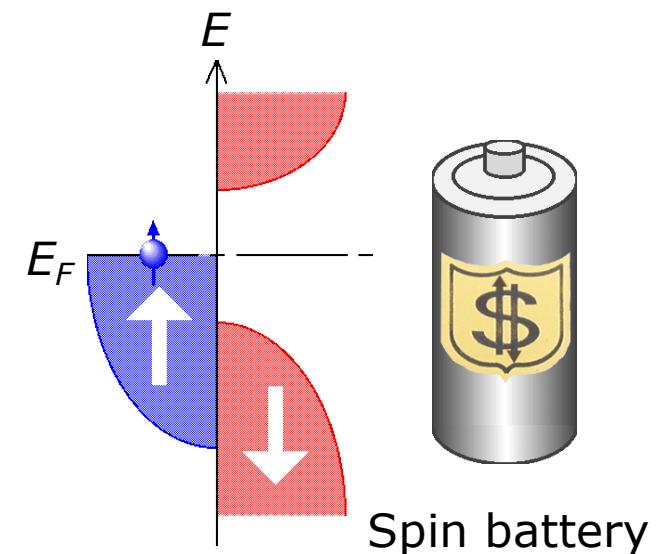
Half-metallic ferromagnet :



Single spin state

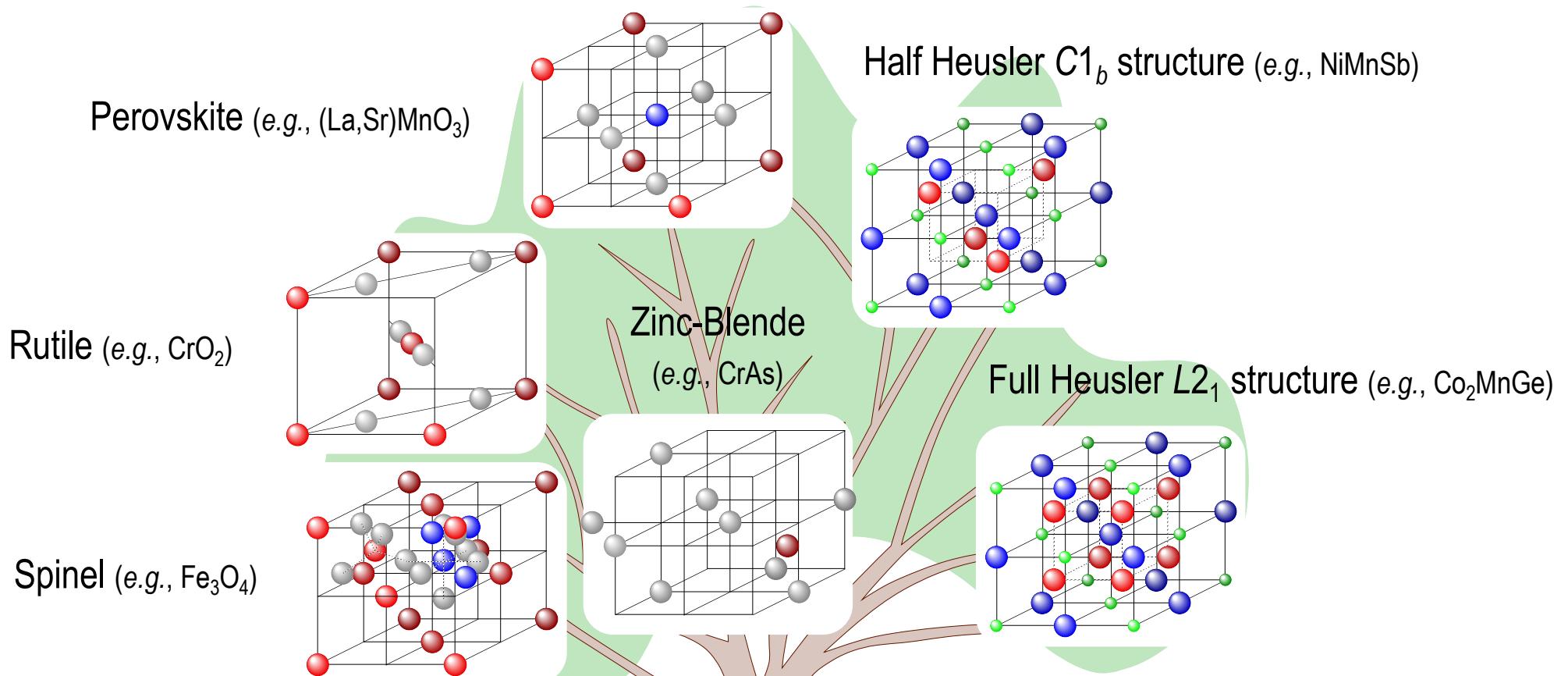


Spin polarisation : 100 %

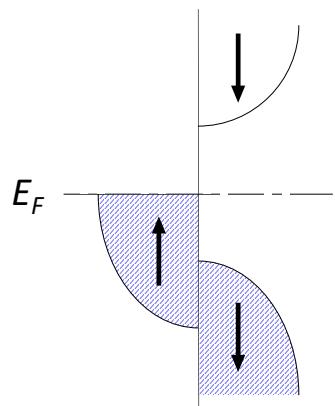




Half-Metallic Ferromagnets



Half-metallic ferromagnets (HMF)



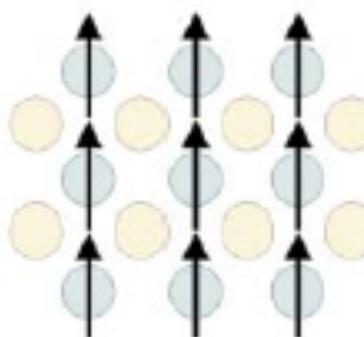
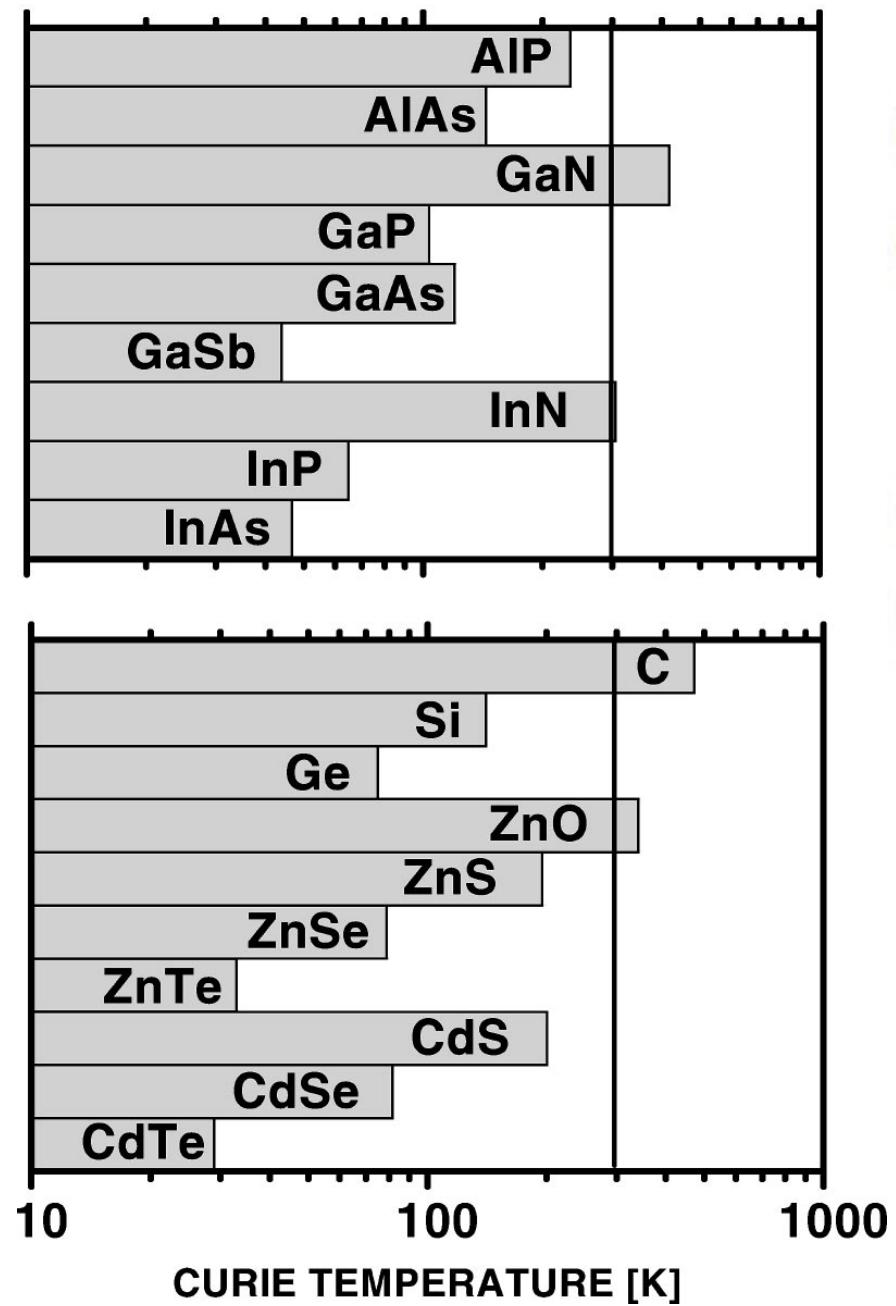
Conduction electrons at the E_F is 100% spin-polarised.

Obstacles to realisation of HMF devices :

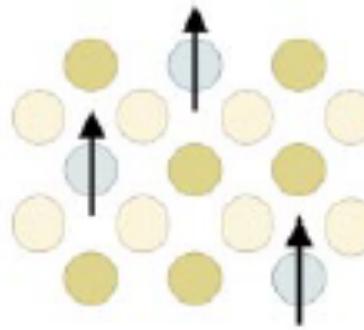
- Curie temperature below room temperature
- atomic disorder / unstable phases



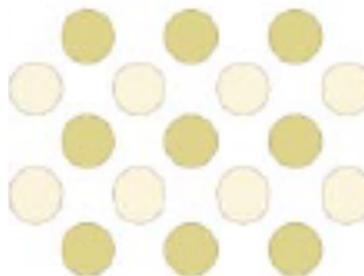
Dilute Magnetic Semiconductors



Magnetic semiconductor



Dilute magnetic semiconductor



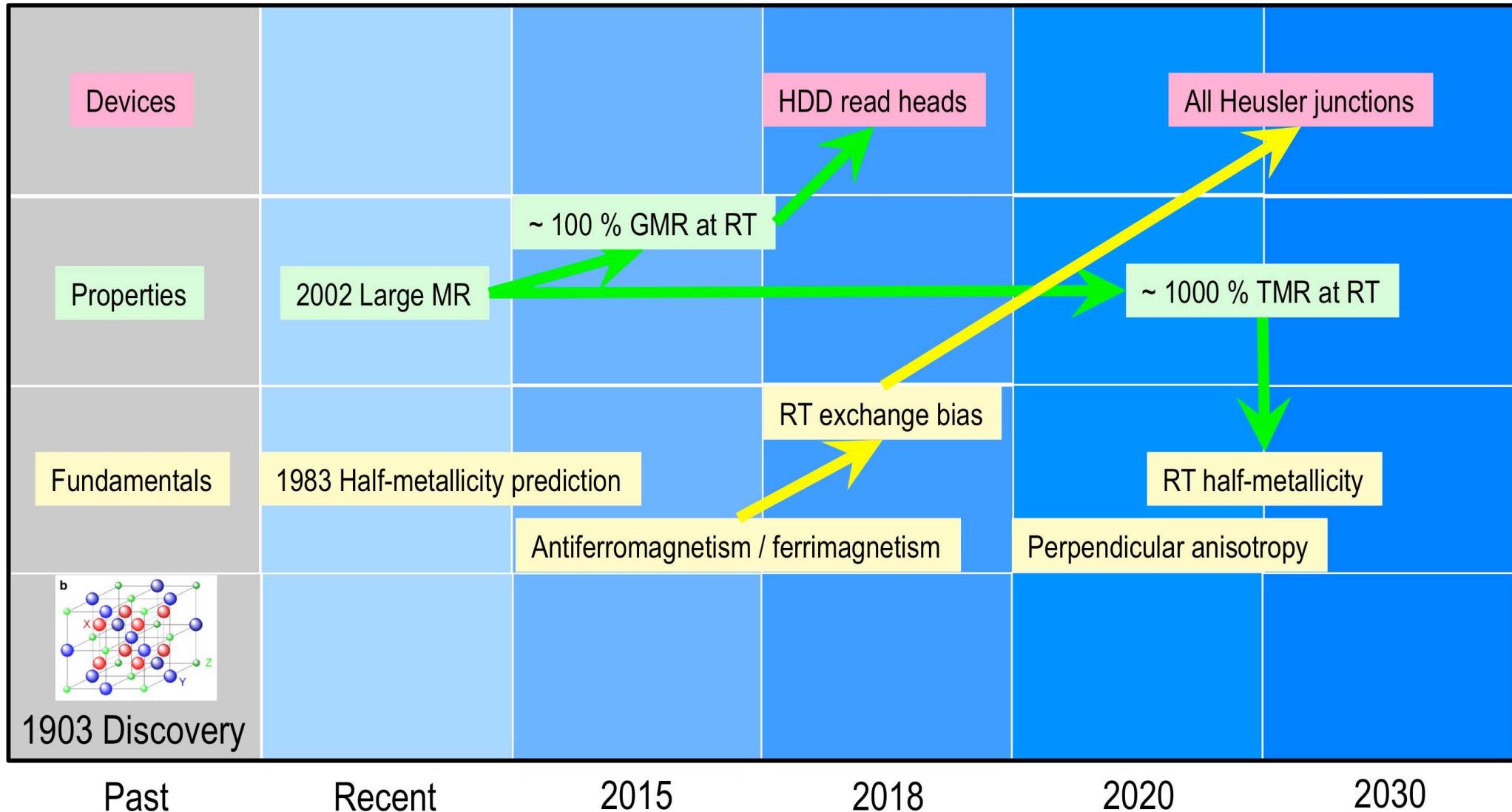
Non-magnetic semiconductor

* H. Munekata *et al.*, *Phys. Rev. Lett.* **63**, 1849 (1989); H. Ohno, *Science* **281**, 951 (1998);

* T. Dietl *et al.*, *Phys. Rev. B* **63**, 195205 (2001).



Roadmap on Heusler Alloys





Summary

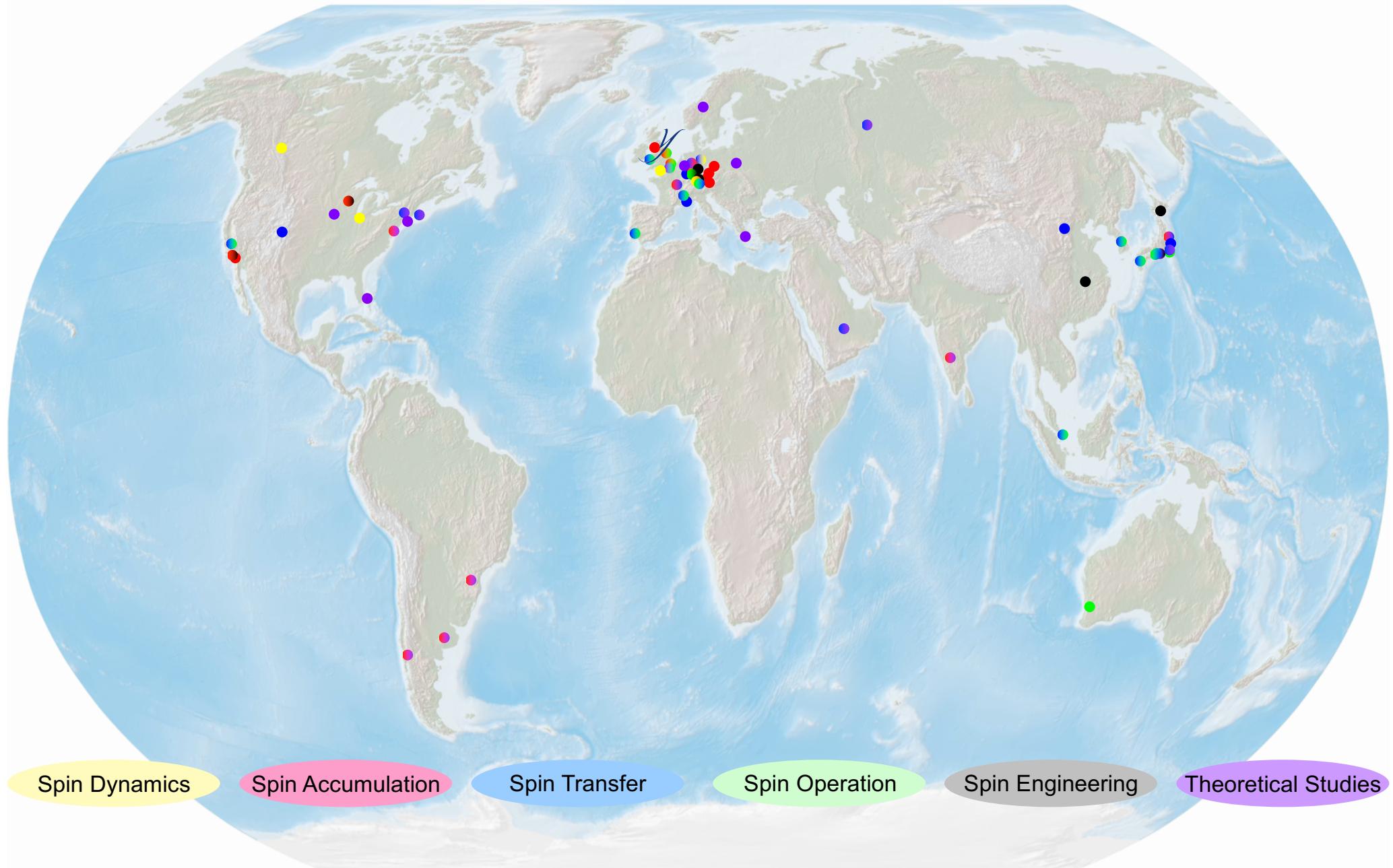
In spintronics, the following contributions need to be considered :

- **Spin-current generation**
e.g., spin injection, electric fields, spin Hall, spin Seebeck, ...
- **Stray fields**
e.g., spin injector design, edge/surface roughness, ...
- **Volume effects**
e.g., epitaxial/poly, edge/surface roughness, activation volume, ...
- **Interfacial effects**
e.g., spin Hall effects, skyrmions, DMI, exchange bias, ...
- **Operation temperatures**
e.g., Curie temperature, Néel temperature, ...
- **Time dependency**
e.g., damping, spin wave, spin pumping, interfacial relaxation, ...
- **Transport**
e.g., ballistic, diffusive (Ohmic), hot electrons, ...
- **Media**
e.g., semiconductor, non-magnetic metal, organic material, ...



Spintonics Studies in the World

Spintronics is one of the *most exciting subject in nano-electronics* :





Group Members



Thank you very much for your attention.



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york spintronics

